

Diffuse Interface Field Approach (DIFA) to Modeling and Simulation of Particle-based Materials Processes

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Motivation

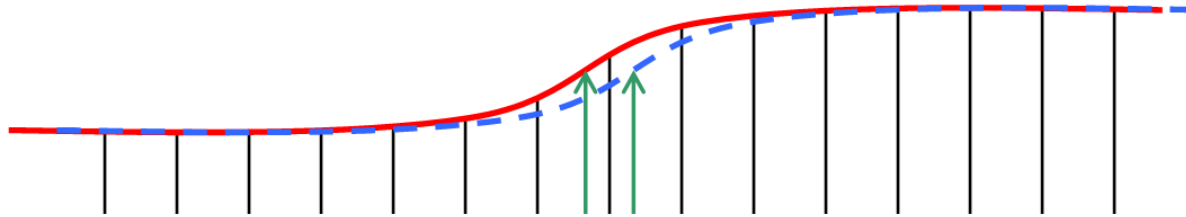
- ❑ Extend **phase field method** to model free-body solid particles

Outline

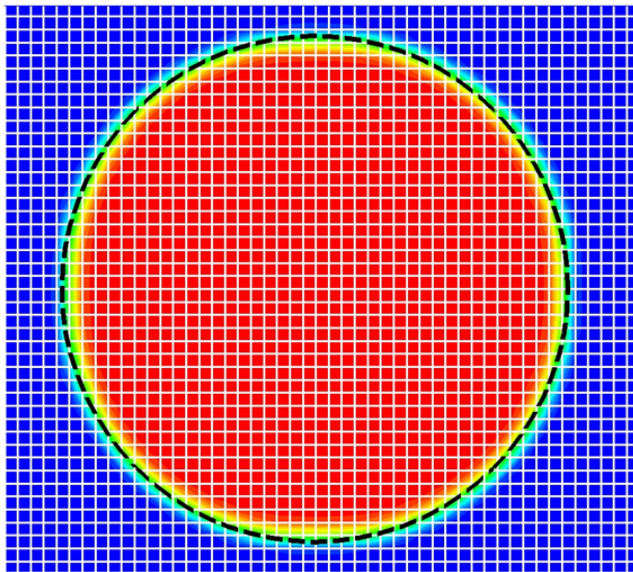
- ❑ Interesting and important issues in particle processes
 - Moving particles of **arbitrary shapes** and sizes in **close distance**: rigid-body translations and rotations
 - Short-range forces: mechanical contact, friction, cohesion, steric repulsion, Stokes drag (particle shape matters)
 - Long-range forces: electric charge, charge heterogeneity, electric double layer, electric/magnetic dipole, van der Waals (point-charge/point-dipole approximation inaccurate)
 - External forces: electric/magnetic field, gravity (field-directed self-assembly)
 - Multi-phase liquid: fluid interface evolution, capillary force on particles (surface tension, Laplace pressure via Gibbs-Duhem relation)

Model Formulation

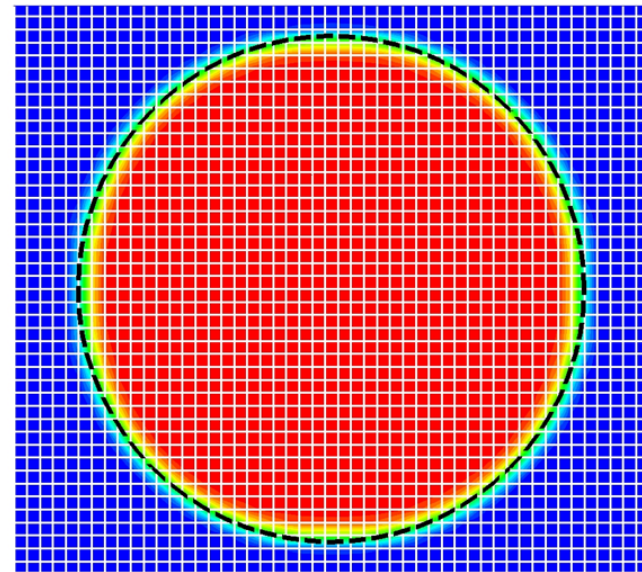
- Diffuse interface field description: arbitrary particle shape, continuous motion on discrete computational grids, as desired for dynamic simulation



(a) diffuse interface field function on discrete computational grids



(b) centered at $X^*=86.95$, $Y^*=64$



(c) centered at $X^*=87.50$, $Y^*=64$

Model Formulation

- Short-range forces: mechanical contact, steric repulsion

$$d\mathbf{F}^{\text{sr}}(\mathbf{r};\alpha) = \kappa \sum_{\alpha' \neq \alpha} \eta(\mathbf{r};\alpha)\eta(\mathbf{r};\alpha') [\nabla \eta(\mathbf{r};\alpha) - \nabla \eta(\mathbf{r};\alpha')] d^3r$$

action-reaction symmetry

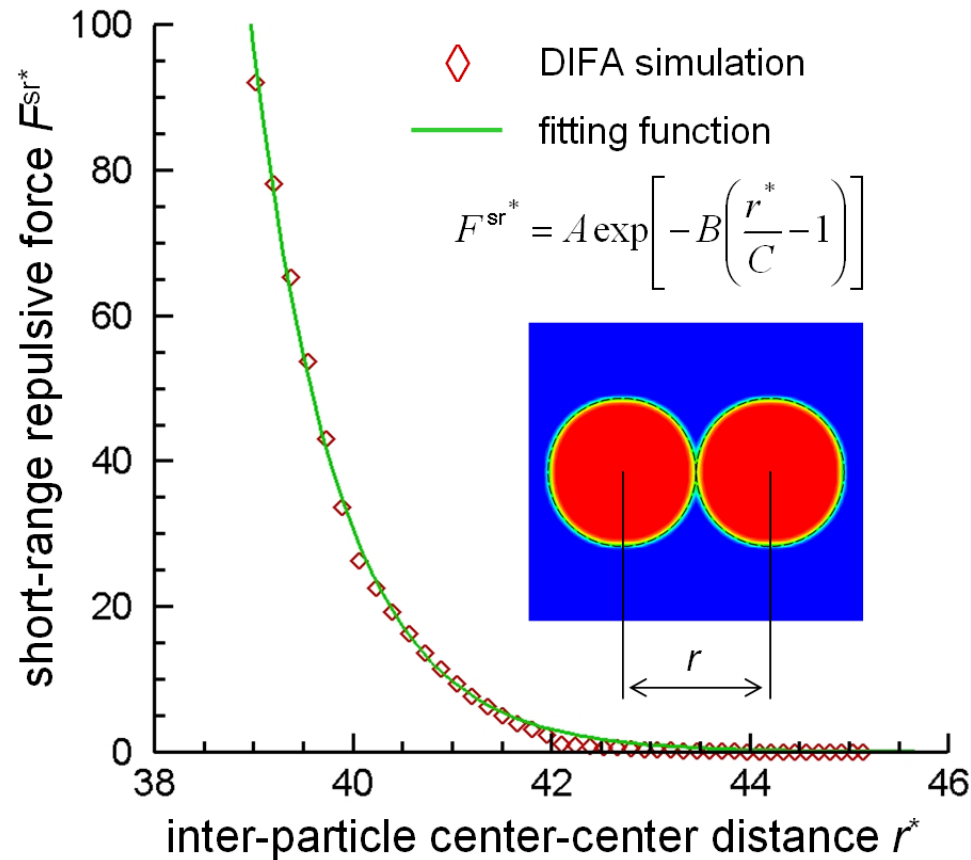
$$\mathbf{F}^{\text{sr}}(\alpha) = \int_V d\mathbf{F}^{\text{sr}}(\mathbf{r};\alpha)$$

soft-particle potential

$$\mathbf{T}^{\text{sr}}(\alpha) = \int_V [\mathbf{r} - \mathbf{r}^c(\alpha)] \times d\mathbf{F}^{\text{sr}}(\mathbf{r};\alpha)$$

torque

Arbitrary particle shapes
without tracking interfaces



Model Formulation

- Total force and torque acting on individual particle

$$\mathbf{F}(\alpha) = \mathbf{F}^{\text{sr}}(\alpha) + \xi^{\text{f}}(\alpha)$$

thermal noise for Brownian motion

$$\mathbf{T}(\alpha) = \mathbf{T}^{\text{sr}}(\alpha) + \xi^{\text{t}}(\alpha)$$

- Particle dynamics in viscous liquid

$$V_i(\alpha) = M_{ij}(\alpha) F_j(\alpha)$$

small Reynolds number $\text{Re} \ll 1$,

$$\Omega_i(\alpha) = N_{ij}(\alpha) T_j(\alpha)$$

Stokes drag (friction), mobility

- Equation of motion

$$\eta(\mathbf{r}, t; \alpha) = \eta(\mathbf{r}^0, t_0; \alpha)$$

mapping without

$$r_i = Q_{ij}(t; \alpha) [r_j^0 - r_j^c(t_0; \alpha)] + r_i^c(t; \alpha)$$

error accumulation

$$r_i^c(t + dt; \alpha) = r_i^c(t; \alpha) + V_i(t; \alpha) dt$$

translation

$$Q_{ij}(t + dt; \alpha) = R_{ik}(t; \alpha) Q_{kj}(t; \alpha)$$

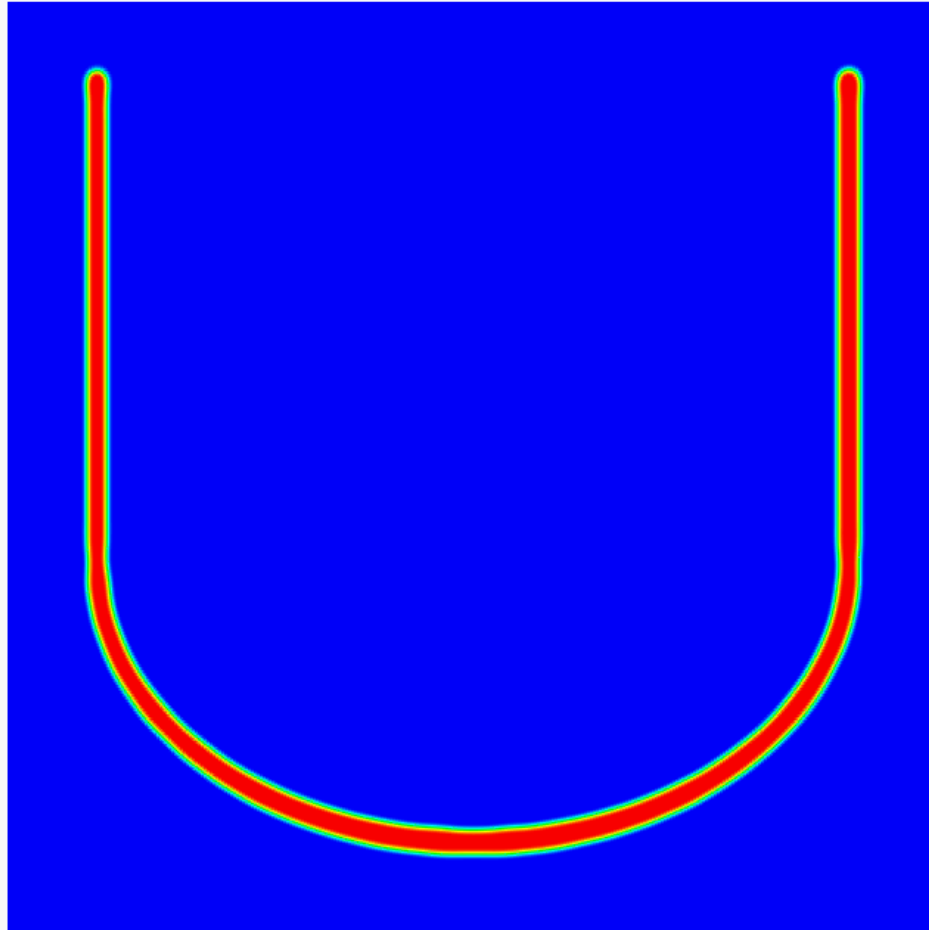
rotation

$$R_{ij}(t; \alpha) = \delta_{ij} \cos \omega + m_i m_j (1 - \cos \omega) - \varepsilon_{ijk} m_k \sin \omega$$

incremental rotation

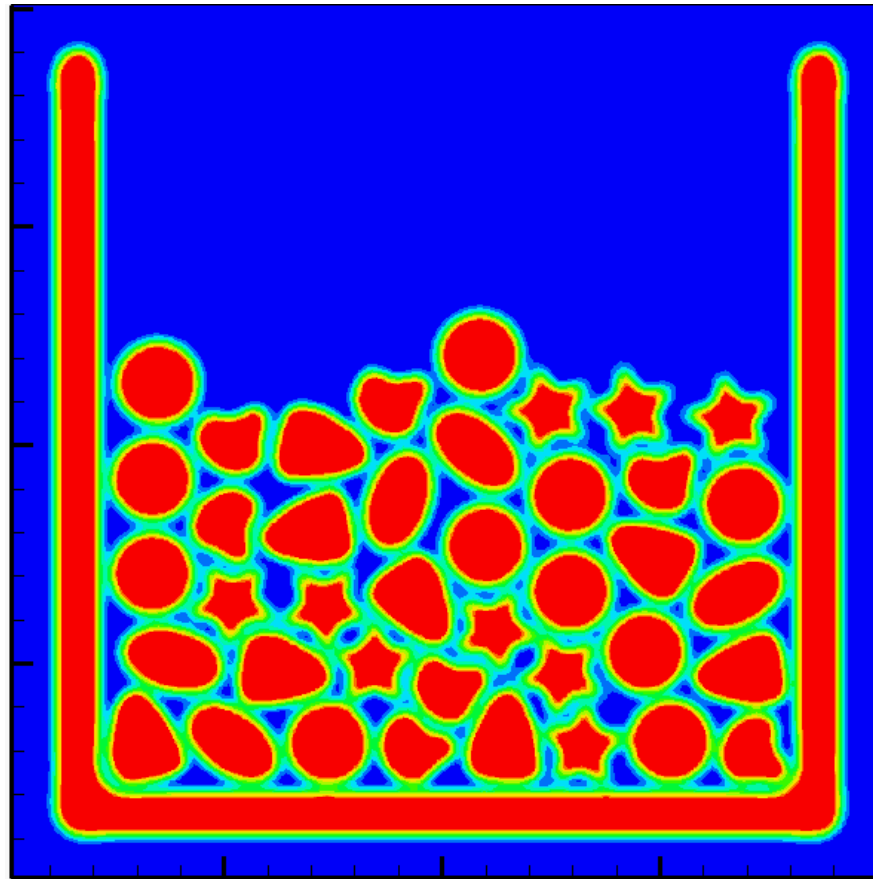
Simulation

- ❑ Particle sedimentation and stacking



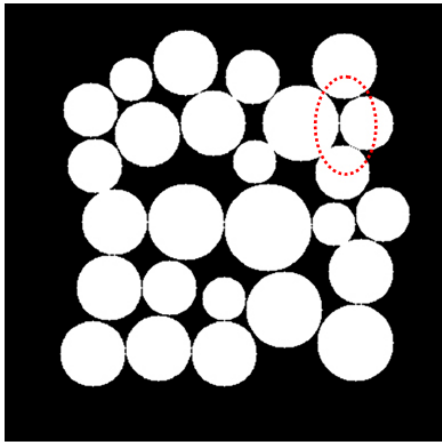
Simulation

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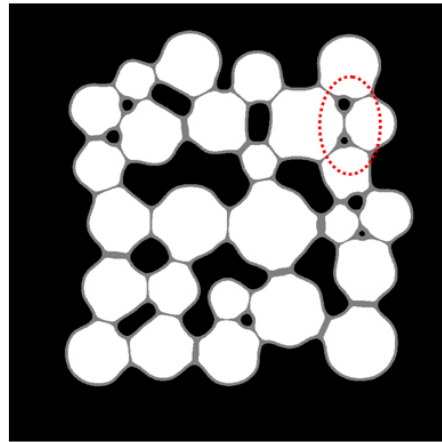


Simulation

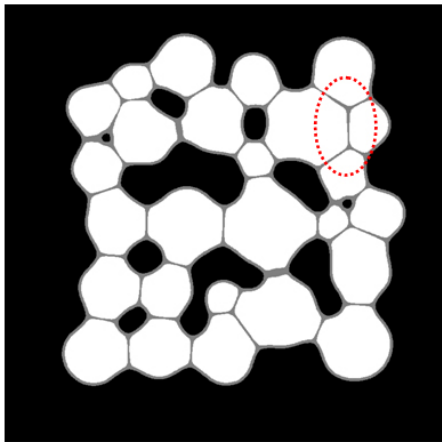
Phase field model of solid-state sintering: **rigid-body motions**



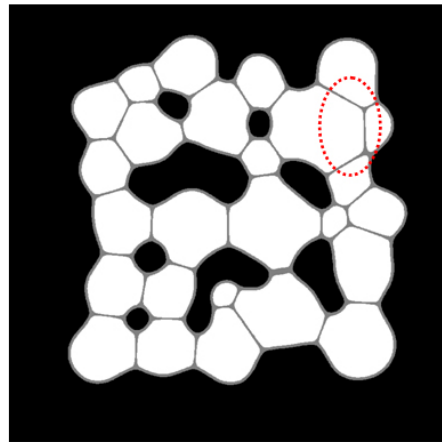
(a) $t^*=0$



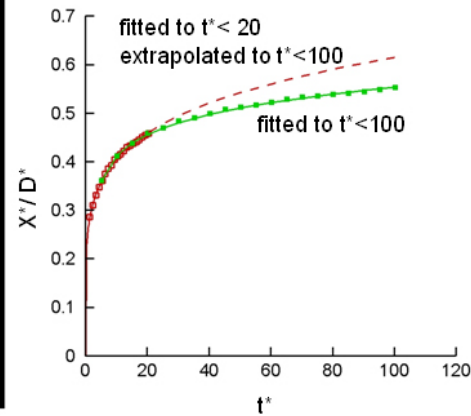
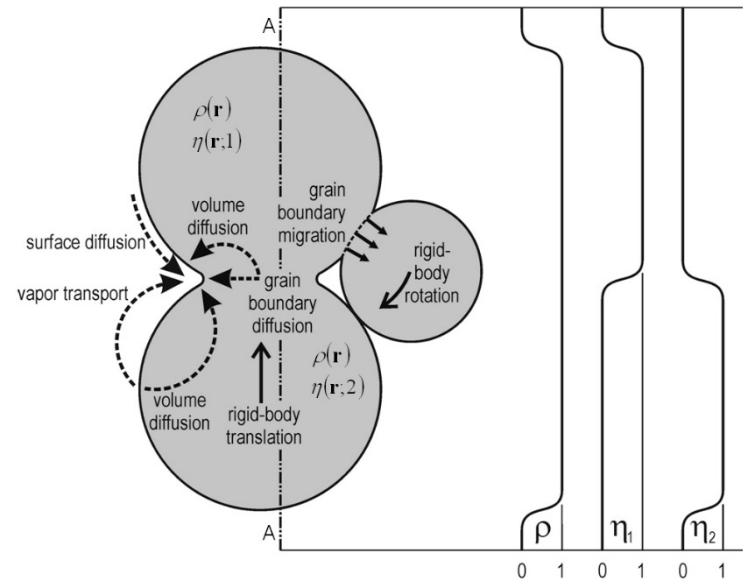
(b) $t^*=16$



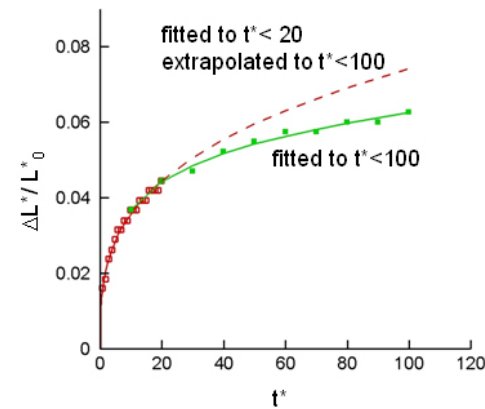
(c) $t^*=46$



(d) $t^*=81$



(a)



(b)

Model Formulation

- Long-range force: charged particles

$$\rho(\mathbf{r}, t; \alpha) = \rho(\alpha) \eta(\mathbf{r}, t; \alpha)$$

body charge

$$\rho(\mathbf{r}, t; \alpha) = \rho(\alpha) \eta(\mathbf{r}, t; \alpha) [1 - \eta(\mathbf{r}, t; \alpha)]$$

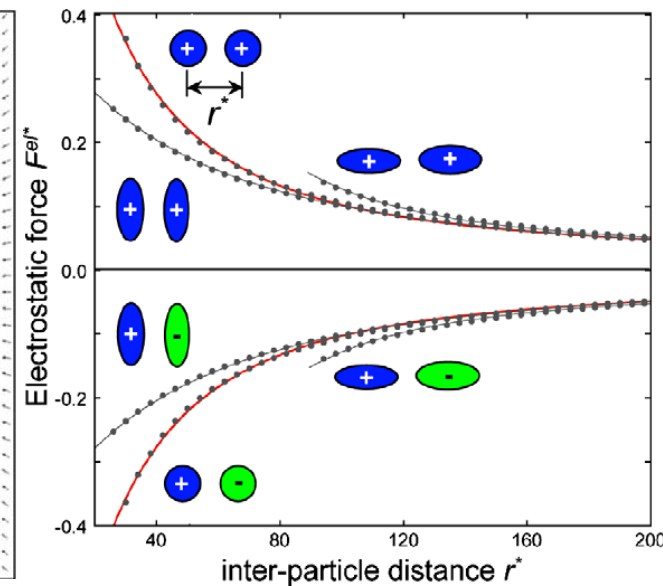
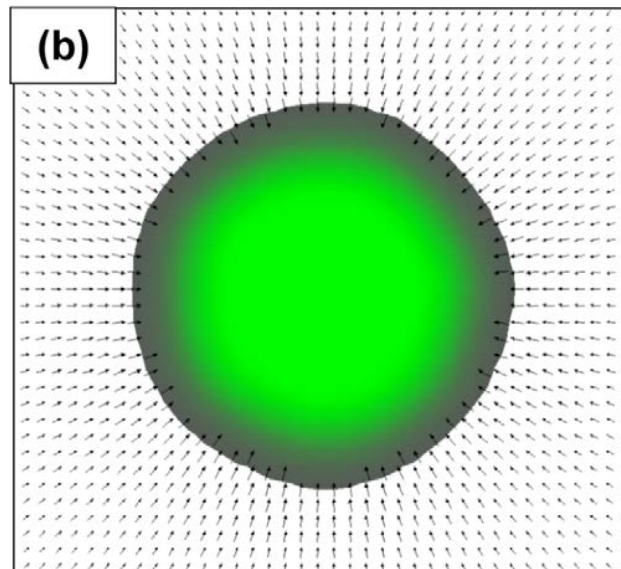
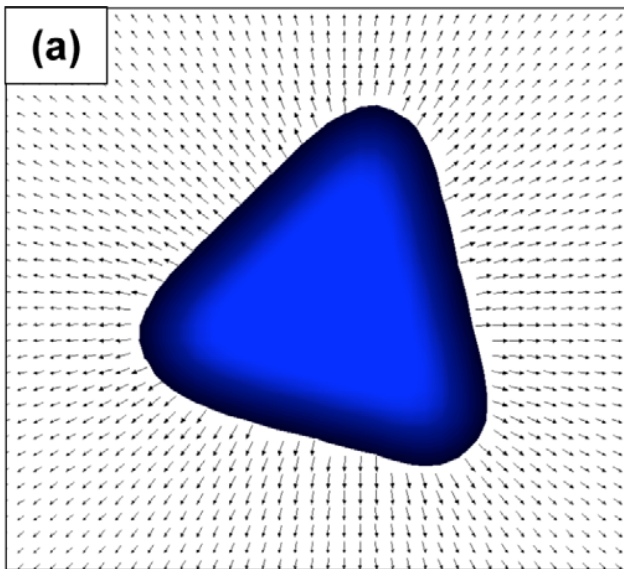
surface charge

$$\rho(\mathbf{r}, t) = \sum_{\alpha} \rho(\mathbf{r}, t; \alpha)$$

$$\mathbf{E}(\mathbf{r}) = \mathbf{E}^{\text{ex}} - \frac{i}{\epsilon_0} \int \frac{d^3 k}{(2\pi)^3} \frac{\tilde{\rho}(\mathbf{k})}{k} \mathbf{n} e^{i\mathbf{k} \cdot \mathbf{r}}$$

$$\mathbf{F}^{\text{el}}(\alpha) = \int_V \mathbf{E}(\mathbf{r}) \rho(\mathbf{r}; \alpha) d^3 r$$

$$\mathbf{T}^{\text{el}}(\alpha) = \int_V [\mathbf{r} - \mathbf{r}^c(\alpha)] \times \mathbf{E}(\mathbf{r}) \rho(\mathbf{r}; \alpha) d^3 r$$



Model Formulation

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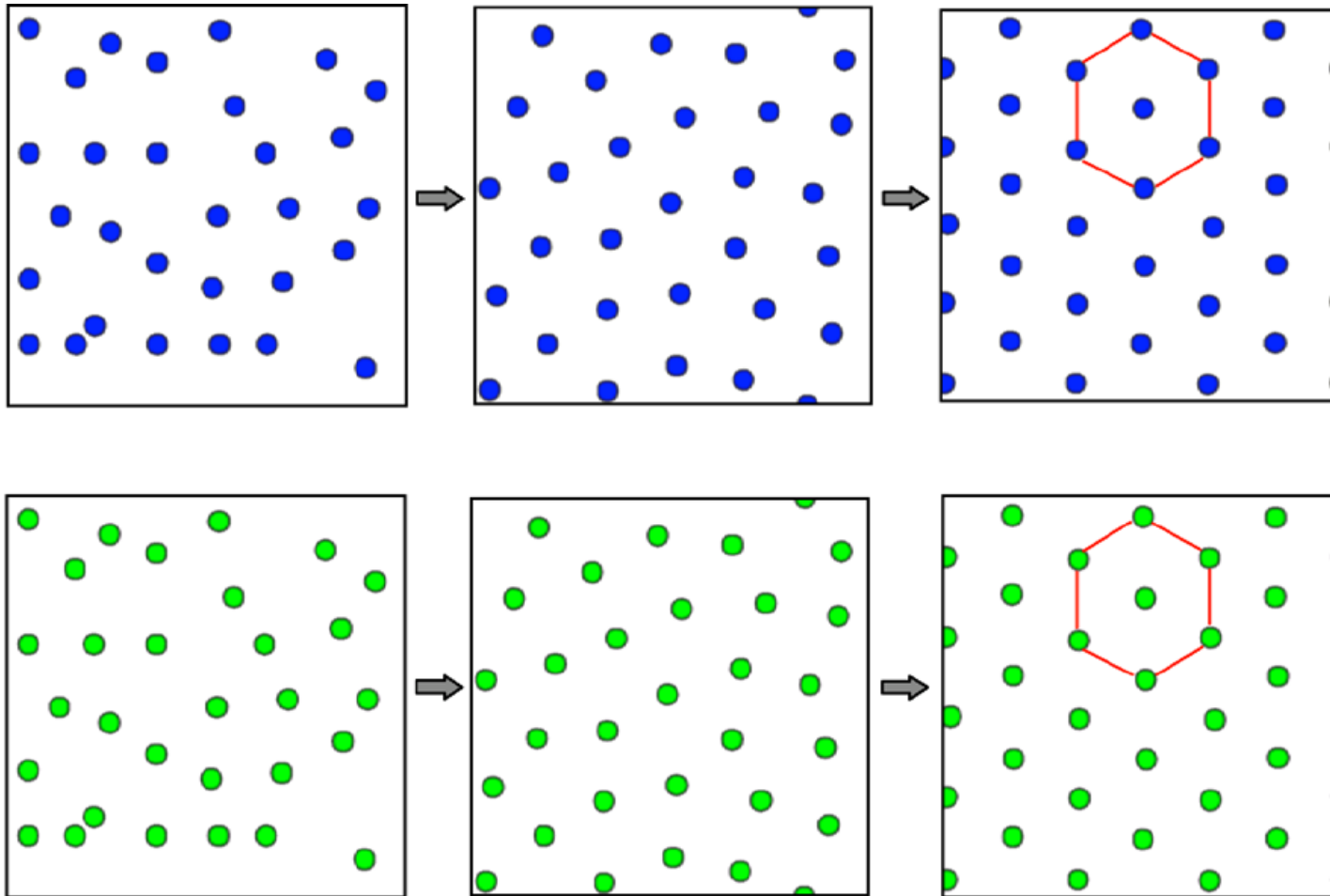
- Total force and torque acting on individual particle

$$\mathbf{F}(\alpha) = \mathbf{F}^{\text{el}}(\alpha) + \mathbf{F}^{\text{sr}}(\alpha) + \boldsymbol{\xi}^{\text{f}}(\alpha)$$

$$\mathbf{T}(\alpha) = \mathbf{T}^{\text{el}}(\alpha) + \mathbf{T}^{\text{sr}}(\alpha) + \boldsymbol{\xi}^{\text{t}}(\alpha)$$

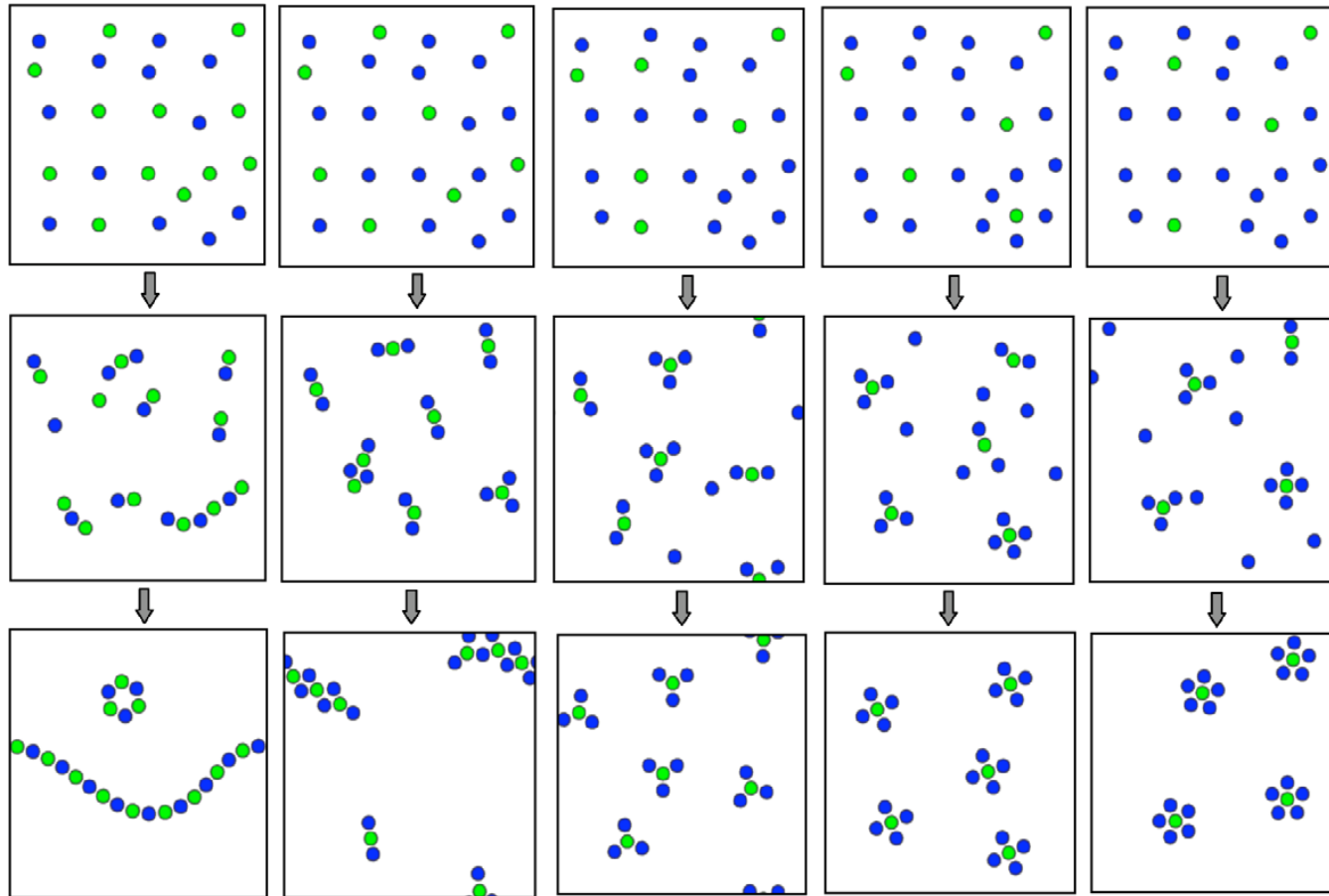
Simulation

- Particles of same charge: **repulsion**



Simulation

□ Particles of opposite charges: **attractive self-assembly**



dipolar

$$N:N^+ = 1:1$$

$$\rho:\rho^+ = 1:1$$

$$N:N^+ = 1:2$$

$$\rho:\rho^+ = 2:1$$

$$N:N^+ = 1:3$$

$$\rho:\rho^+ = 3:1$$

$$N:N^+ = 1:4$$

$$\rho:\rho^+ = 4:1$$

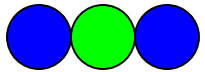
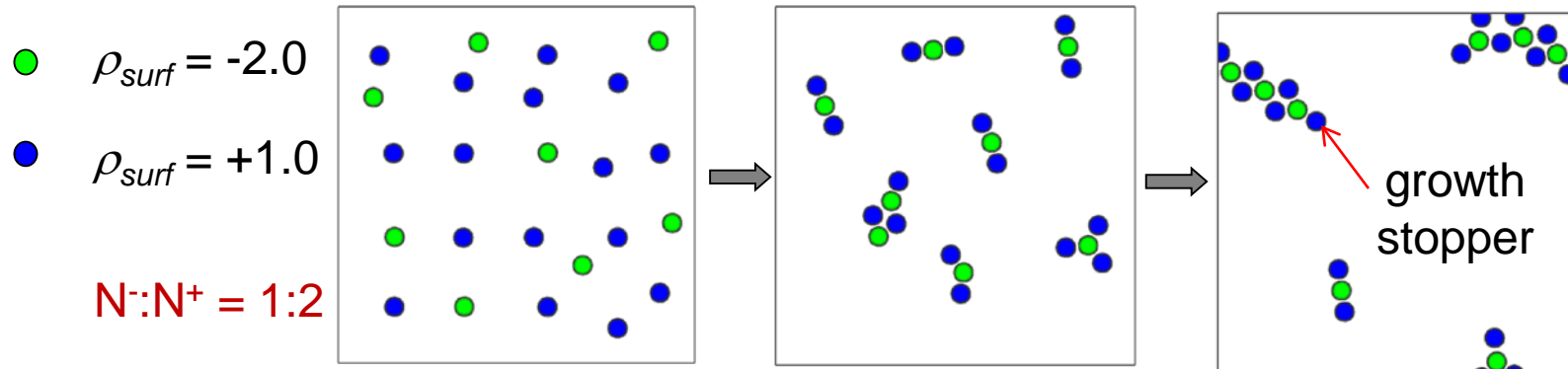
$$N:N^+ = 1:5$$

$$\rho:\rho^+ = 5:1$$

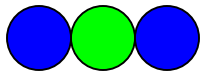
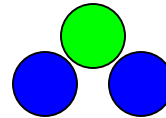
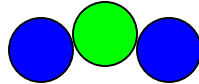
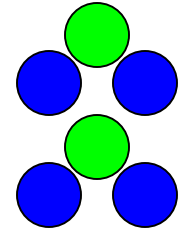
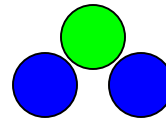
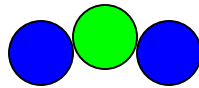
stable

mutually induced dipoles

Self-Assembly Mechanisms



neutral chain formation



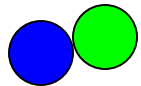
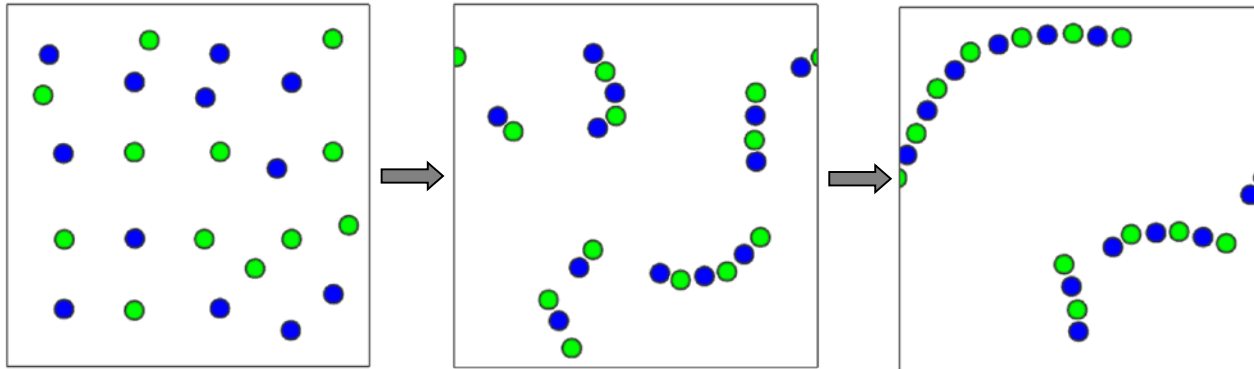
(1) neutral & symmetric (2) induced dipole (3) attraction (4) repeated growth & dipolar

Self-Assembly Mechanisms

● $\rho_{surf} = -2.0$

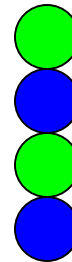
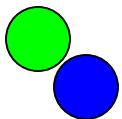
● $\rho_{surf} = +1.0$

$N^-:N^+ = 1:1$



repel at long distance
attract at short distance

charged chain formation,
mutually repulsive,
as straight as possible



(1) charged & dipole

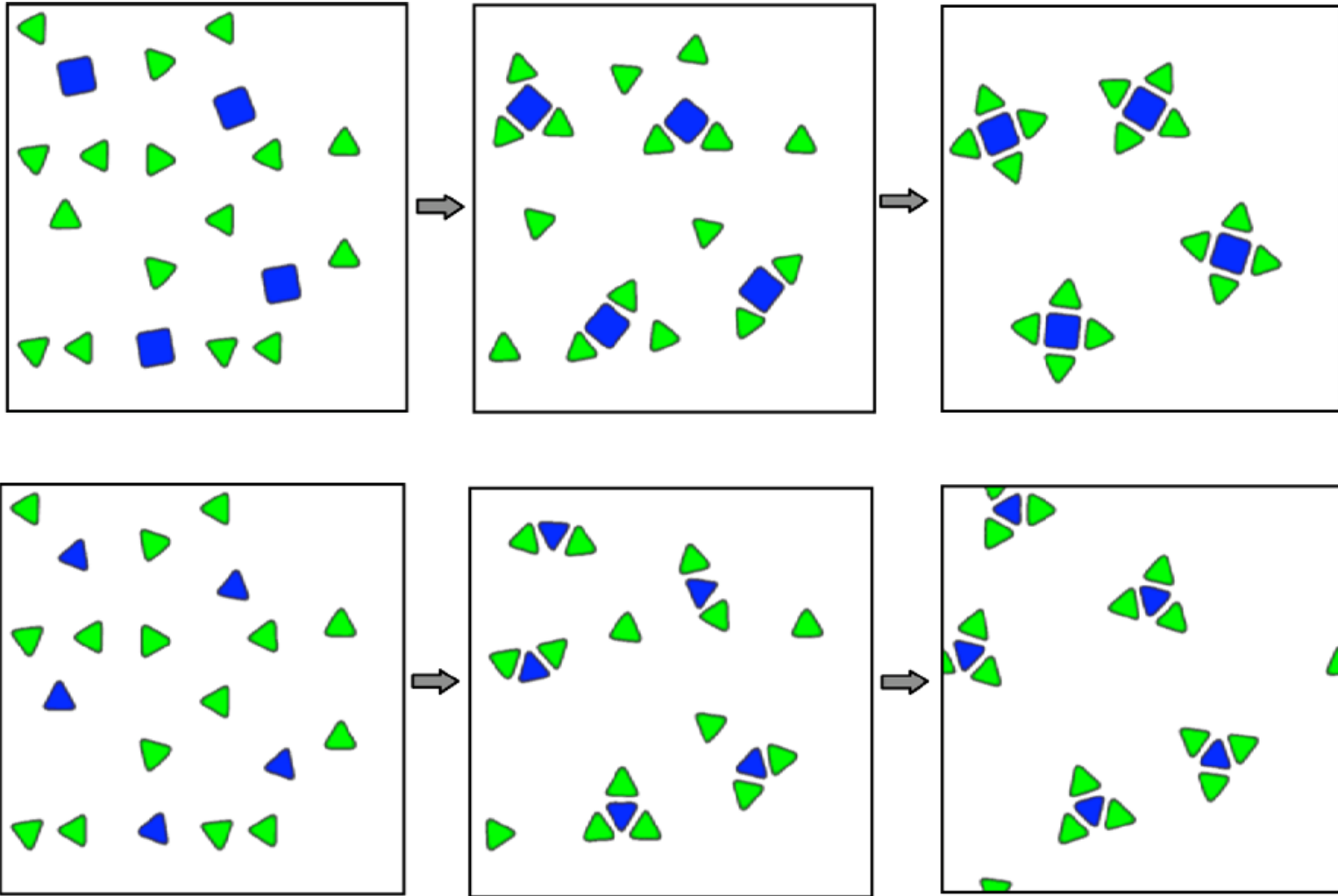
(2) alignment

(3) attraction

(4) repeated growth & charged

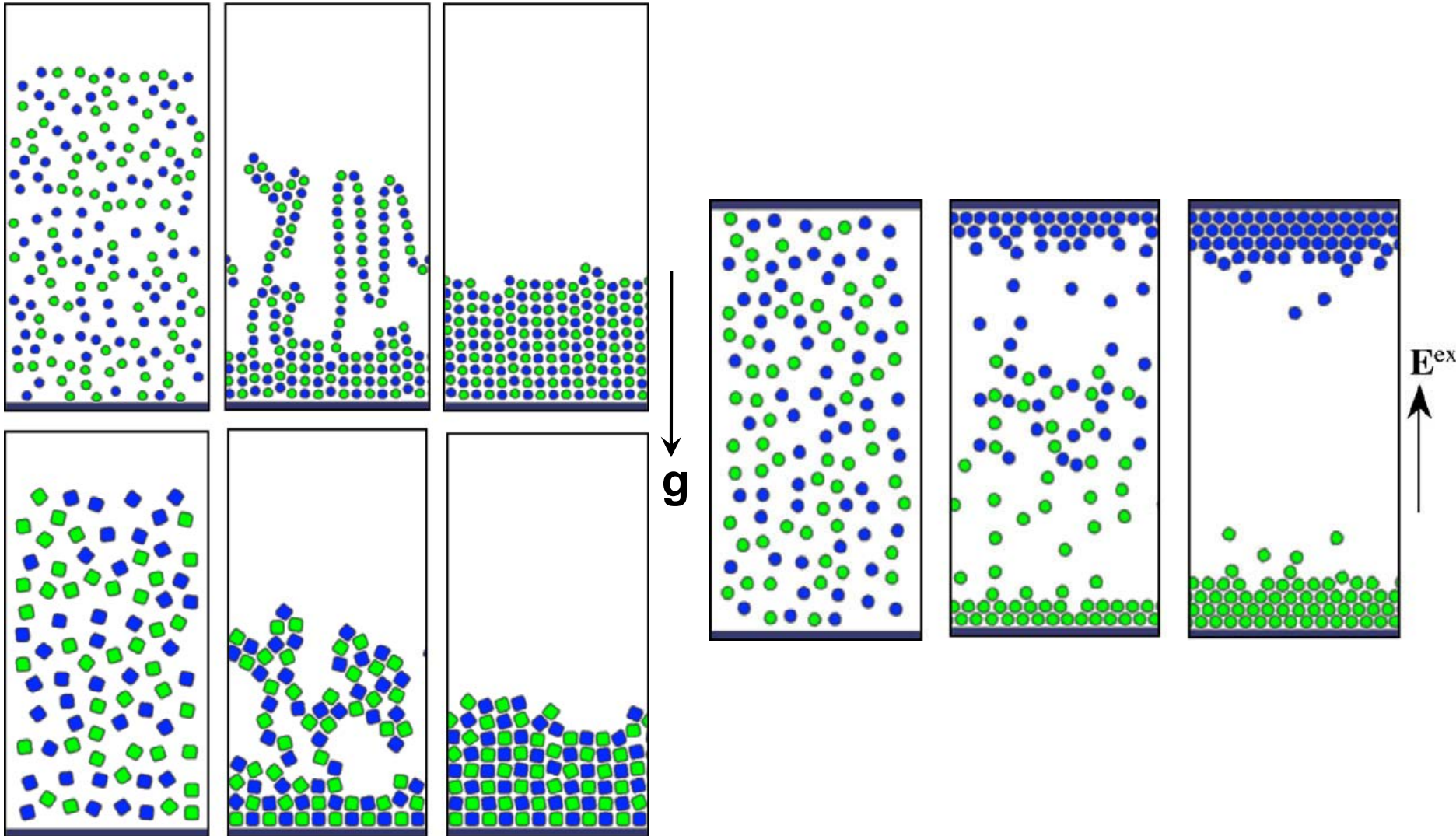
Simulation

- Particles of opposite charges: non-spherical shapes



Simulation

- Stacking of charged particles under external fields



Model Formulation

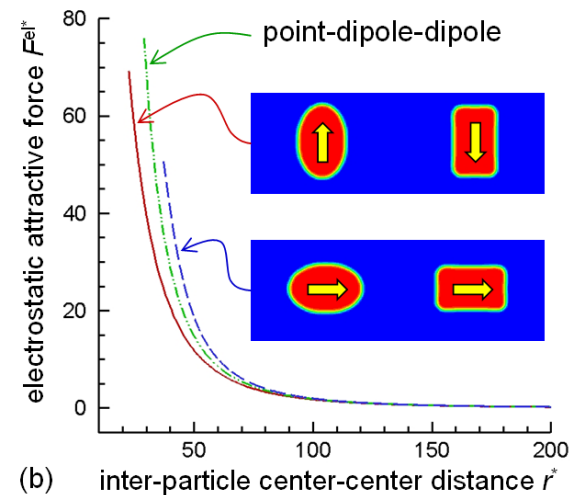
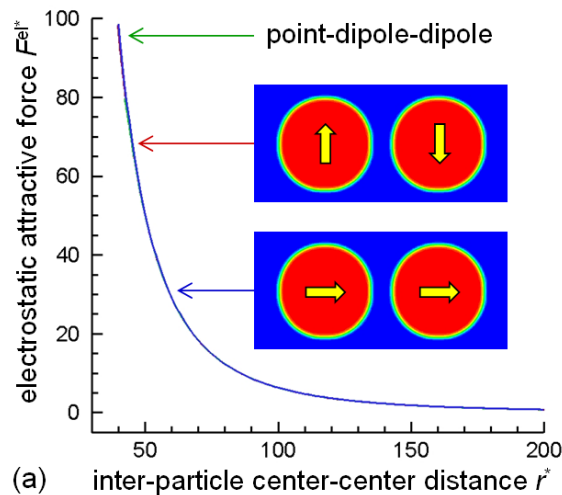
- Long-range force: dipolar particles

$$\mathbf{P}(\mathbf{r}, t; \alpha) = \mathbf{P}(t; \alpha) \eta(\mathbf{r}, t; \alpha)$$

$$\mathbf{P}(\mathbf{r}, t) = \sum_{\alpha} \mathbf{P}(\mathbf{r}, t; \alpha) \quad \mathbf{E}(\mathbf{r}) = \mathbf{E}^{\text{ex}} - \frac{1}{\epsilon_0} \int \frac{d^3 k}{(2\pi)^3} [\mathbf{n} \cdot \tilde{\mathbf{P}}(\mathbf{k})] \mathbf{n} e^{i\mathbf{k} \cdot \mathbf{r}}$$

$$\mathbf{F}^{\text{el}}(\alpha) = \int_V [\mathbf{P}(\alpha) \cdot \nabla] \mathbf{E}(\mathbf{r}) \eta(\mathbf{r}; \alpha) d^3 r$$

$$\mathbf{T}^{\text{el}}(\alpha) = \int_V \mathbf{P}(\alpha) \times \mathbf{E}(\mathbf{r}) \eta(\mathbf{r}; \alpha) d^3 r + \int_V [\mathbf{r} - \mathbf{r}^c(\alpha)] \times \{ [\mathbf{P}(\alpha) \cdot \nabla] \mathbf{E}(\mathbf{r}) \} \eta(\mathbf{r}; \alpha) d^3 r$$



Model Formulation

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- Long-range force: magnetic particles

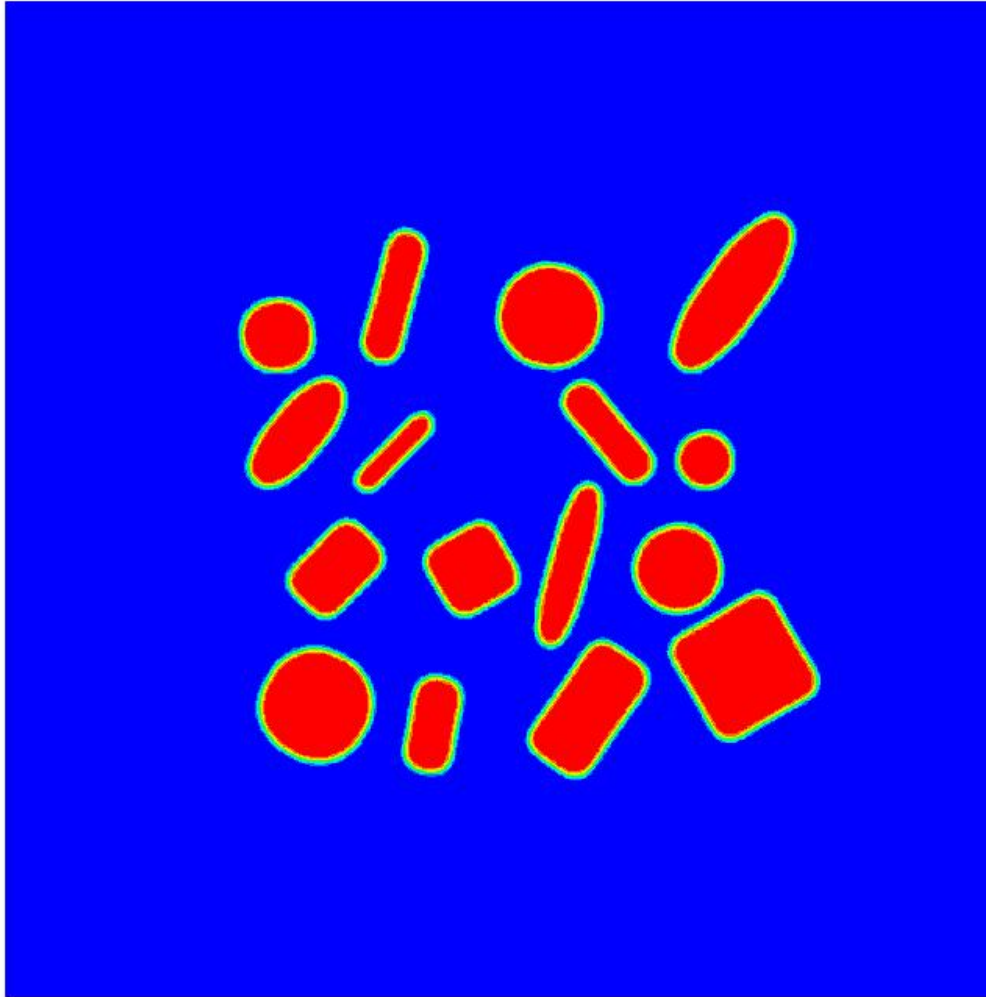
$$\mathbf{M}(\mathbf{r}, t) = \sum_{\alpha} \mathbf{M}(t; \alpha) \eta(\mathbf{r}, t; \alpha) \quad \mathbf{H}(\mathbf{r}) = \mathbf{H}^{\text{ex}} - \int \frac{d^3 k}{(2\pi)^3} [\mathbf{n} \cdot \tilde{\mathbf{M}}(\mathbf{k})] \mathbf{n} e^{i\mathbf{k} \cdot \mathbf{r}}$$

$$\mathbf{F}^{\text{mag}}(\alpha) = \mu_0 \int_V [\mathbf{M}(\alpha) \cdot \nabla] \mathbf{H}(\mathbf{r}) \eta(\mathbf{r}; \alpha) d^3 r$$

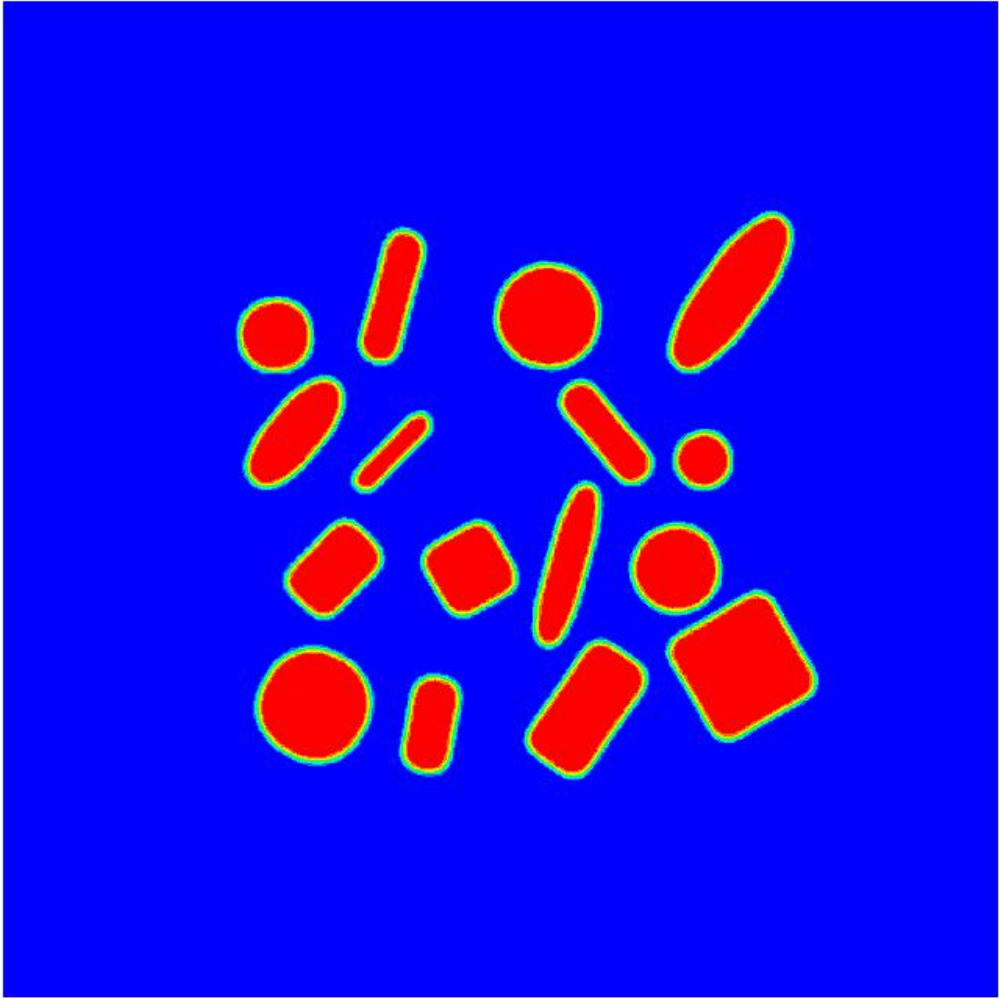
$$\mathbf{T}^{\text{mag}}(\alpha) = \mu_0 \int_V \mathbf{M}(\alpha) \times \mathbf{H}(\mathbf{r}) \eta(\mathbf{r}; \alpha) d^3 r + \mu_0 \int_V [\mathbf{r} - \mathbf{r}^c(\alpha)] \times \{ [\mathbf{M}(\alpha) \cdot \nabla] \mathbf{H}(\mathbf{r}) \} \eta(\mathbf{r}; \alpha) d^3 r$$

Simulation

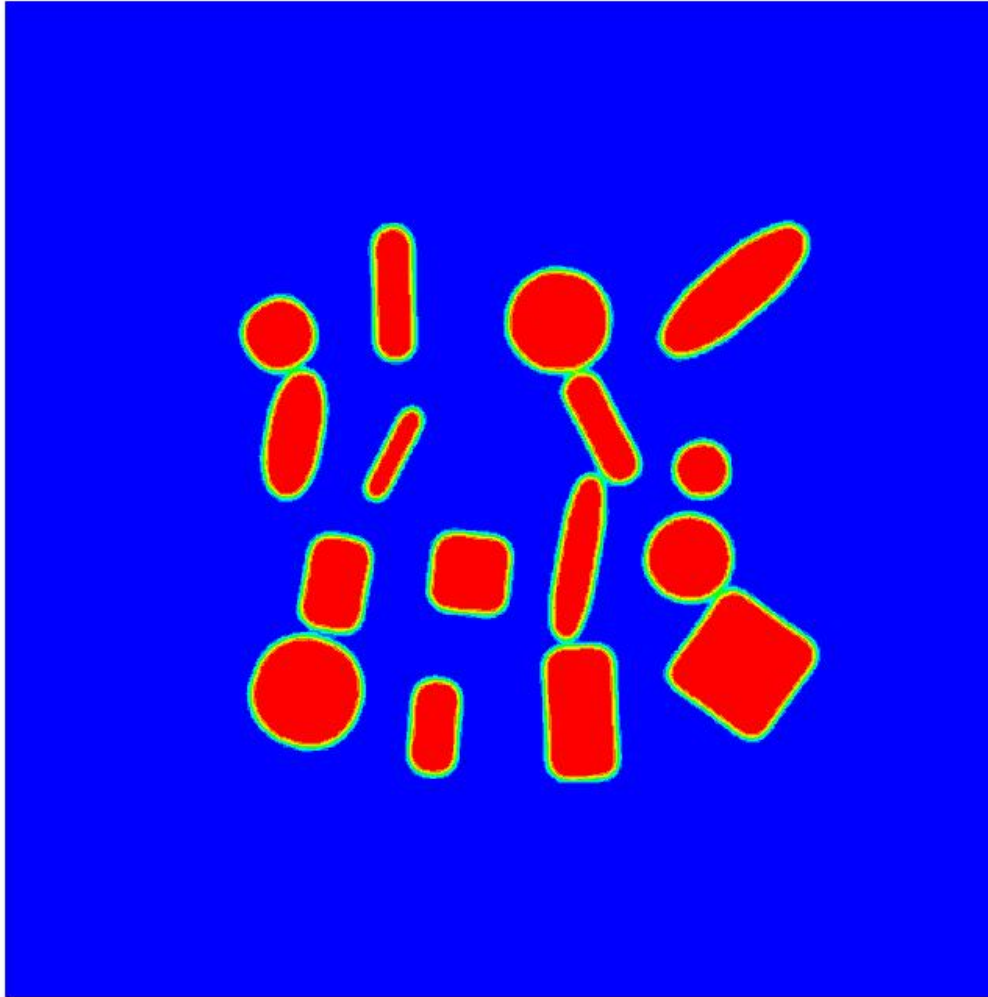
- Dipolar particles: agglomeration



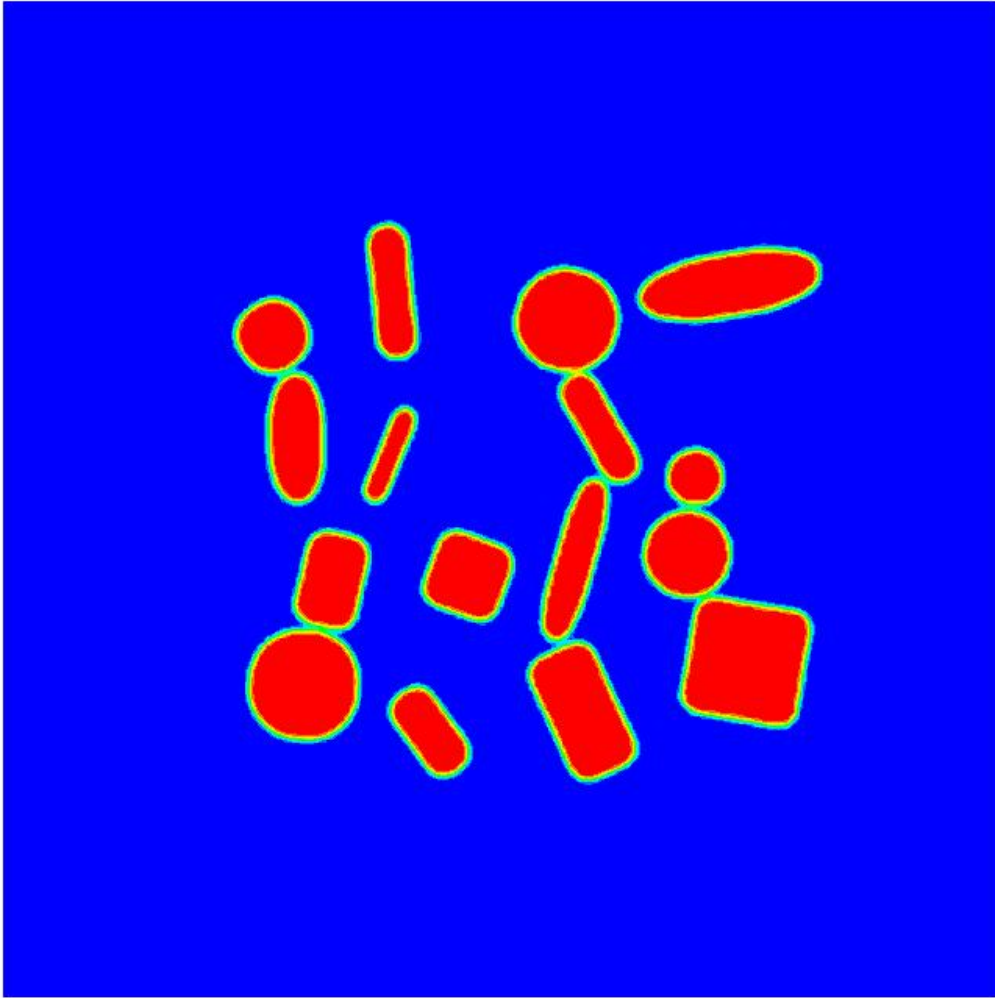
Self-Assembly of Arbitrary-Shaped Dipolar Particles



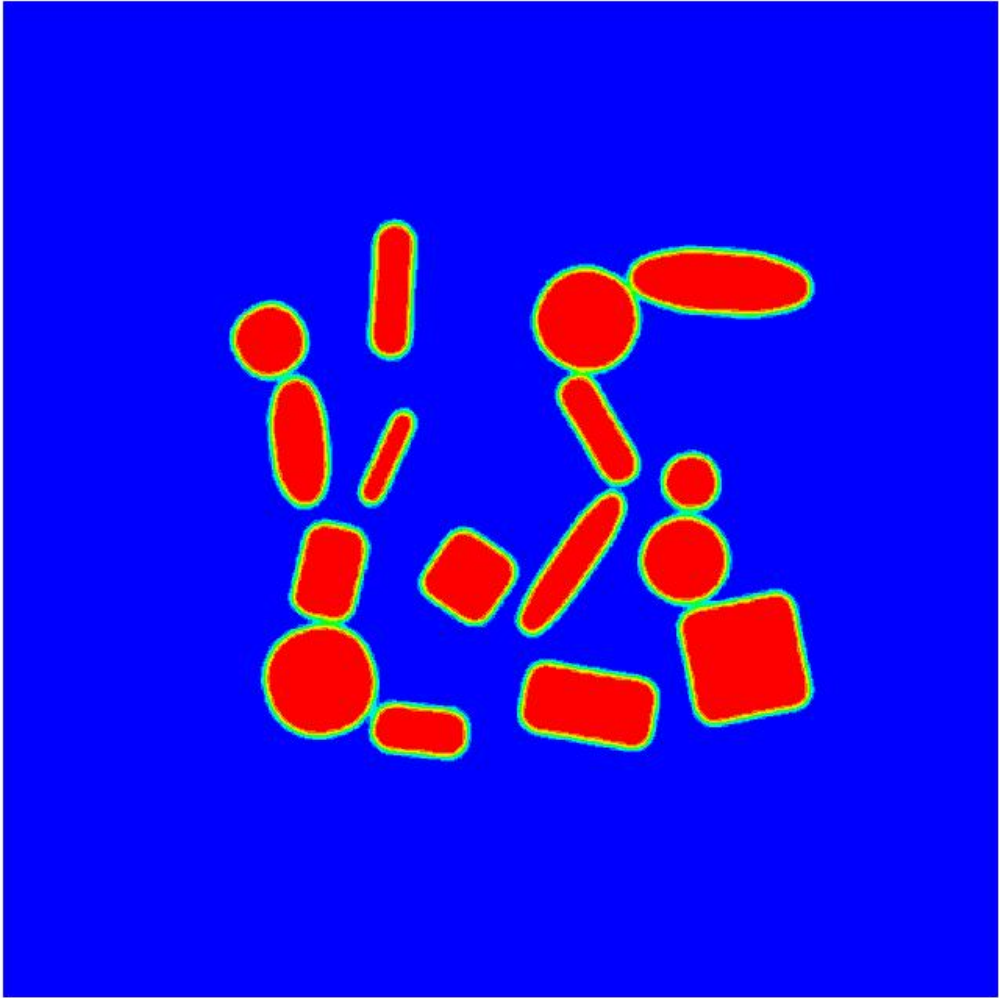
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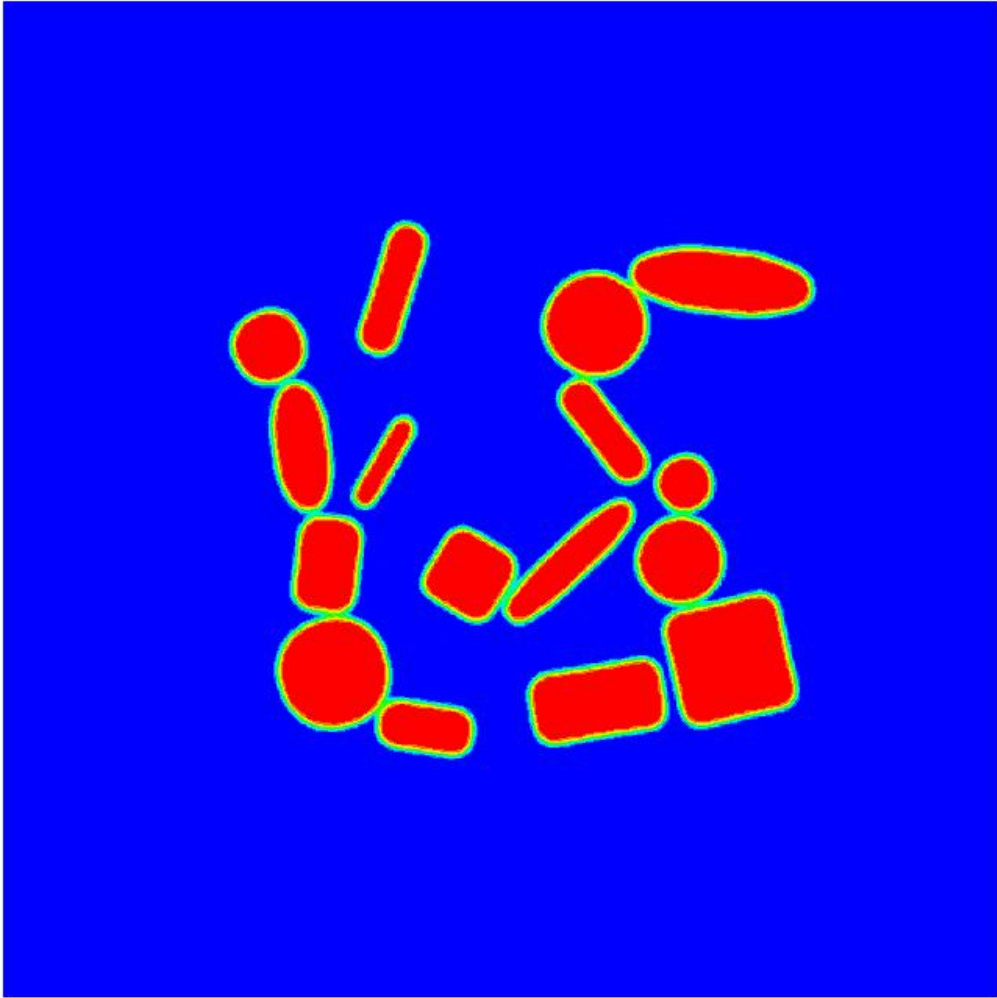
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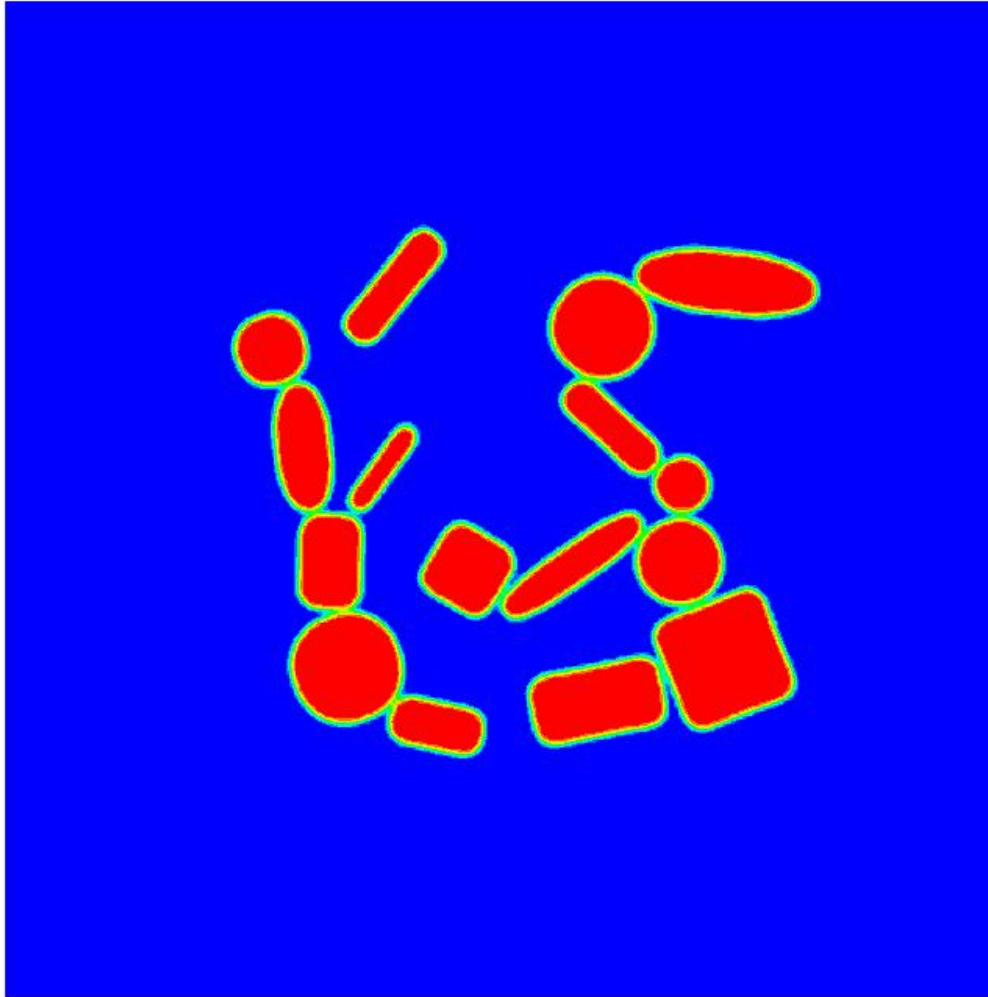
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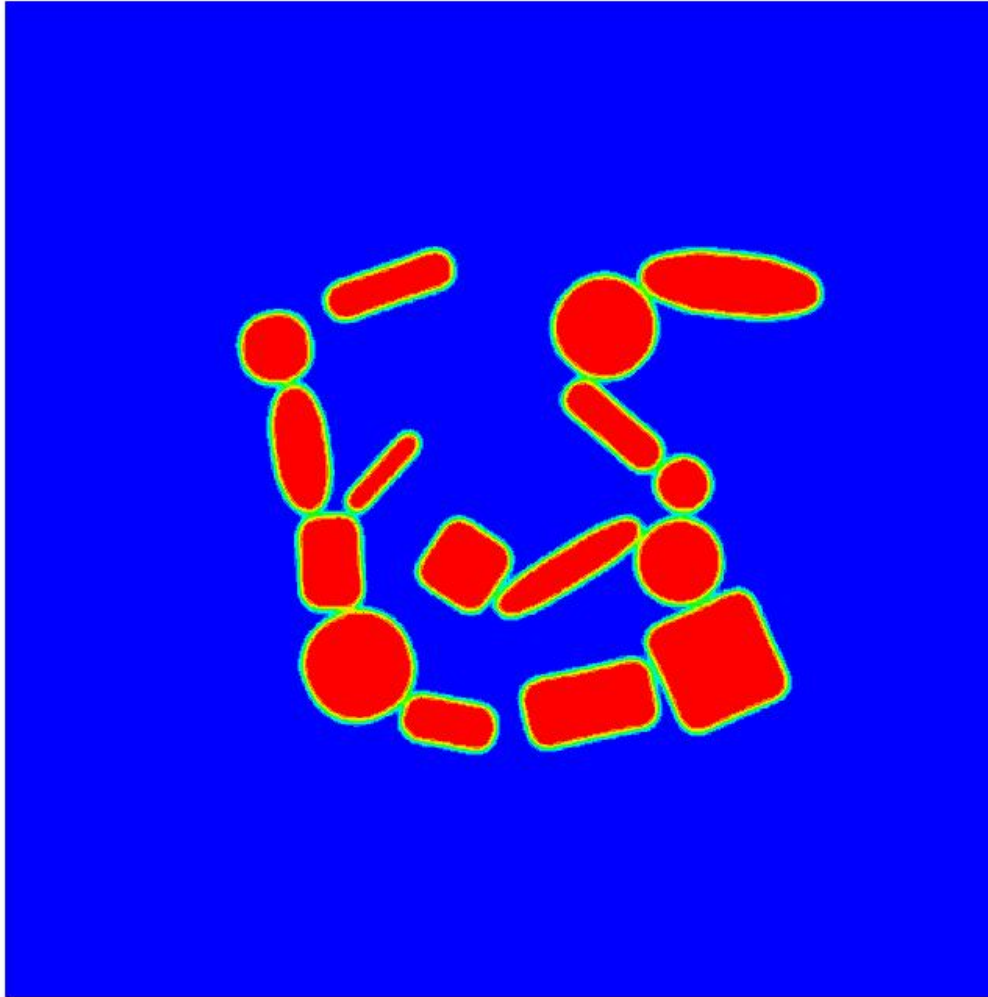
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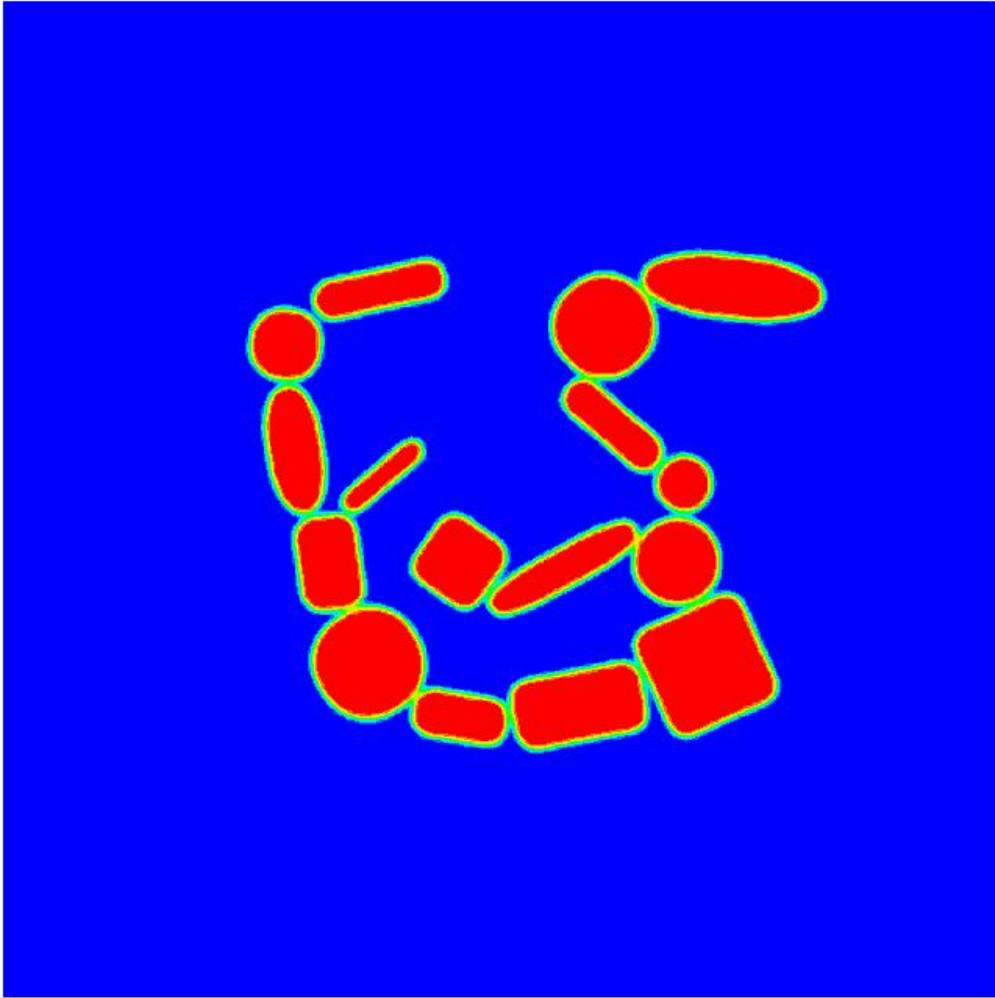
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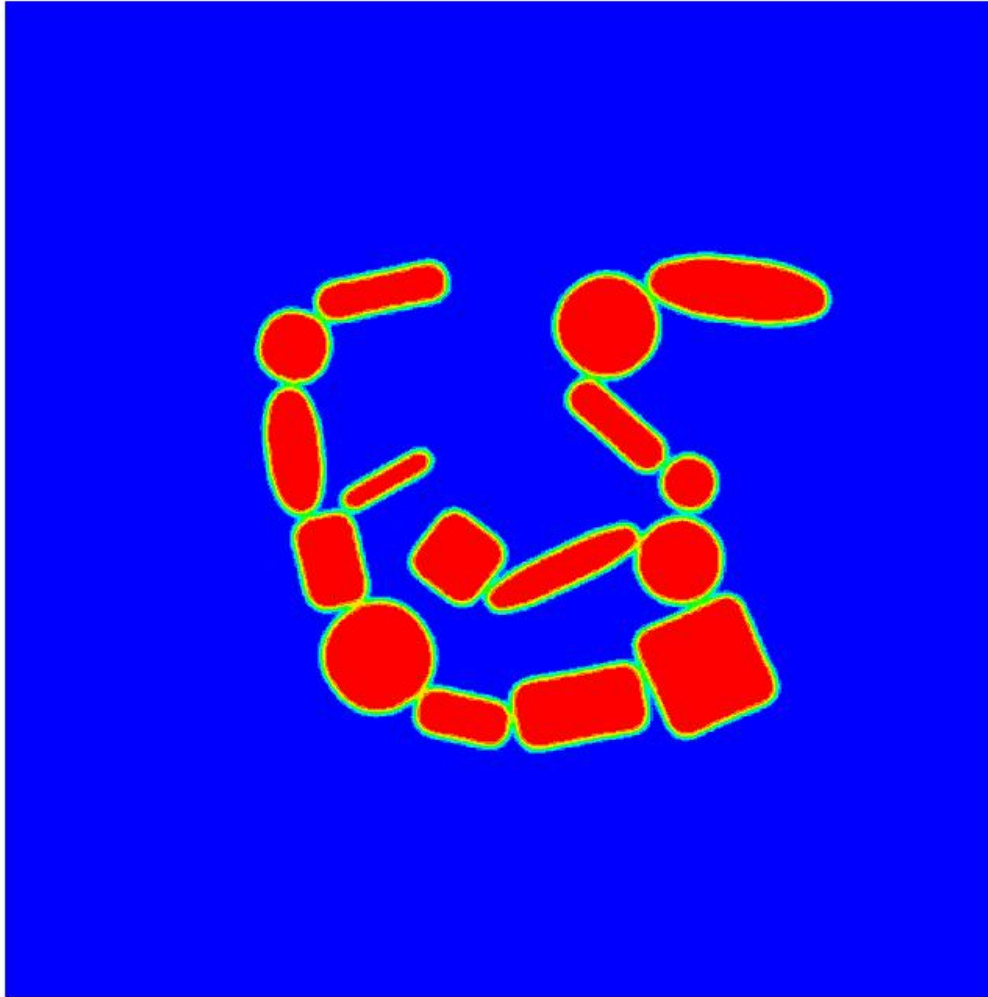
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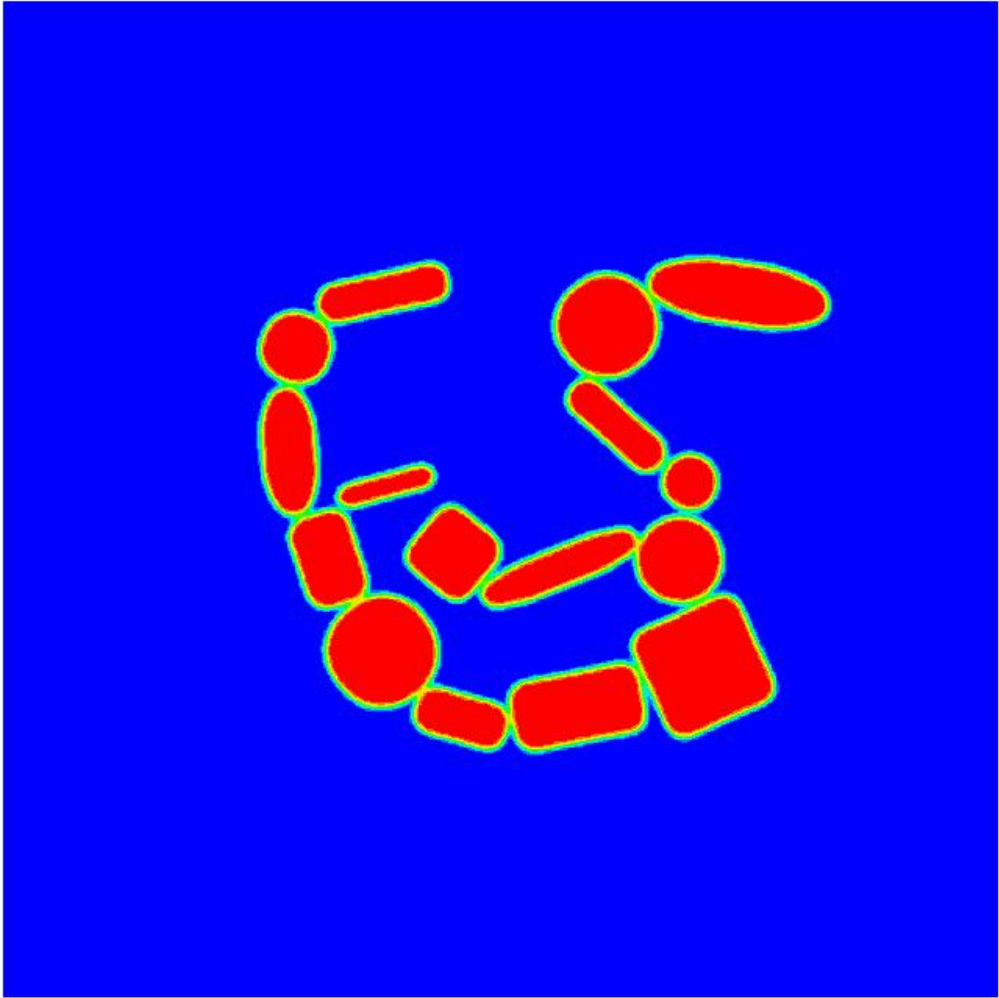
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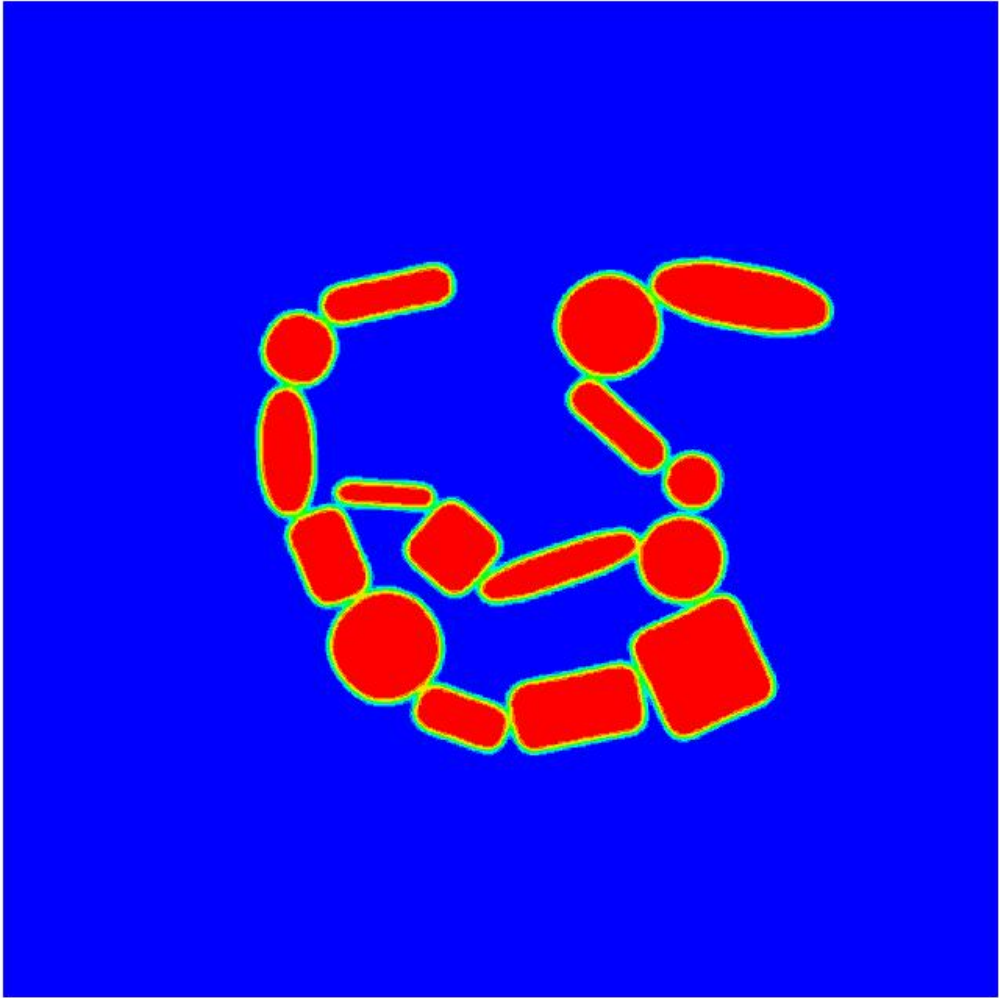
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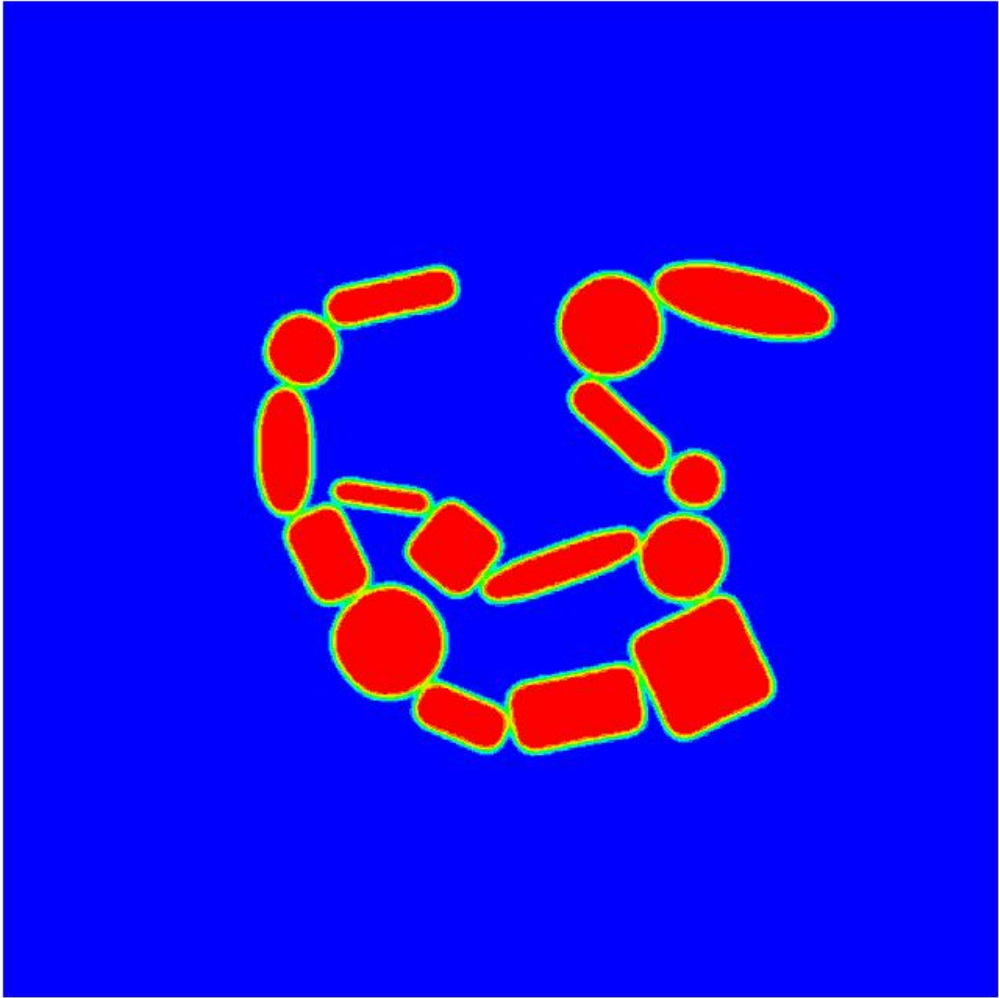
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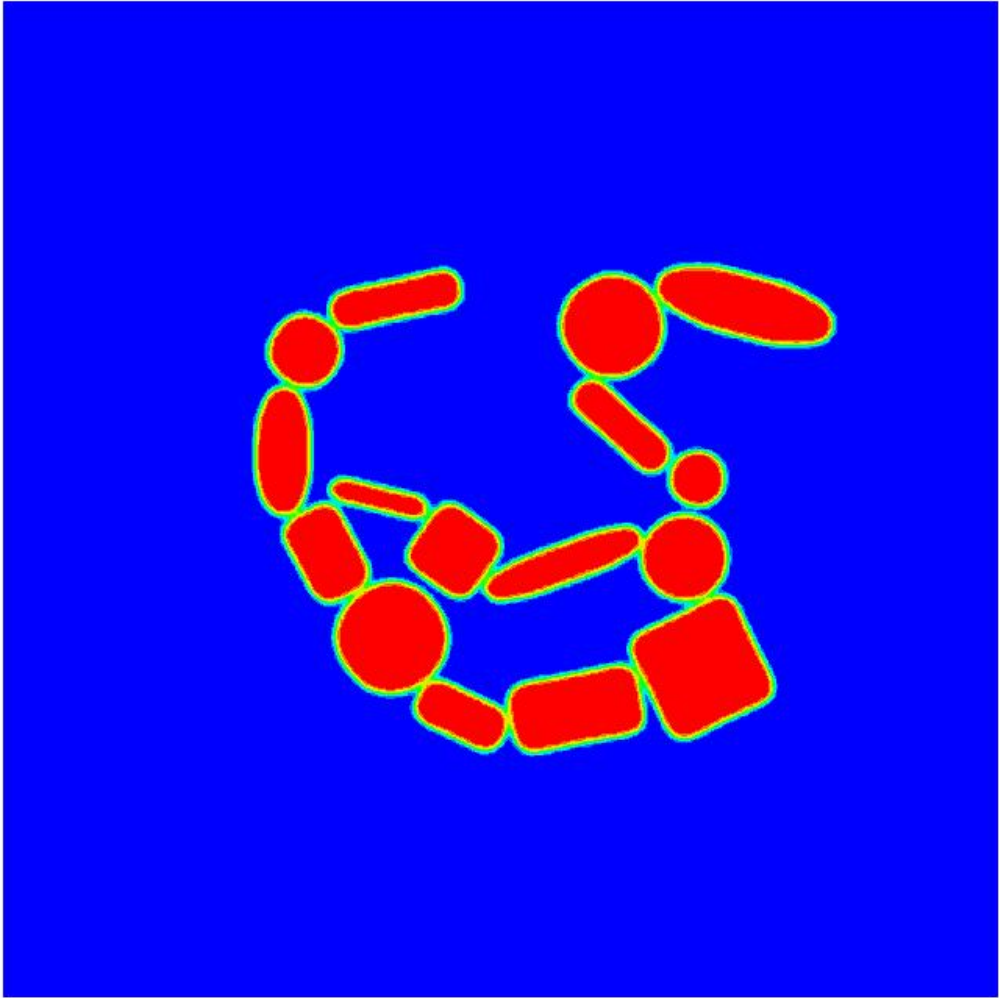
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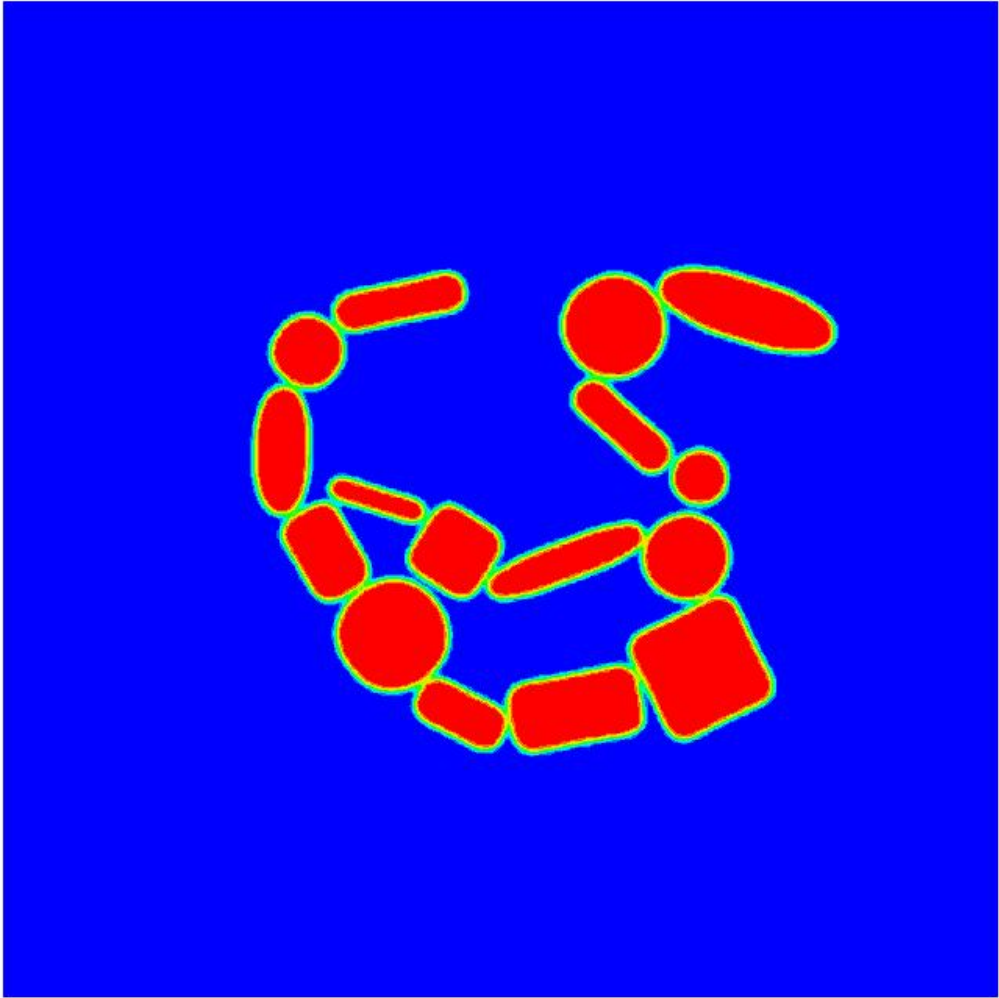
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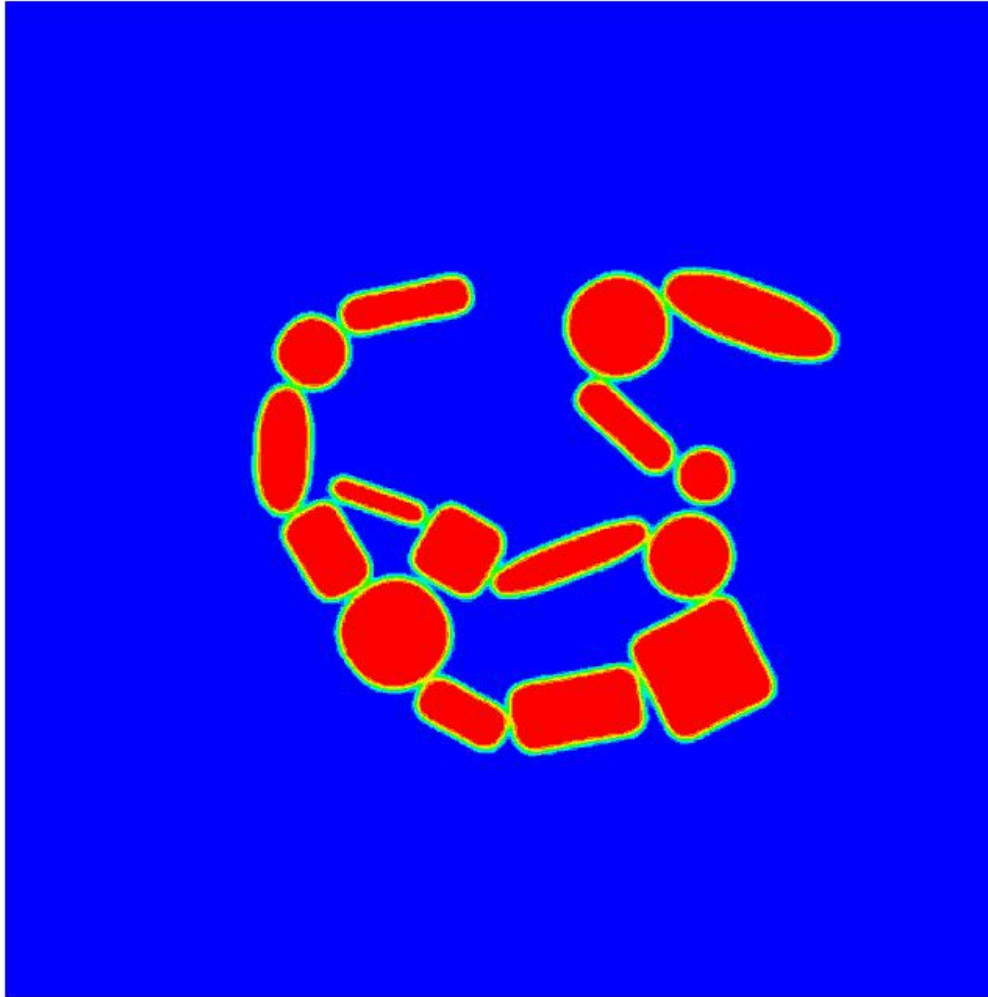
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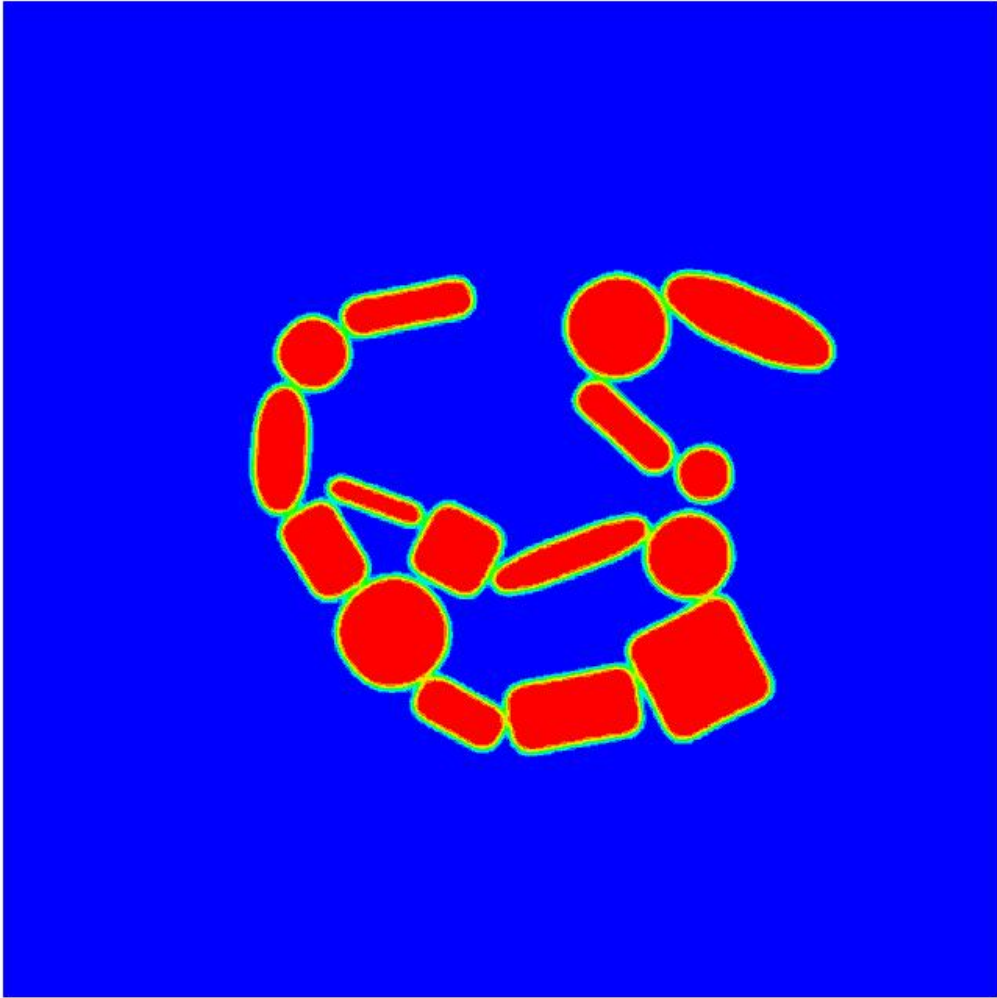
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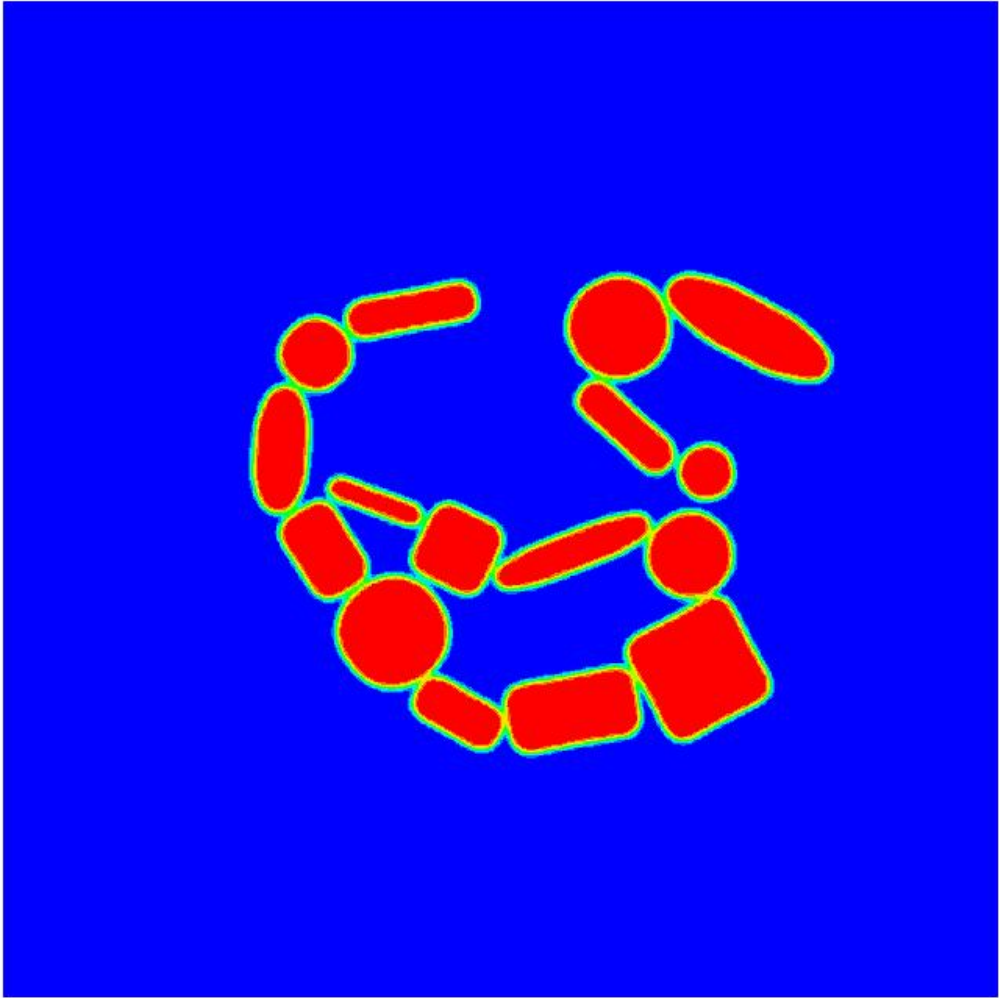
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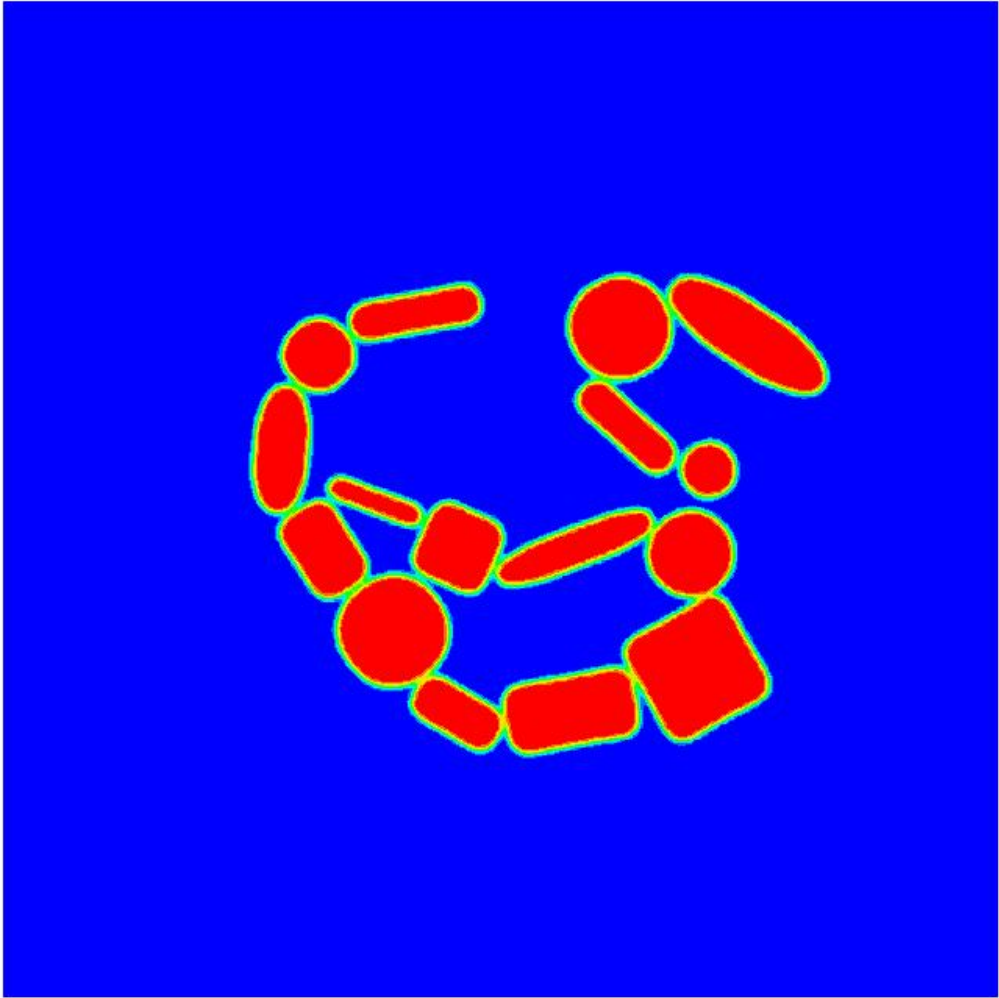
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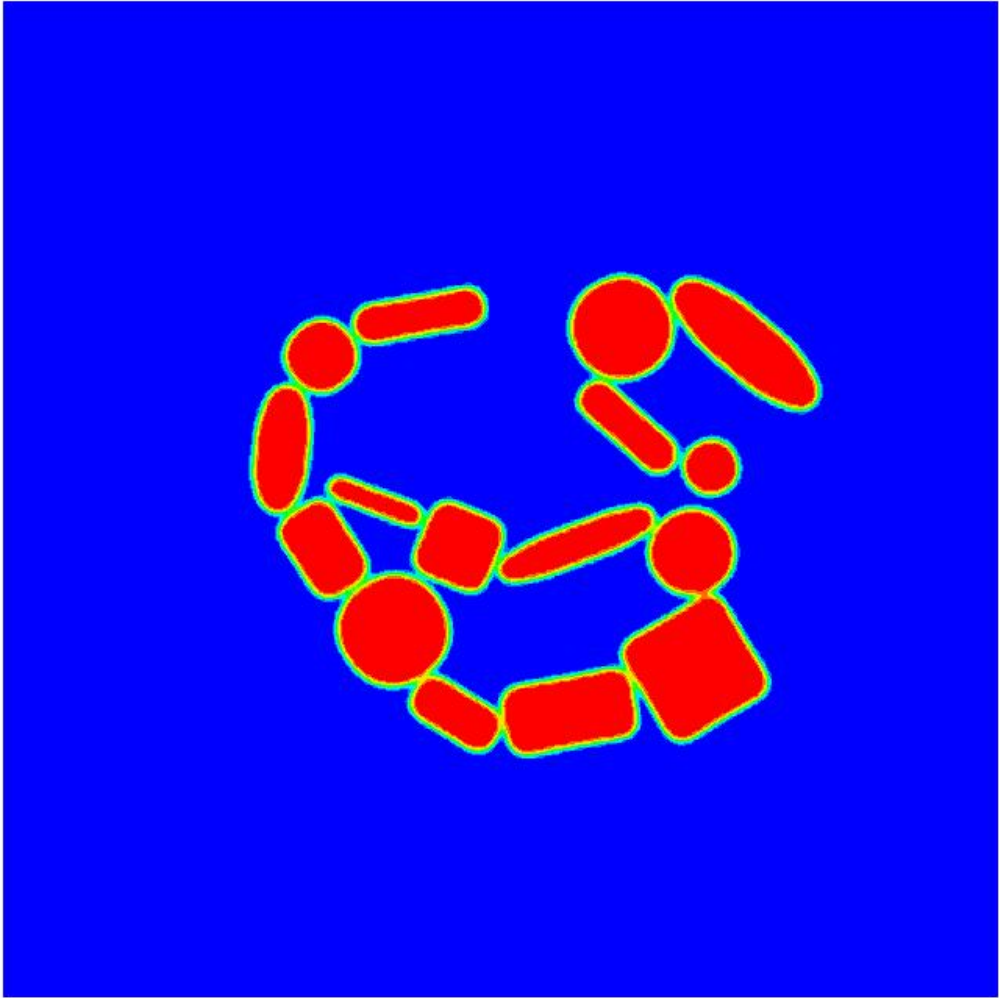
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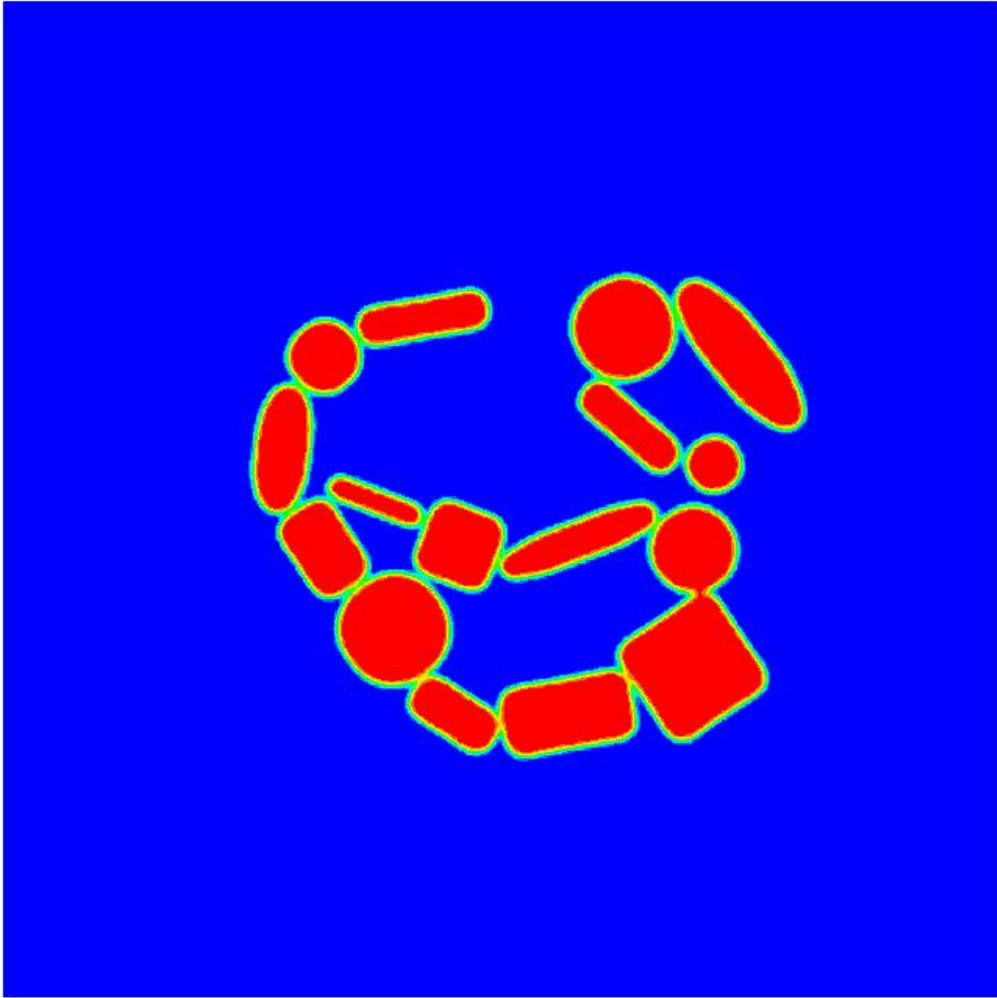
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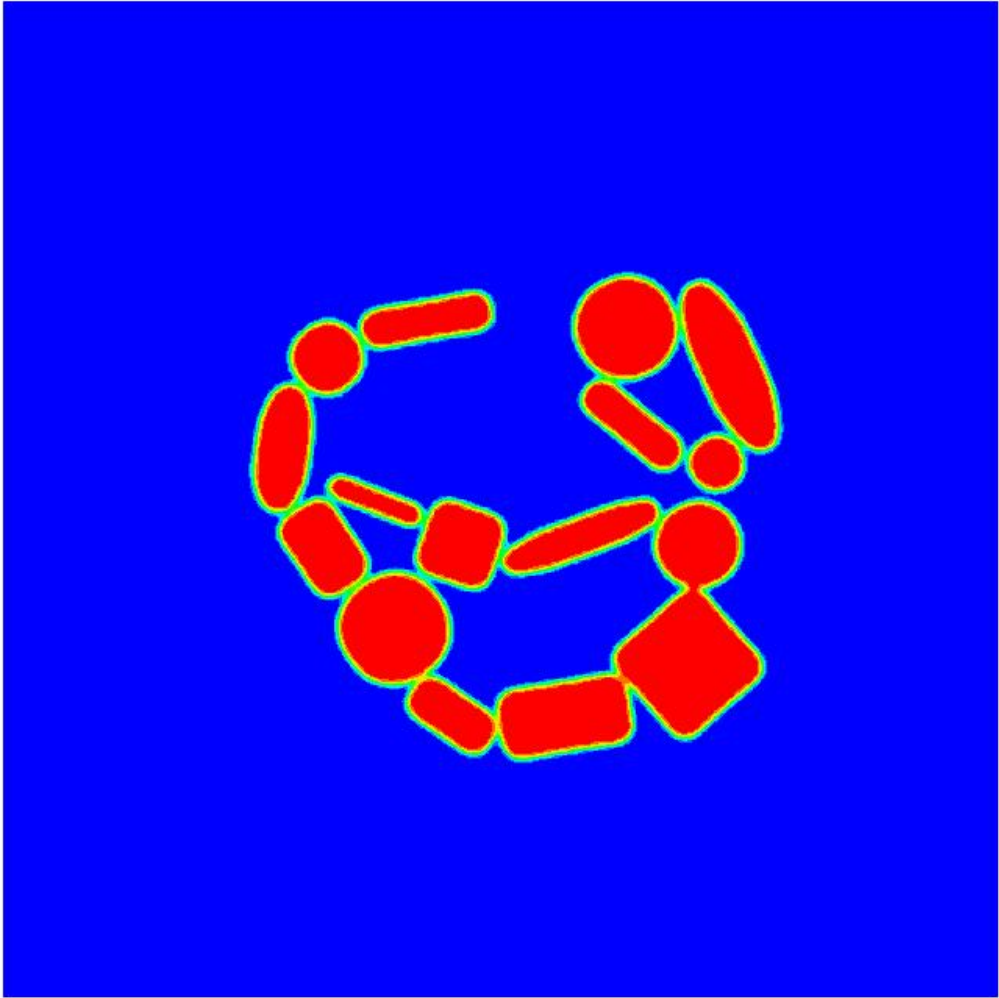
Self-Assembly of Arbitrary-Shaped Dipolar Particles



Self-Assembly of Arbitrary-Shaped Dipolar Particles

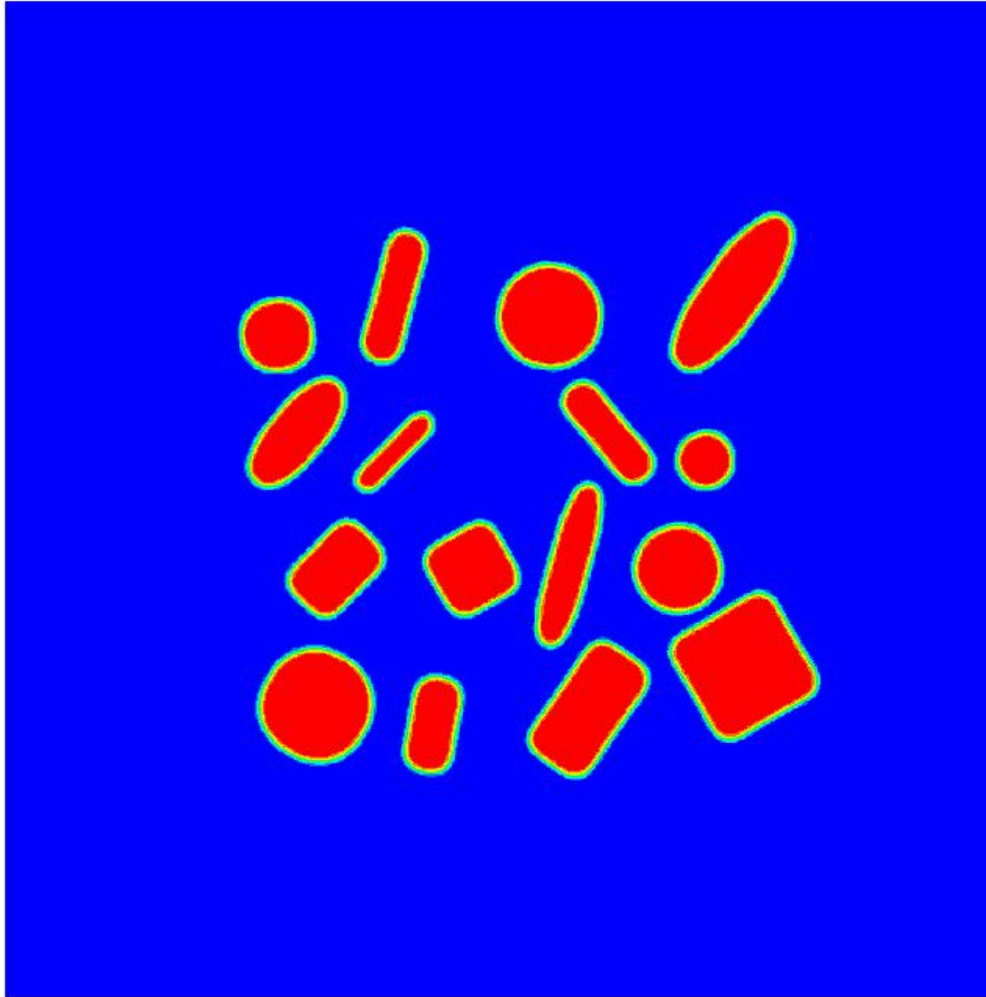


Self-Assembly of Arbitrary-Shaped Dipolar Particles

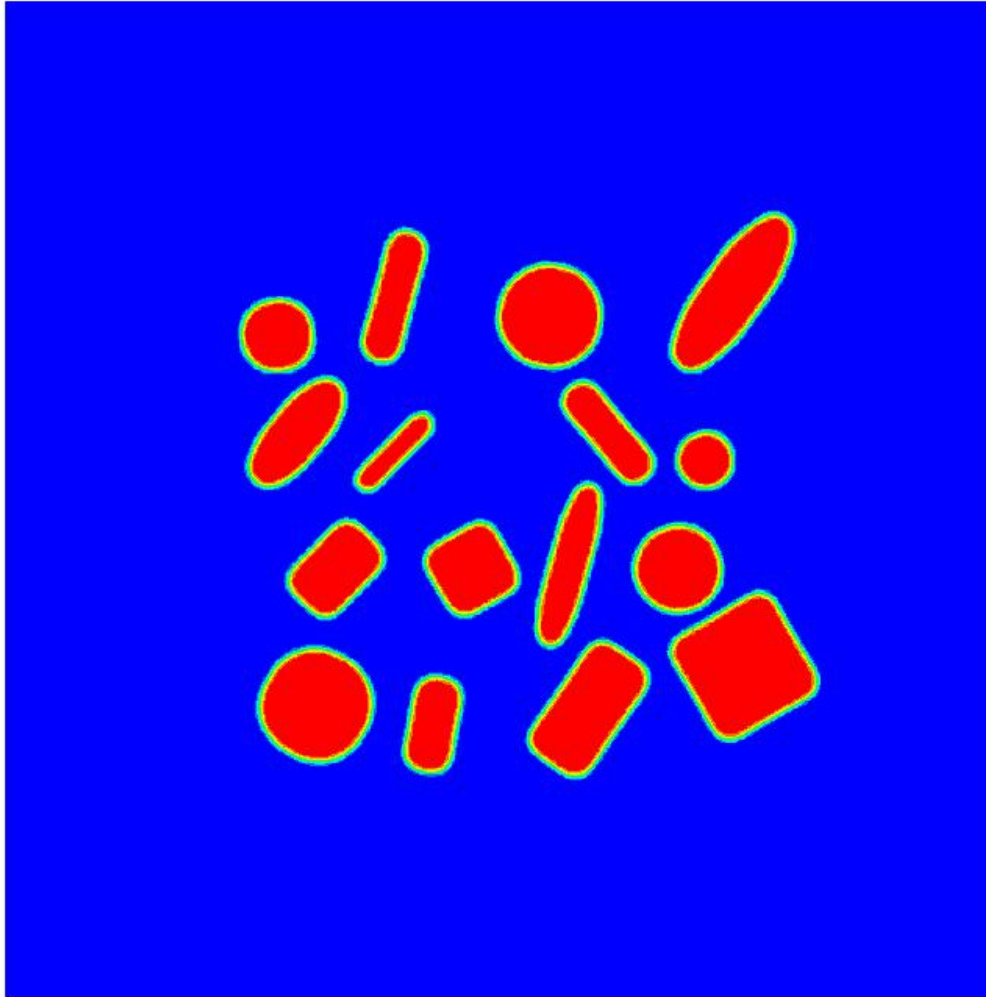
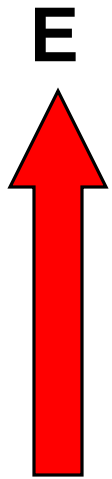


Simulation

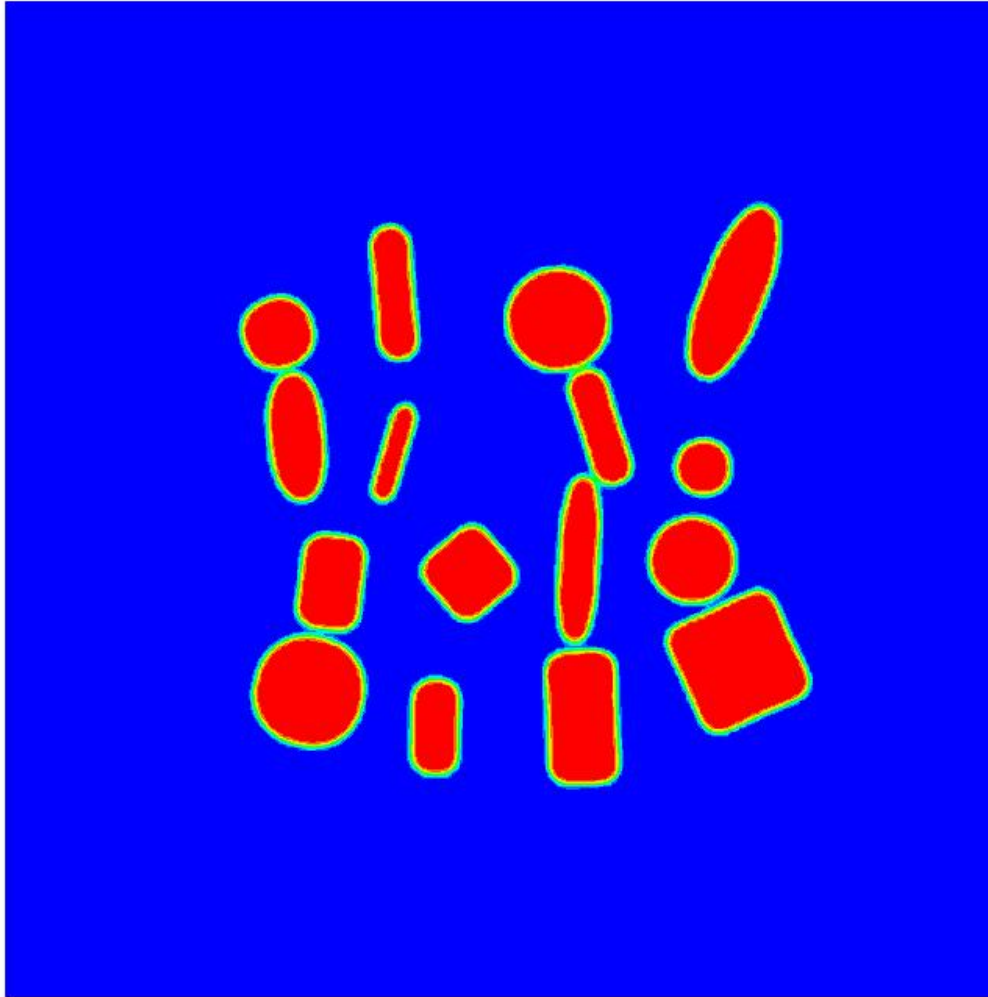
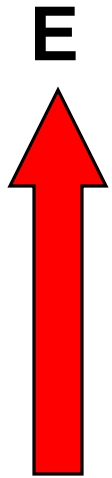
- Dipolar particles: field-directed self-assembly



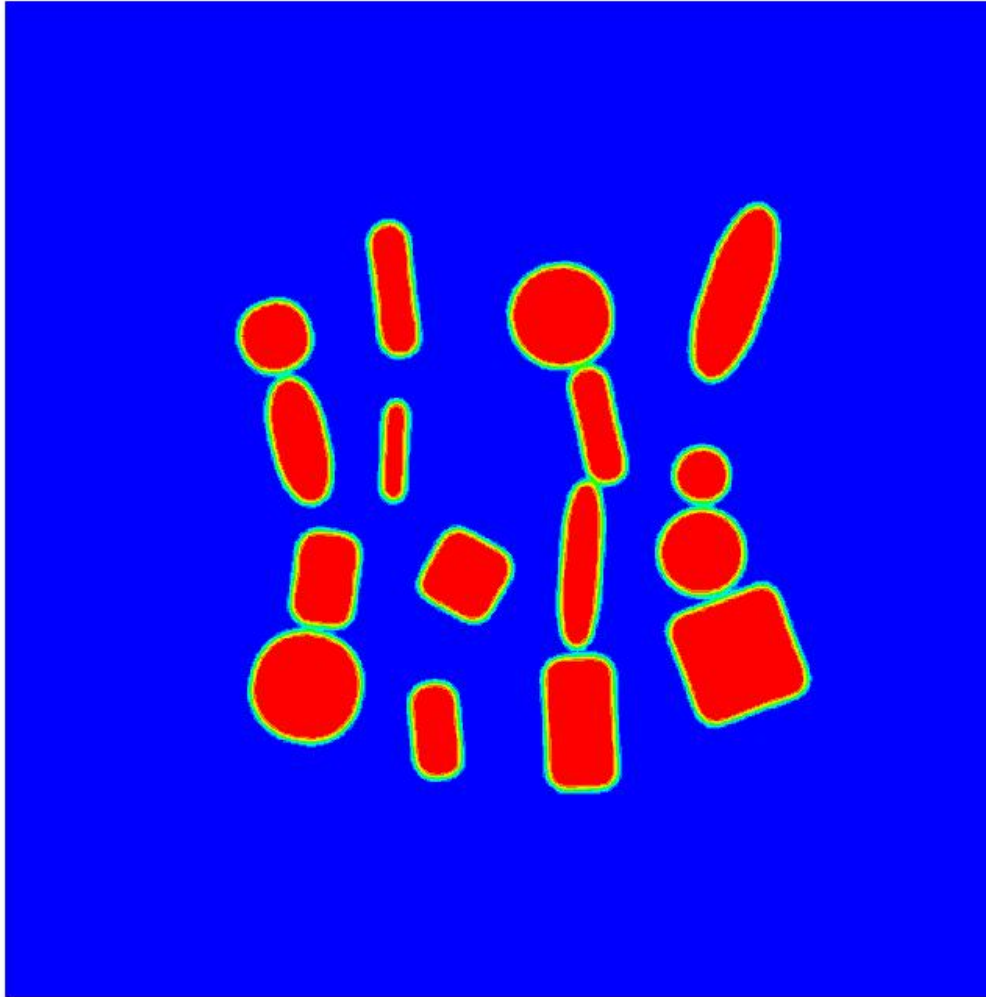
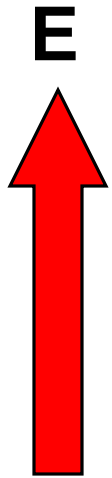
Self-Assembly of Arbitrary-Shaped Dipolar Particles



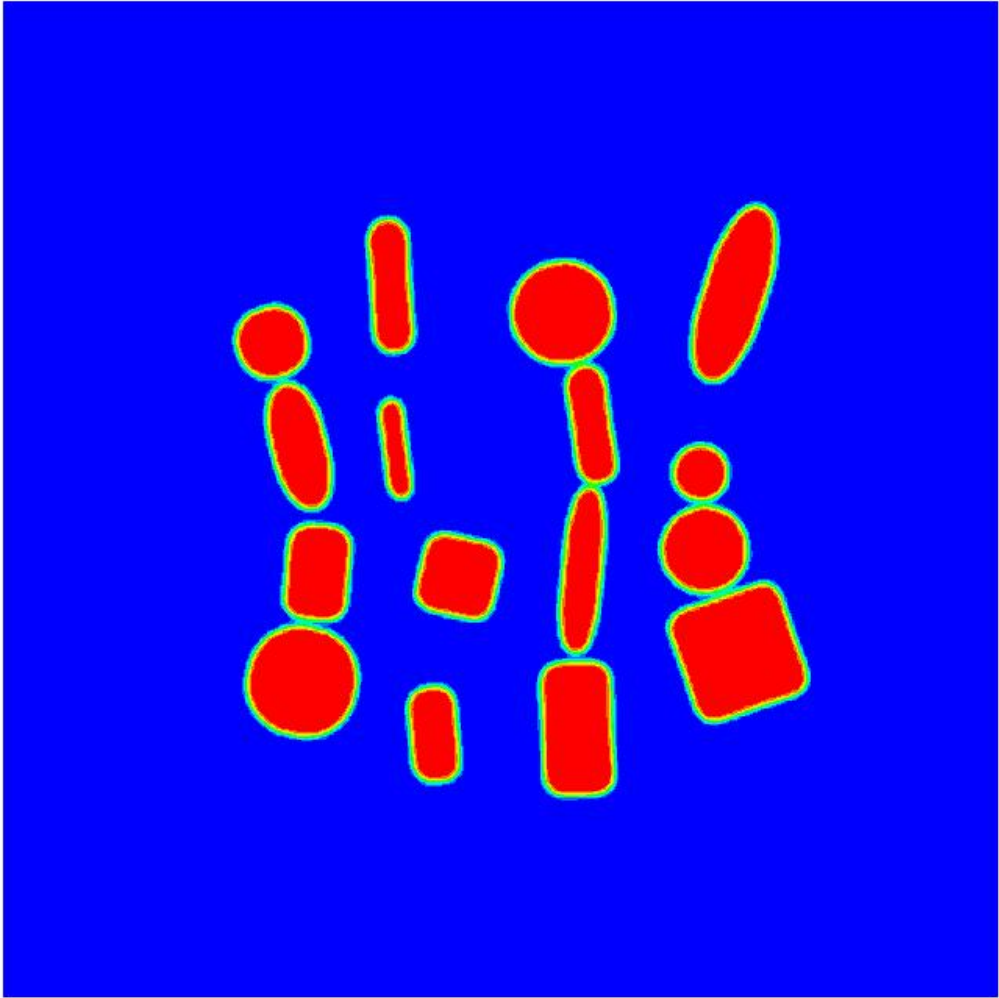
Self-Assembly of Arbitrary-Shaped Dipolar Particles



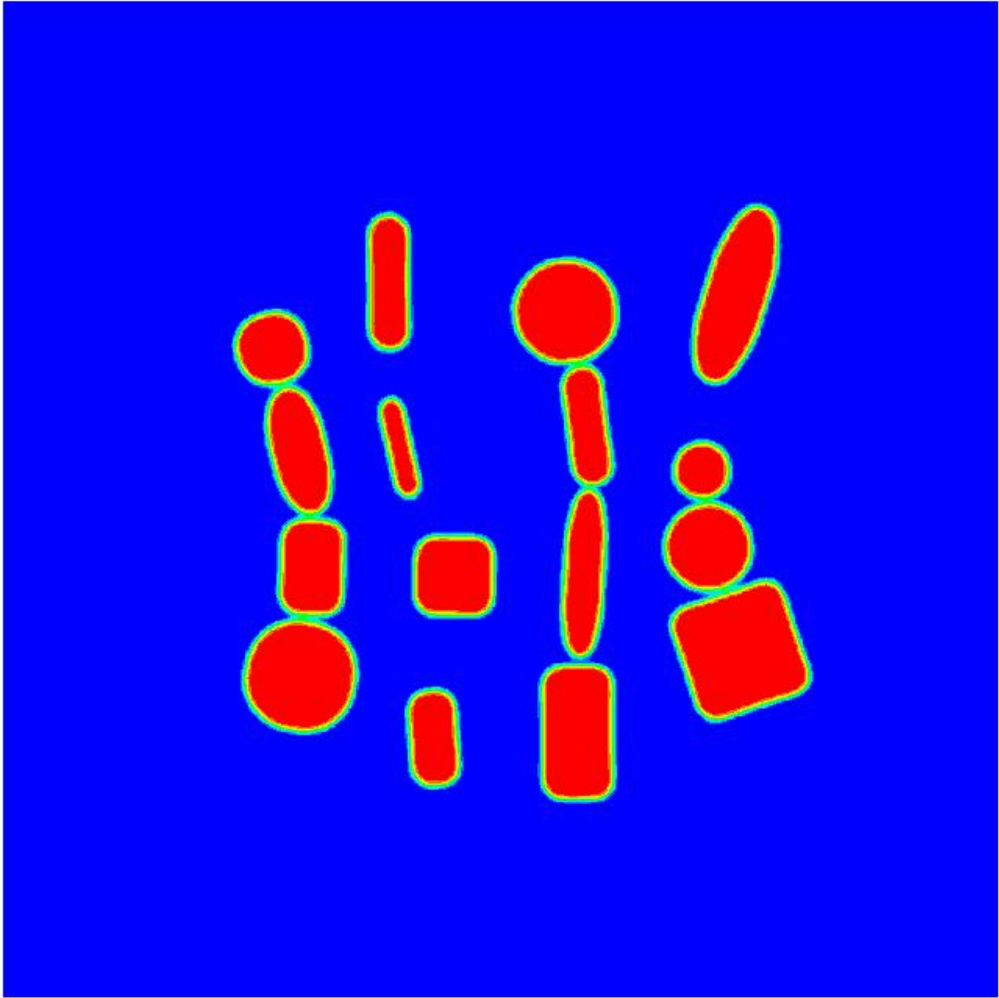
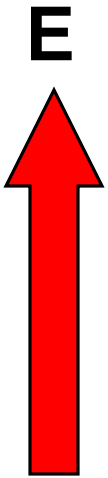
Self-Assembly of Arbitrary-Shaped Dipolar Particles



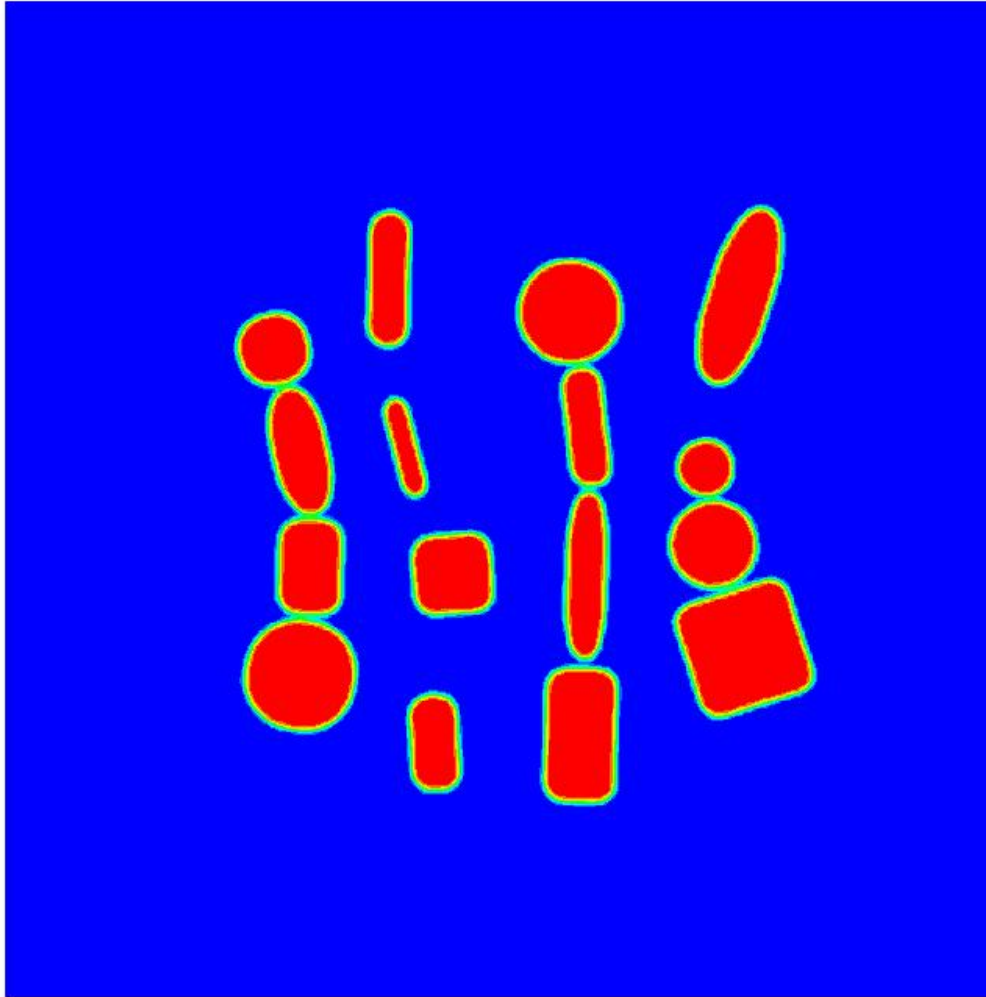
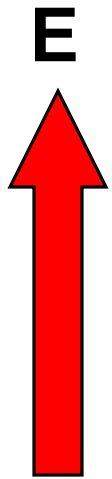
Self-Assembly of Arbitrary-Shaped Dipolar Particles



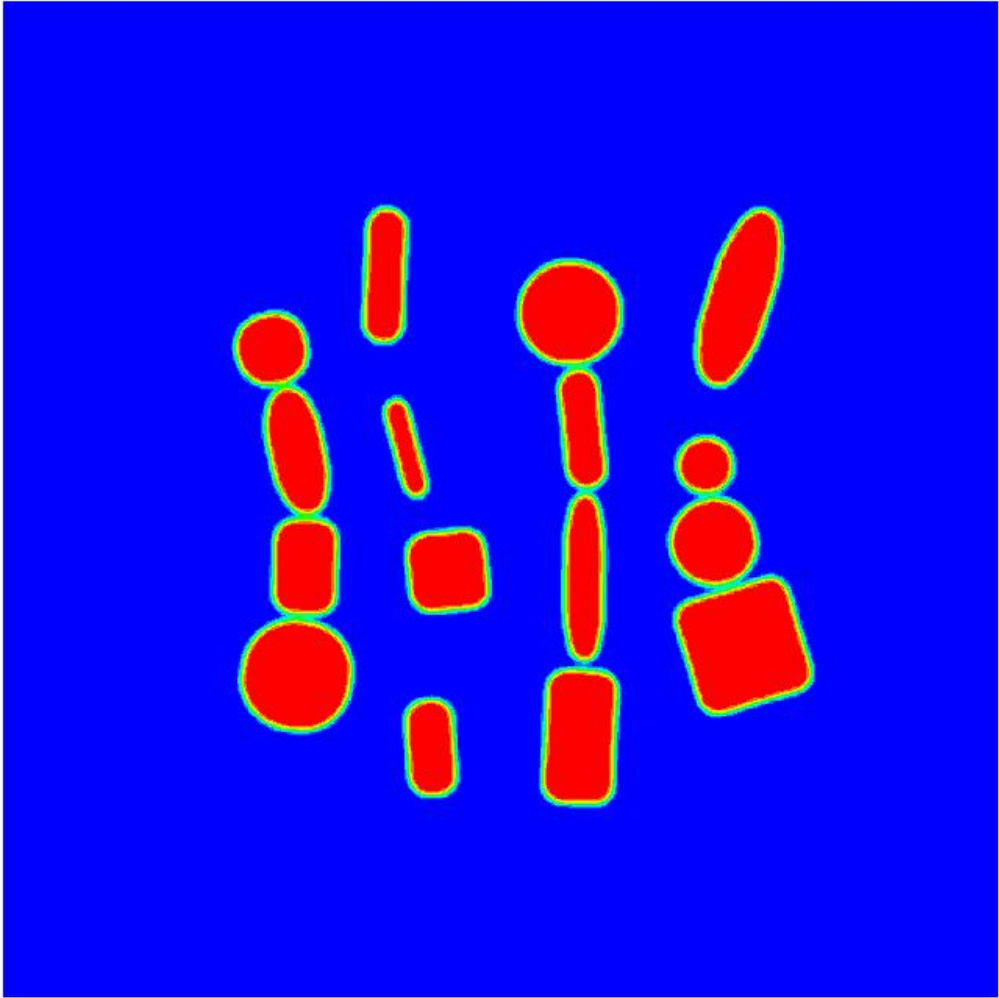
Self-Assembly of Arbitrary-Shaped Dipolar Particles



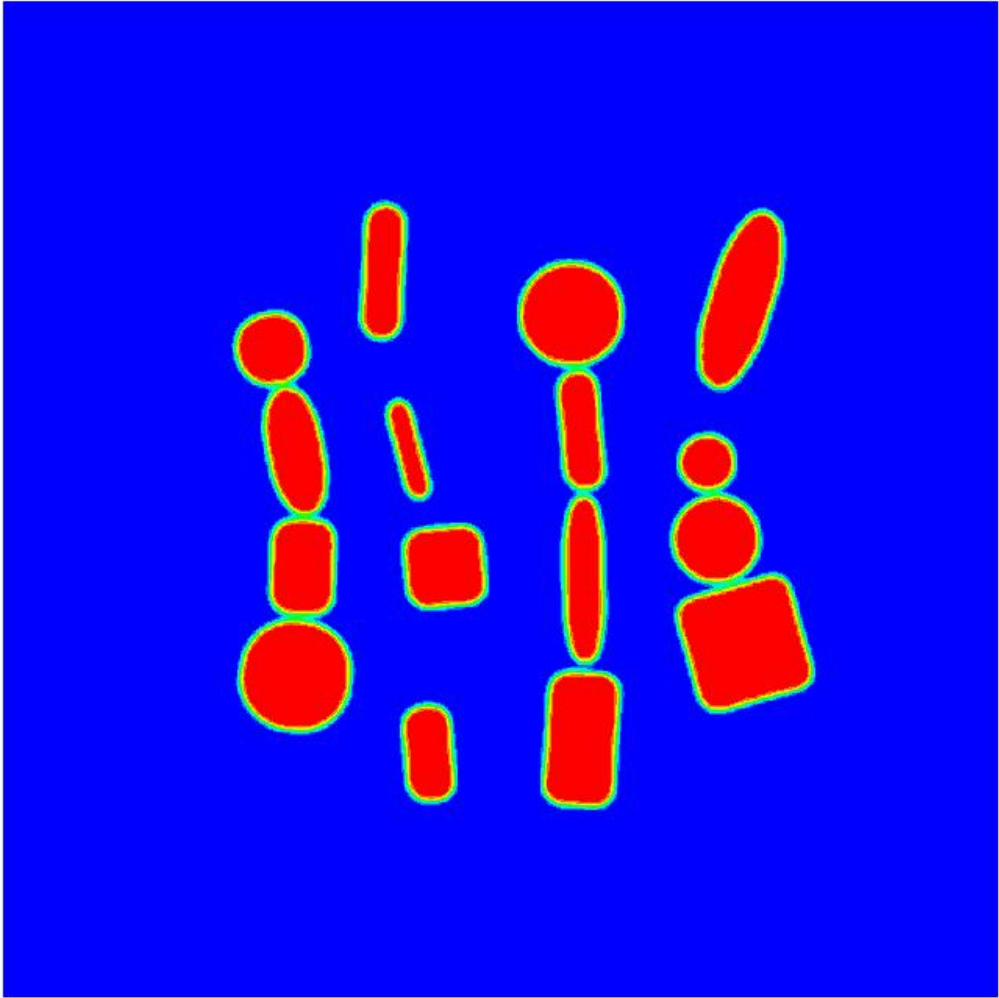
Self-Assembly of Arbitrary-Shaped Dipolar Particles



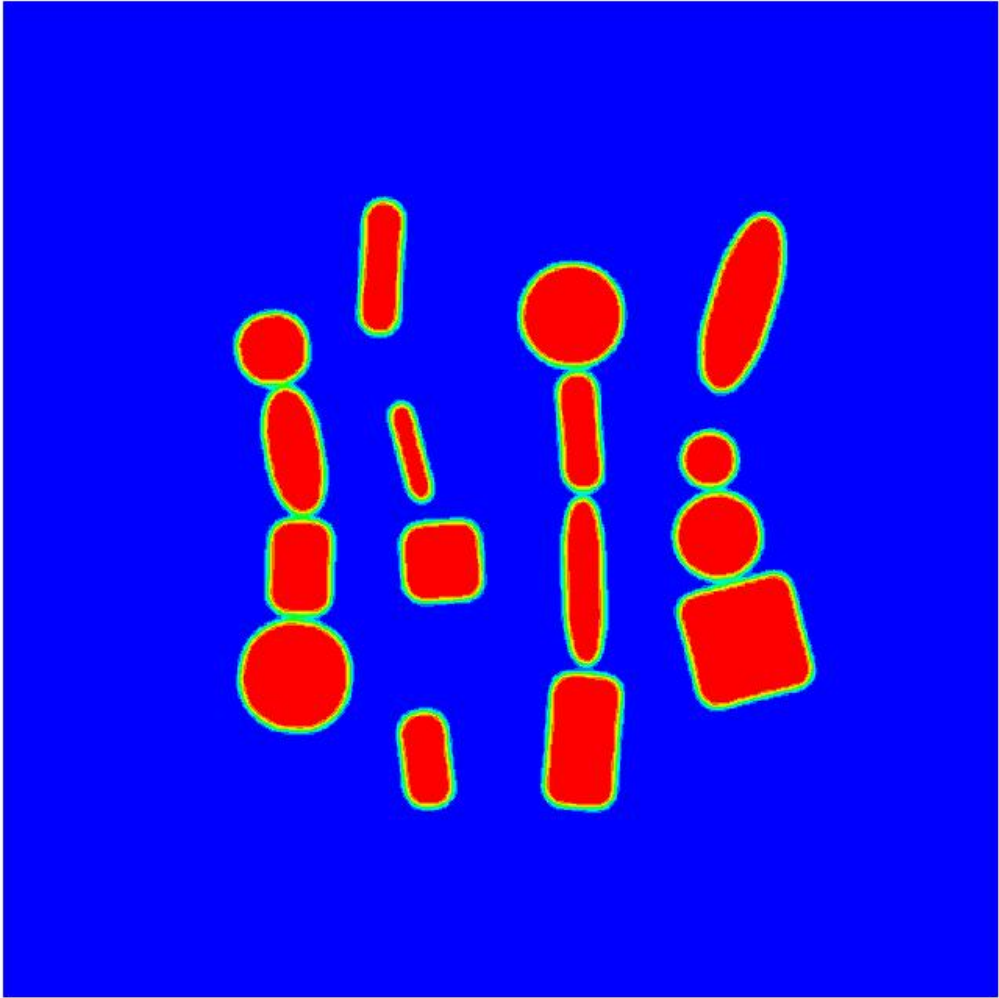
Self-Assembly of Arbitrary-Shaped Dipolar Particles



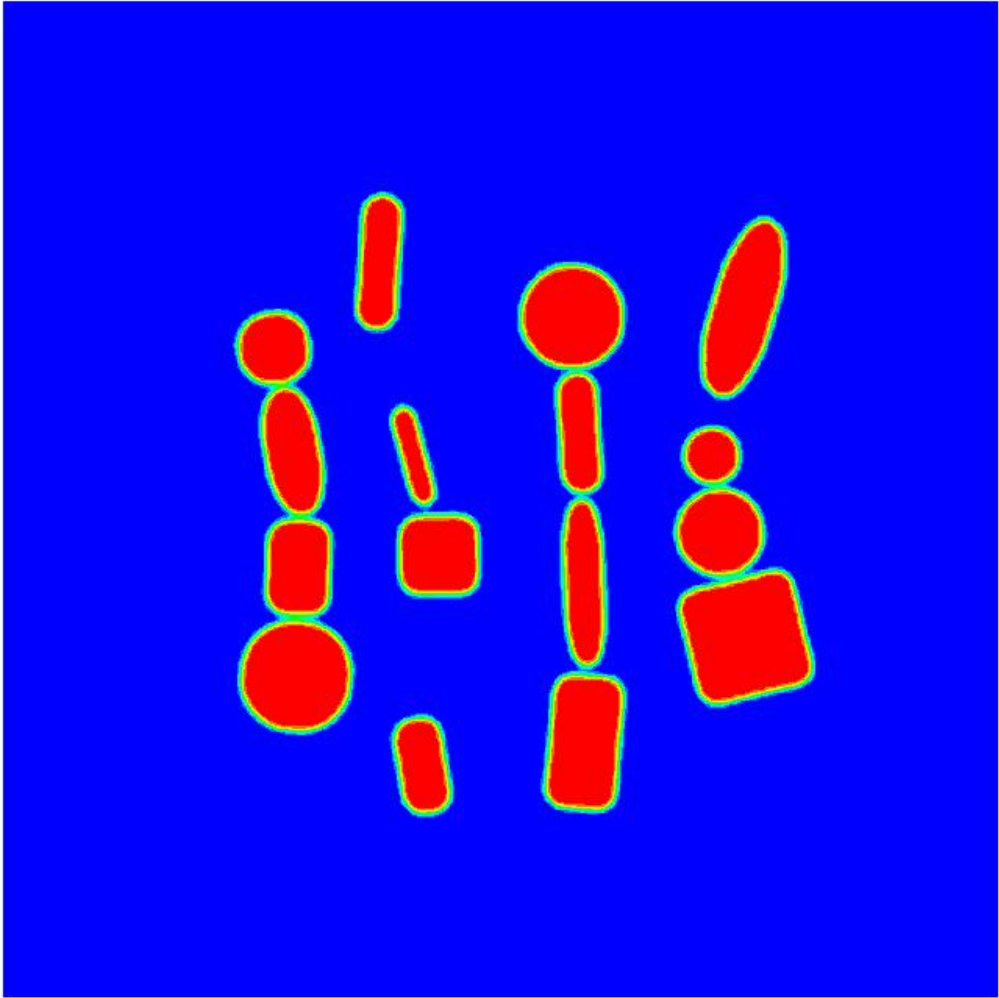
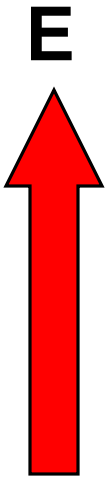
Self-Assembly of Arbitrary-Shaped Dipolar Particles



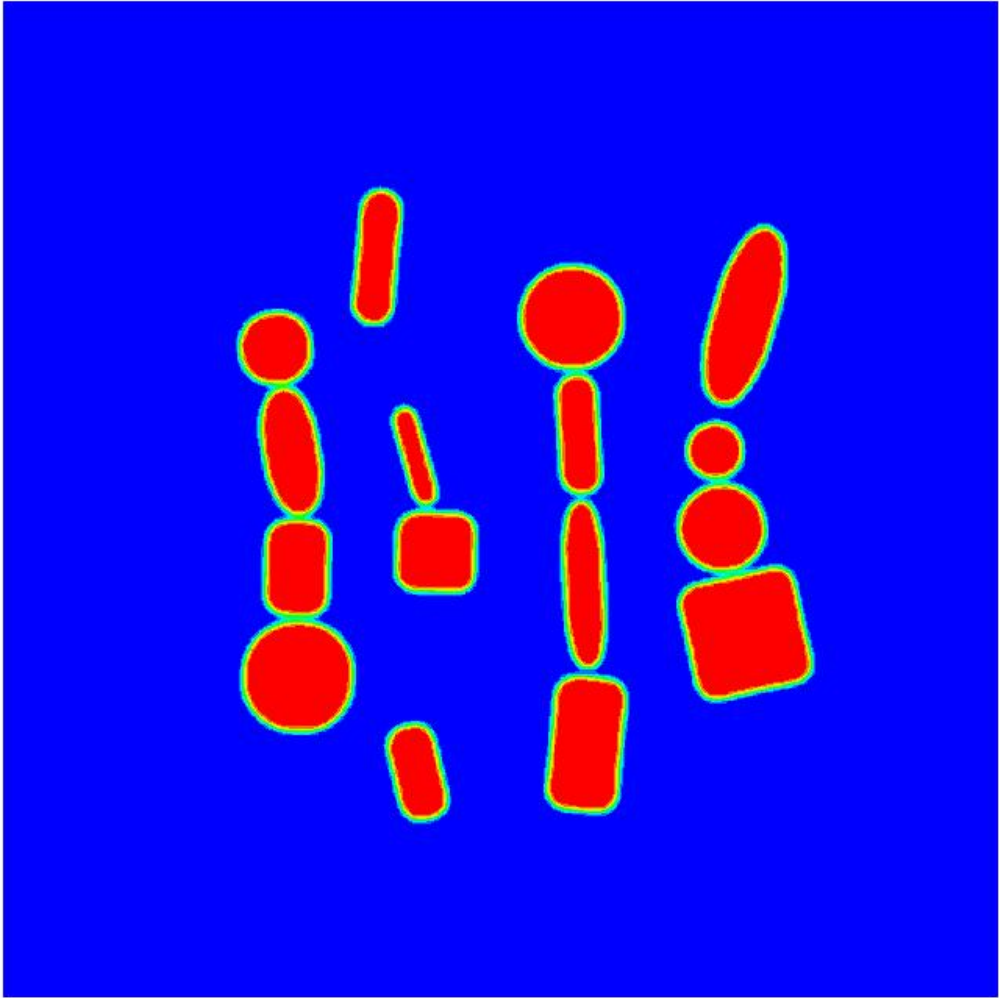
Self-Assembly of Arbitrary-Shaped Dipolar Particles



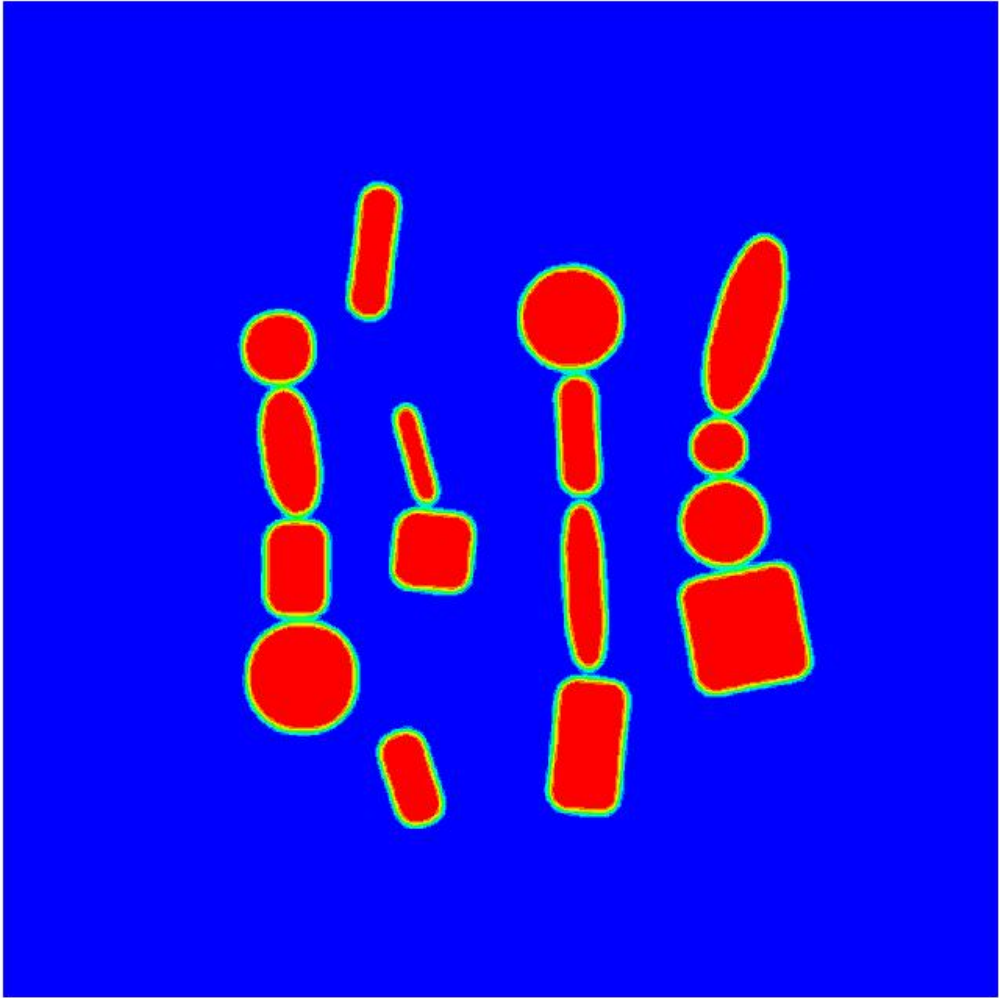
Self-Assembly of Arbitrary-Shaped Dipolar Particles



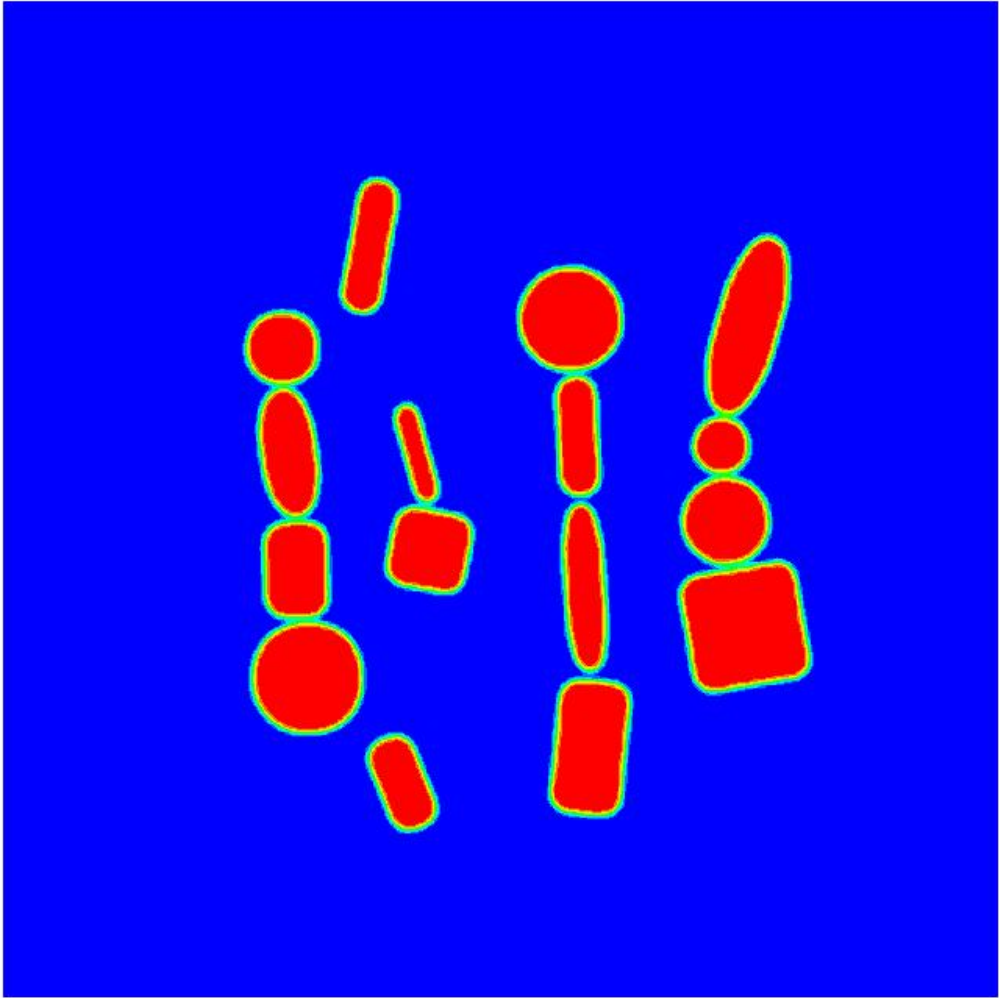
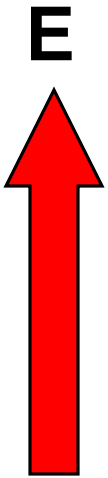
Self-Assembly of Arbitrary-Shaped Dipolar Particles



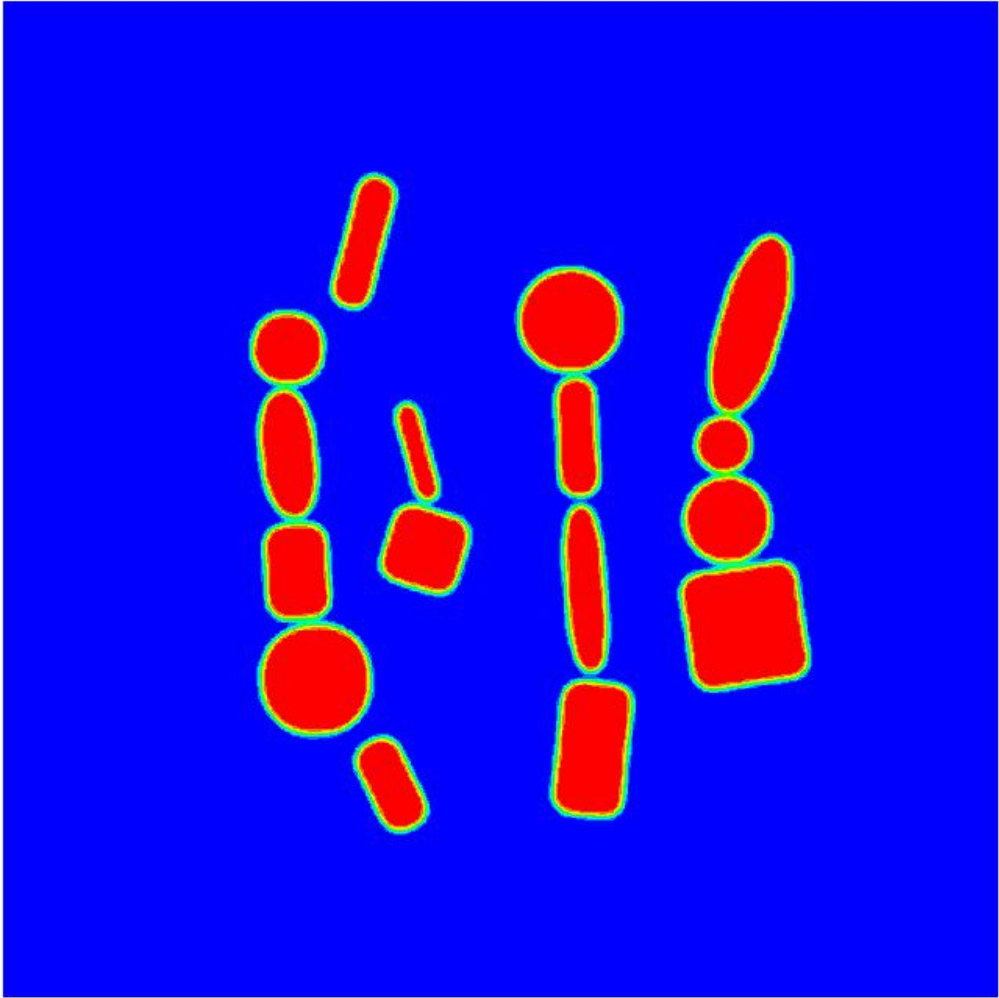
Self-Assembly of Arbitrary-Shaped Dipolar Particles



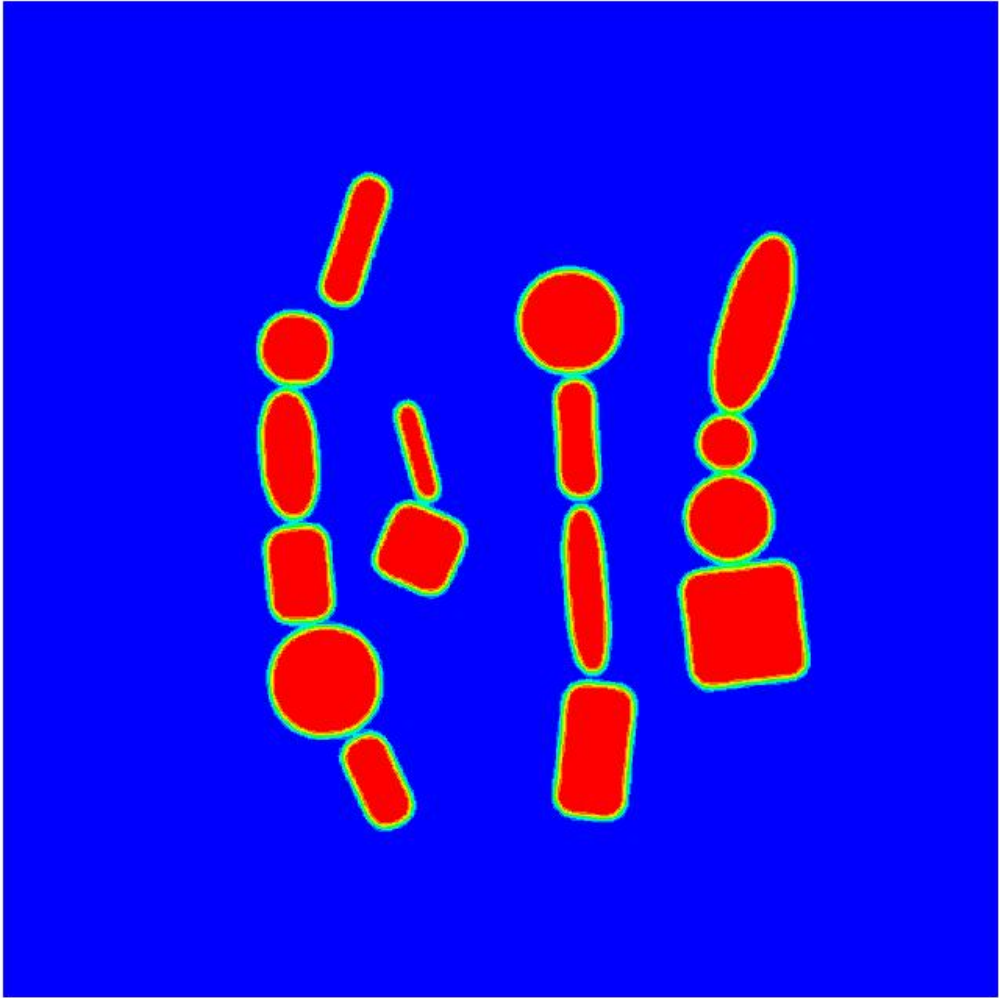
Self-Assembly of Arbitrary-Shaped Dipolar Particles



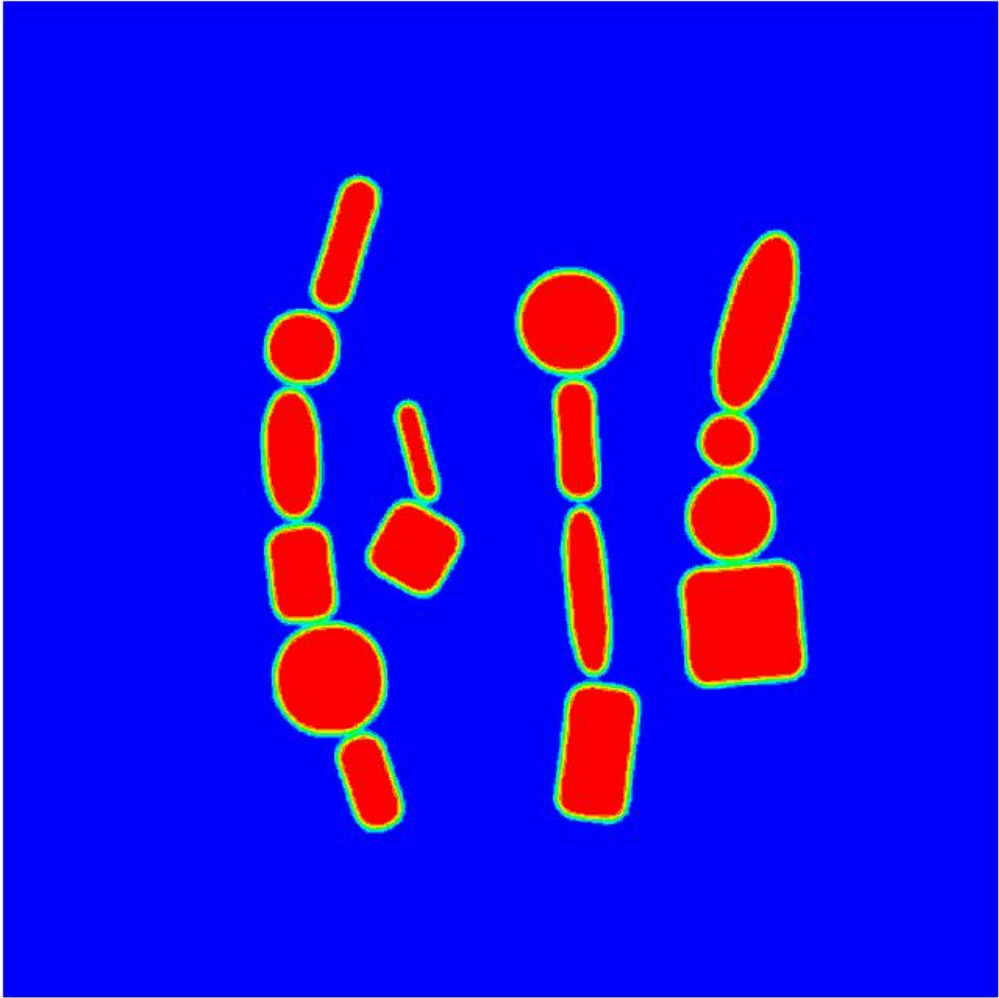
Self-Assembly of Arbitrary-Shaped Dipolar Particles



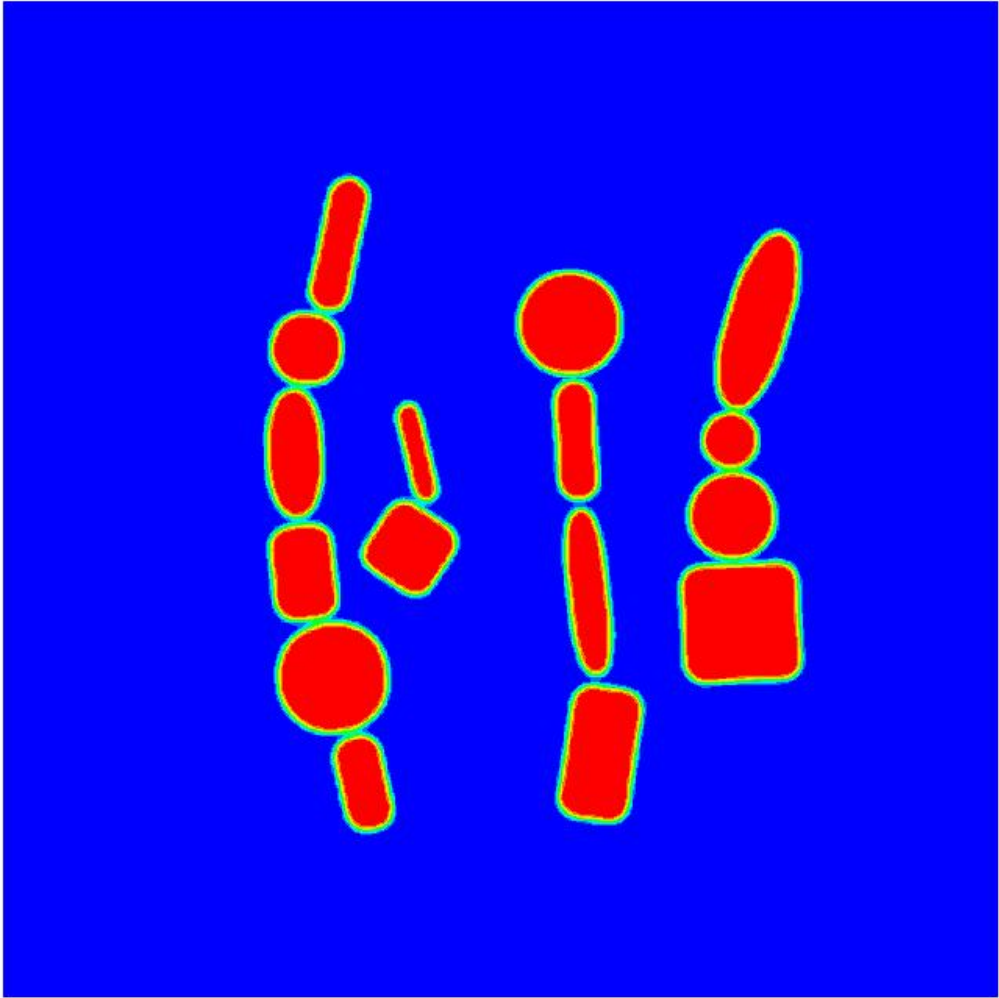
Self-Assembly of Arbitrary-Shaped Dipolar Particles



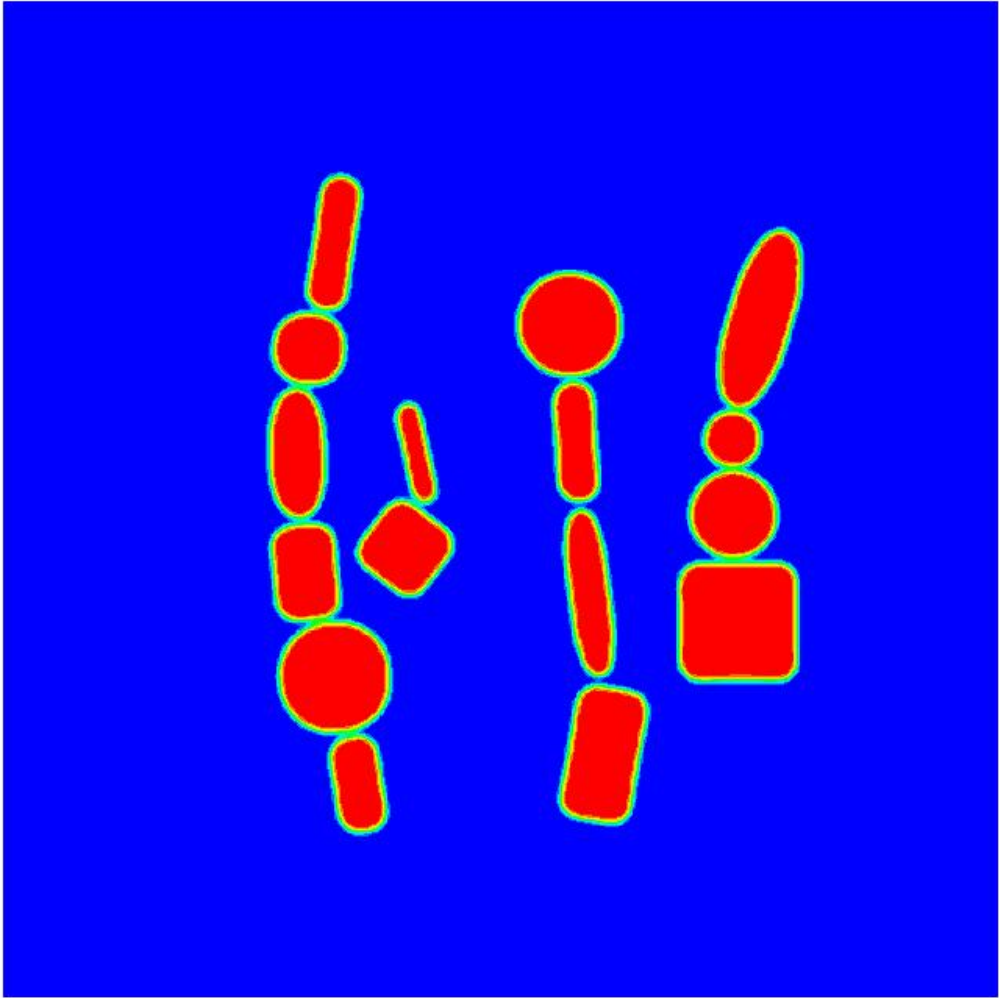
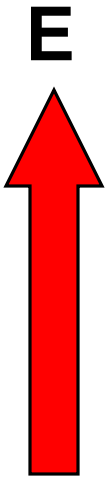
Self-Assembly of Arbitrary-Shaped Dipolar Particles



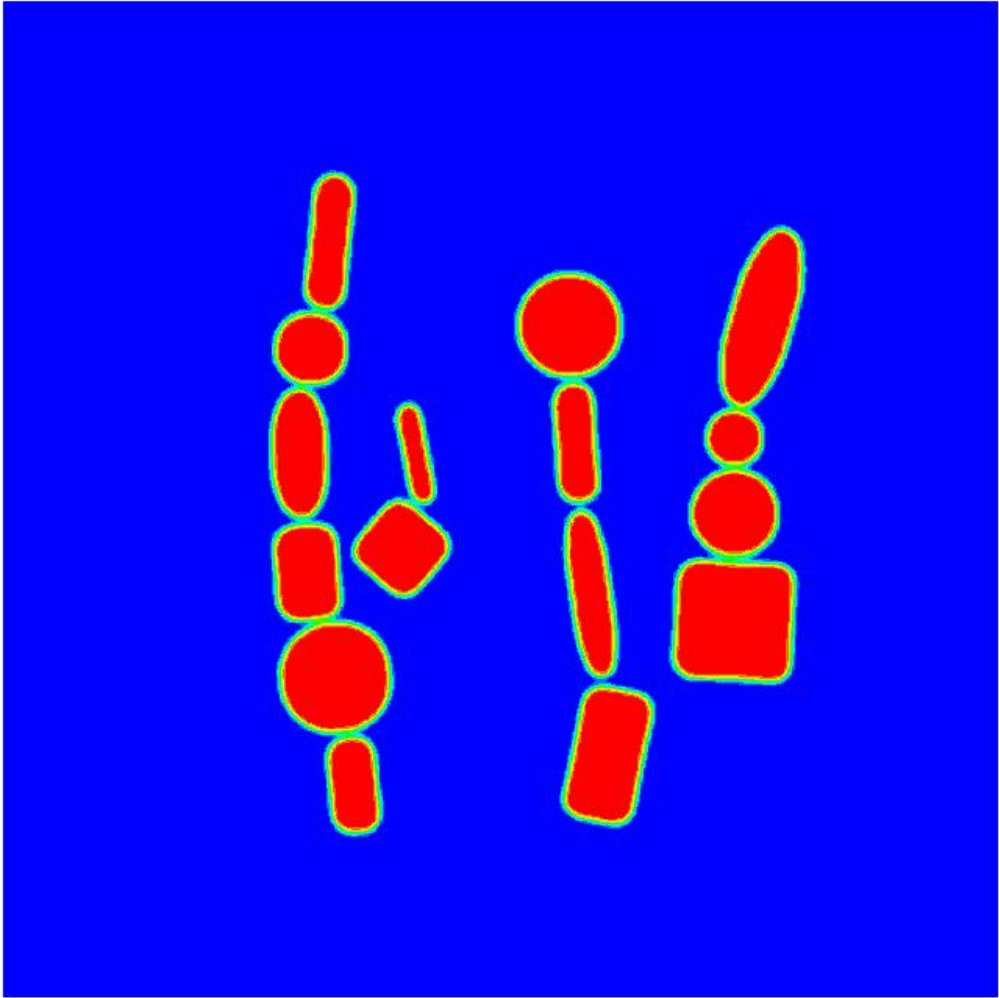
Self-Assembly of Arbitrary-Shaped Dipolar Particles



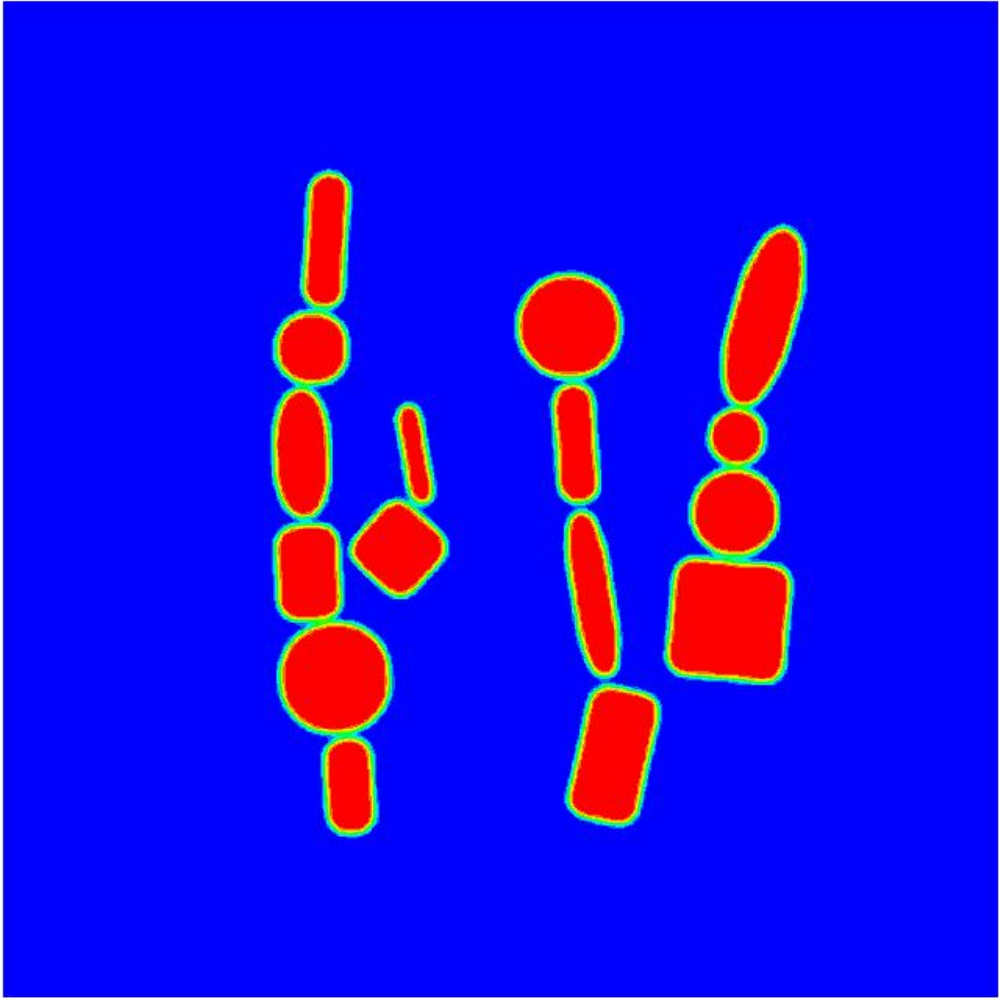
Self-Assembly of Arbitrary-Shaped Dipolar Particles



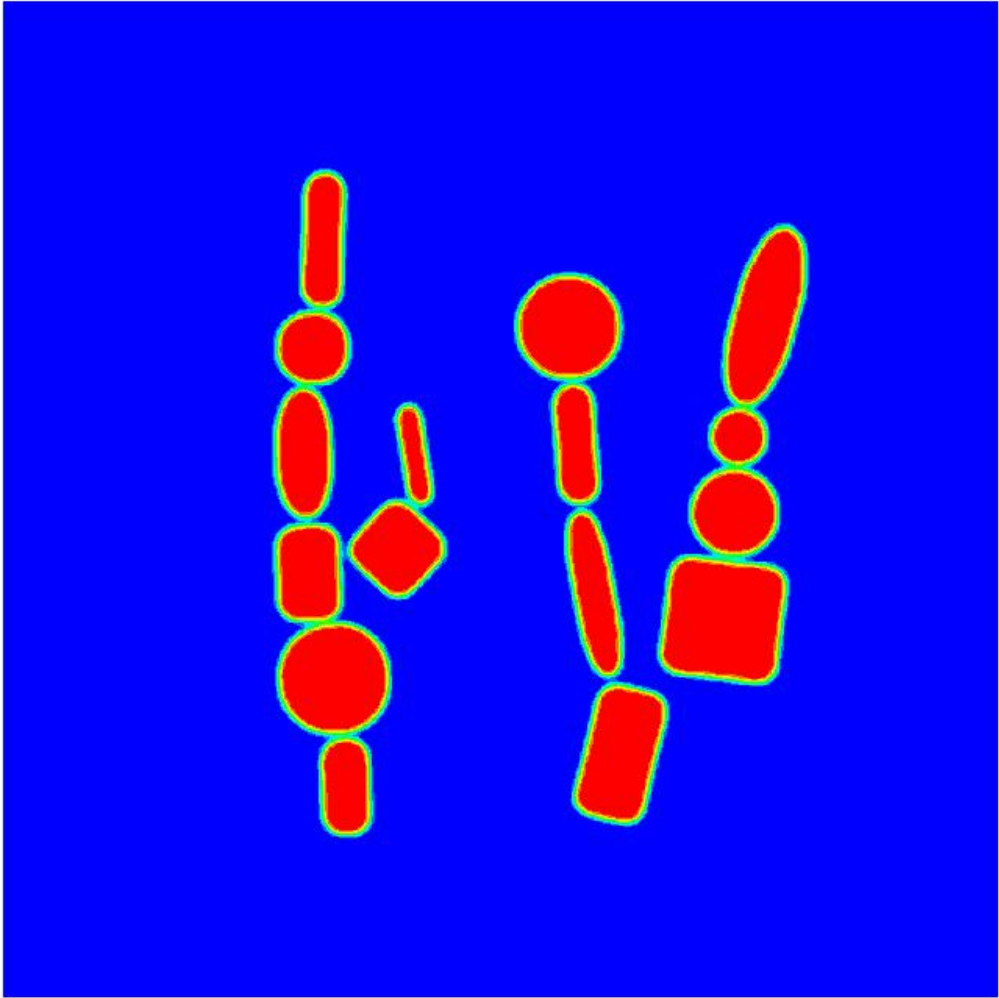
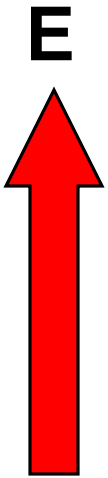
Self-Assembly of Arbitrary-Shaped Dipolar Particles



Self-Assembly of Arbitrary-Shaped Dipolar Particles

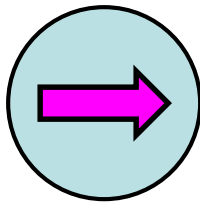


Self-Assembly of Arbitrary-Shaped Dipolar Particles

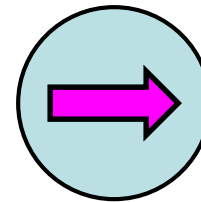
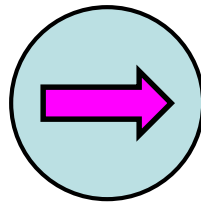


Processing-Microstructure Relationship

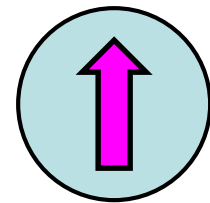
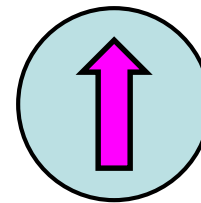
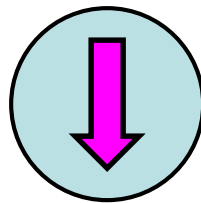
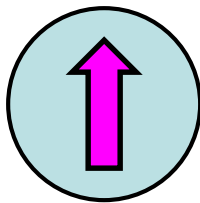
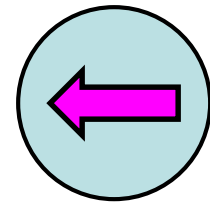
- Mechanisms of Filler Particle Self-Assembly
 - Strongly anisotropic force that can be tuned by external field
 - Rigid-body motion (translation and rotation) of colloidal particles in liquids (water, organic solvent, polymer melt, etc.)



attraction

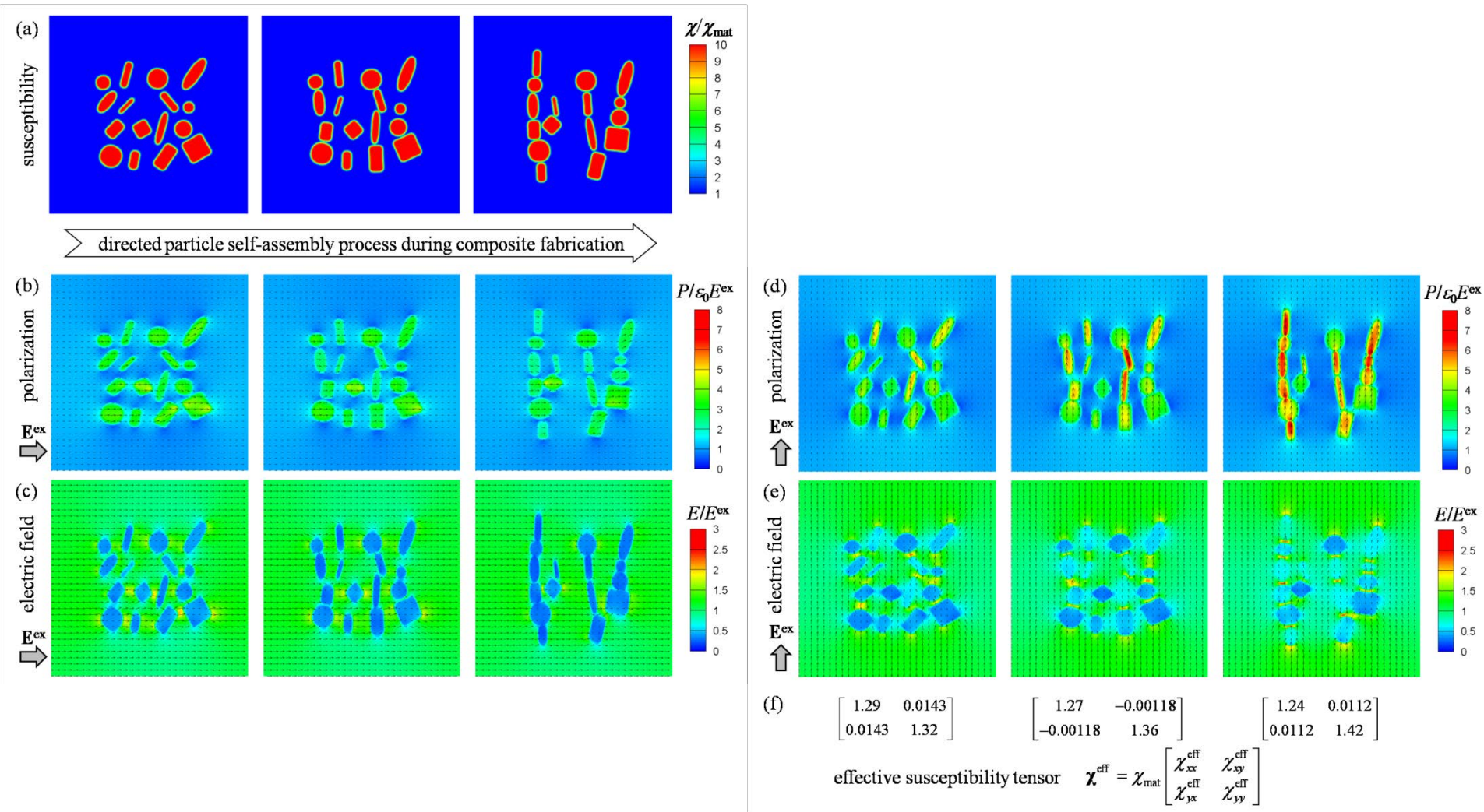


repulsion



Simulation

Phase field model of dielectric/magnetic composites



Particle-Filled Polymer-Matrix Composites

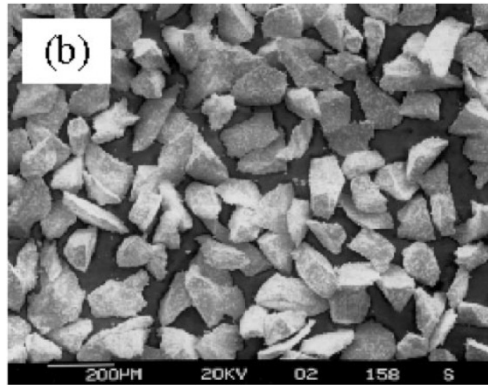
□ Alignment of irregular-shaped functional filler particles

Dielectric: PZT fillers

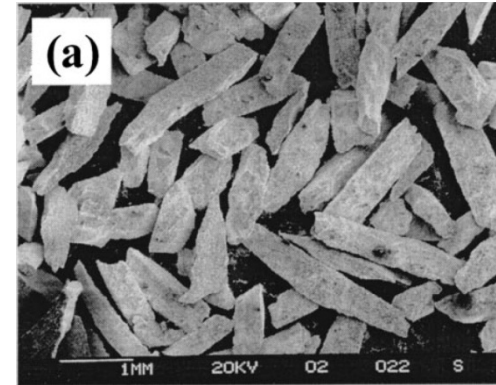
Electro-Optic: PbTiO_3 nanoparticles

Magnetostrictive: Terfenol-D particles

equiaxed
irregular



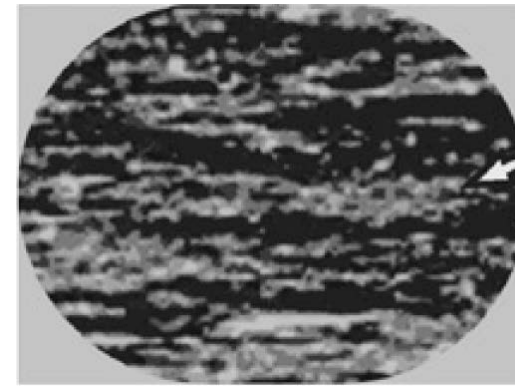
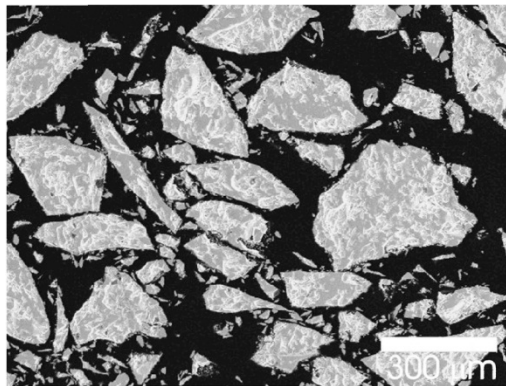
Duenas et al, *J. Appl. Phys.*, **90**, 2433, 2001.



needle-shaped
irregular

Or et al, *J. Appl. Phys.*, **93**, 8510, 2003.

random



aligned

Shanmugham et al, *J. Mater. Res.*, **19**, 795, 2004. Or et al, *J. Magn. Magn. Mater.*, **262**, L181, 2003.

Model Formulation

□ Particles in multi-phase liquid: capillary forces

$$F = \int \left[f(\{c_\alpha\}, \{\eta_\beta\}) + \sum_\alpha \frac{1}{2} \kappa_\alpha |\nabla c_\alpha|^2 \right] dV$$

Landau polynomial

$$f(\{c_\alpha\}, \{\eta_\beta\}) = A \left[\sum_{\alpha=1}^2 (3c_\alpha^4 - 4c_\alpha^3) + \sum_\beta (3\eta_\beta^4 - 4\eta_\beta^3) + 6 \left(\chi c_1^2 c_2^2 + \sum_\beta \sum_{\alpha=1}^2 \lambda_\alpha c_\alpha^2 \eta_\beta^2 \right) \right]$$

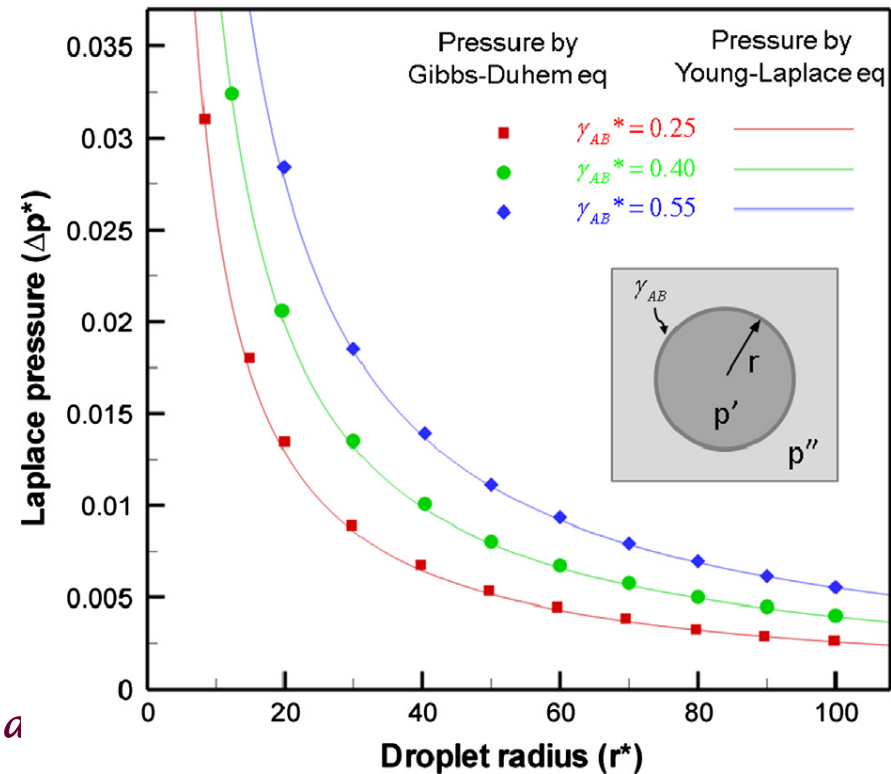
$$\frac{\partial c_\alpha}{\partial t} = \nabla \cdot \left(M_\alpha \nabla \frac{\delta F}{\delta c_\alpha} \right) \quad \text{Cahn-Hilliard}$$

$$dp = c_A d\mu_A + c_B d\mu_B$$

$$p - p^0 = c_1 \mu_1 + c_2 \mu_2 \quad \text{Gibbs-Duhem}$$

$$\mu_\alpha = \partial f / \partial c_\alpha$$

$$\Delta p = \frac{\gamma}{R} \quad \text{Young-Laplace}$$

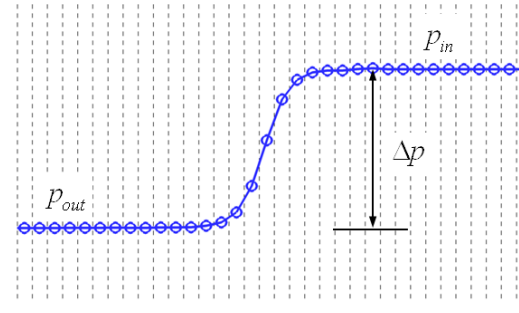
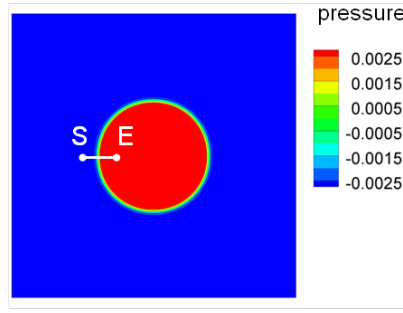


Model Formulation

- Particles in multi-phase liquid: capillary forces

Laplace pressure

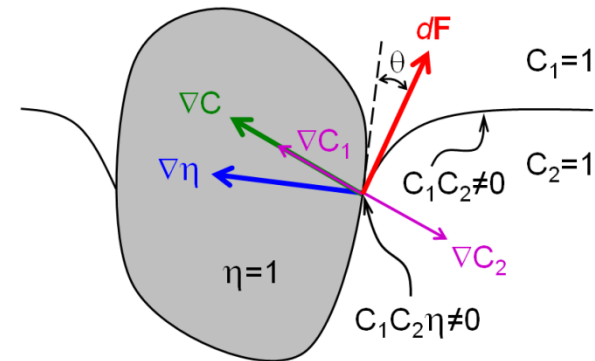
$$d\mathbf{F}^{\text{LP}}(\mathbf{r}, \beta) = \kappa_P \nabla \eta(\mathbf{r}, \beta) p(\mathbf{r}) dV$$



interfacial tension

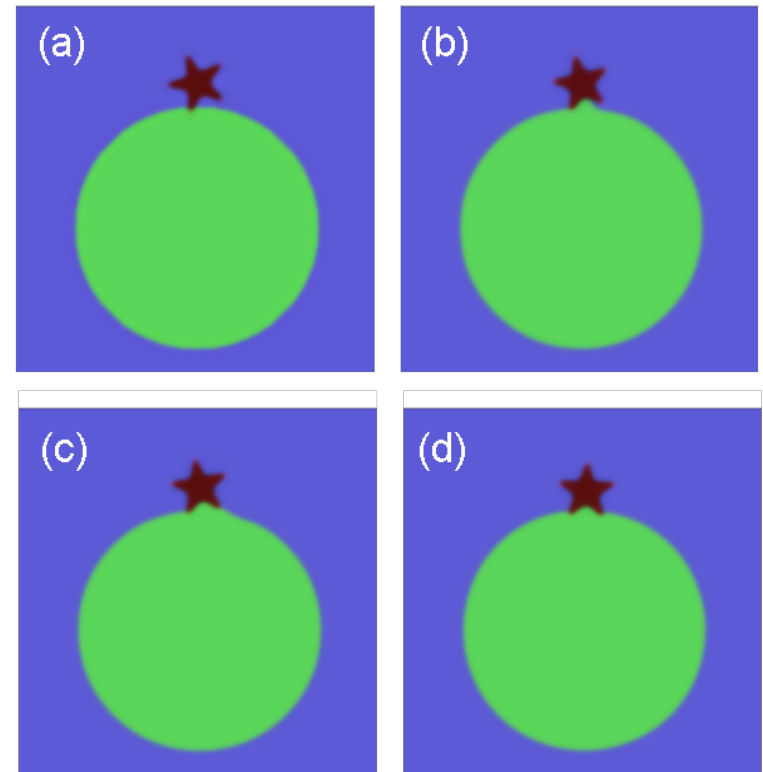
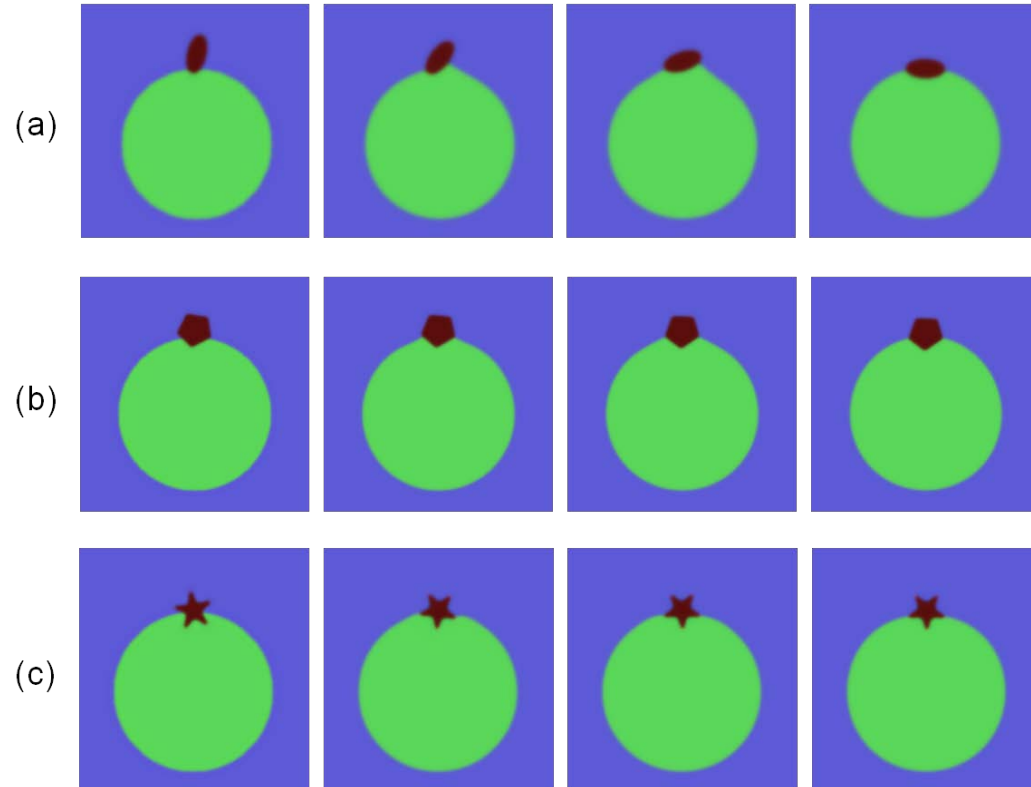
$$\begin{aligned} d\mathbf{F}^{\text{IT}}(\beta) &= \kappa_T [\nabla c \times (\nabla c \times \nabla \eta_\beta)] dV \\ &= \kappa_T [(\nabla c \cdot \nabla \eta_\beta) \nabla c - |\nabla c|^2 \nabla \eta_\beta] dV \end{aligned}$$

$$\nabla c = c_1 c_2 (\nabla c_1 - \nabla c_2)$$



Simulation

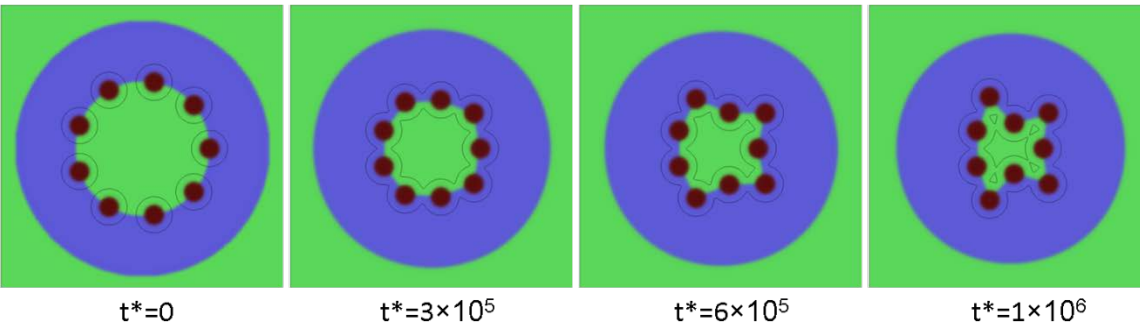
❑ Irregular-shaped particle at curved fluid interface



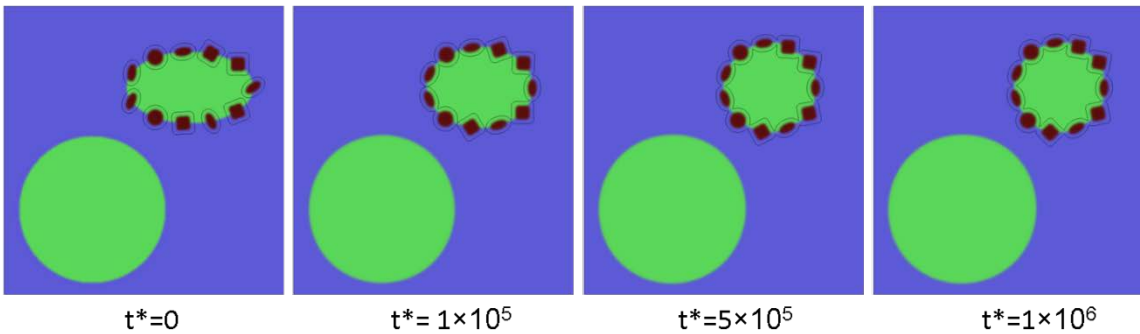
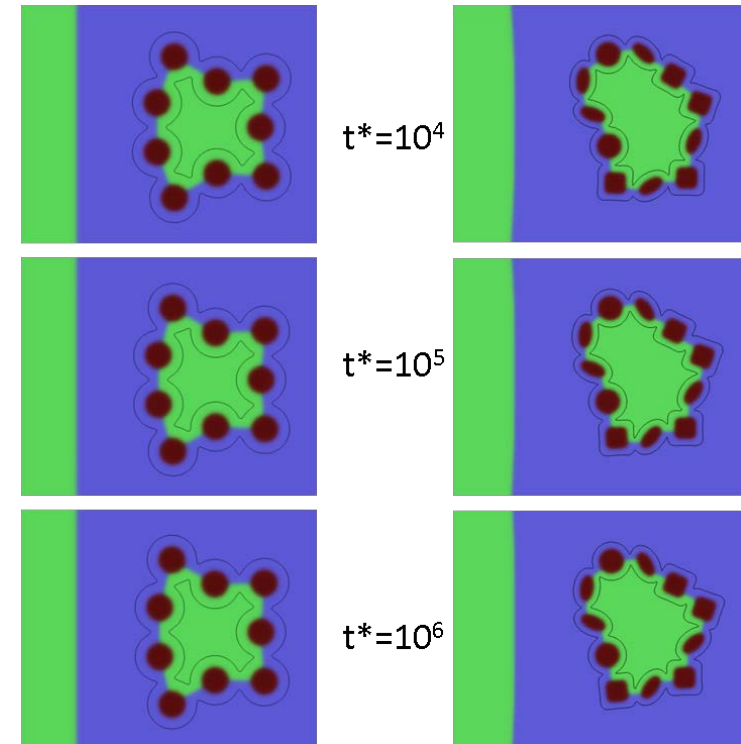
Simulation

Particle self-assembly directed by fluid interface: encapsulation

negative pressure



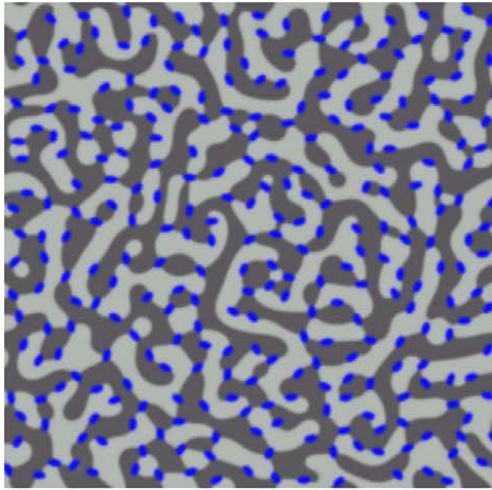
zero pressure



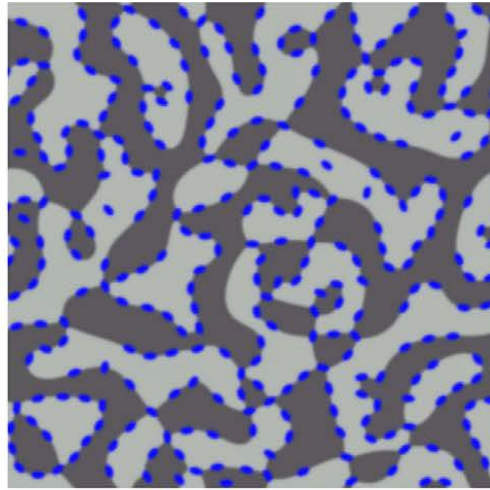
positive pressure

Simulation

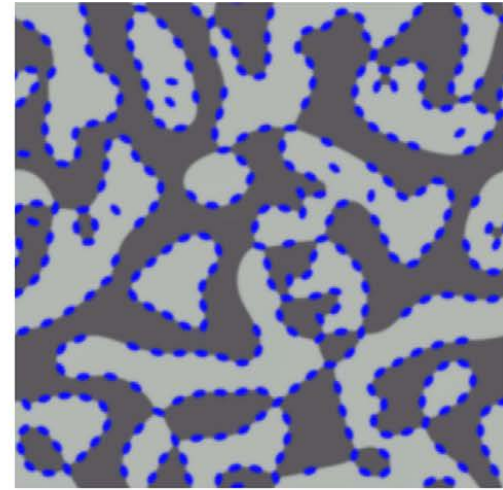
- Bijel: bicontinuous interfacially jammed emulsion gels



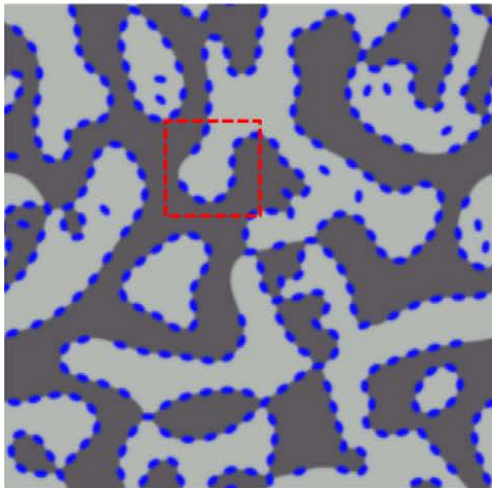
(a) $t^*=4,000$



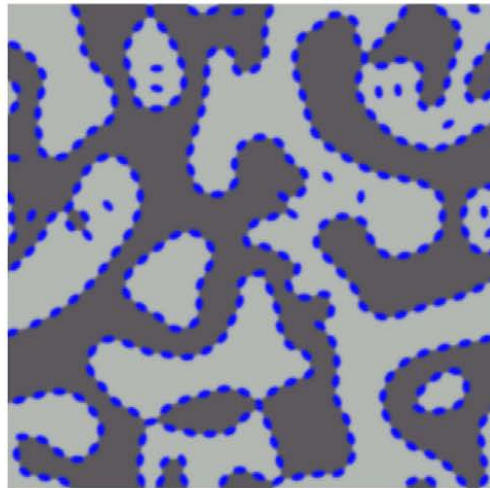
(b) $t^*=20,000$



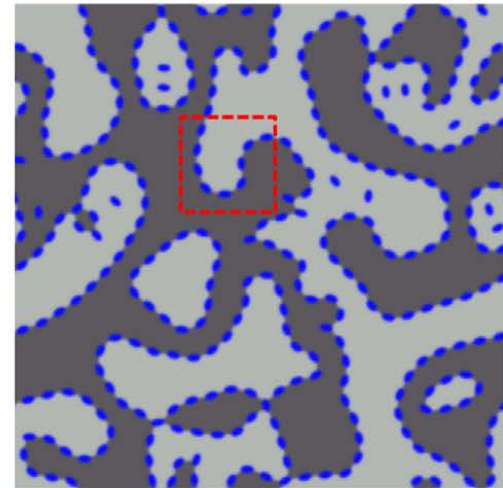
(c) $t^*=40,000$



(d) $t^*=60,000$



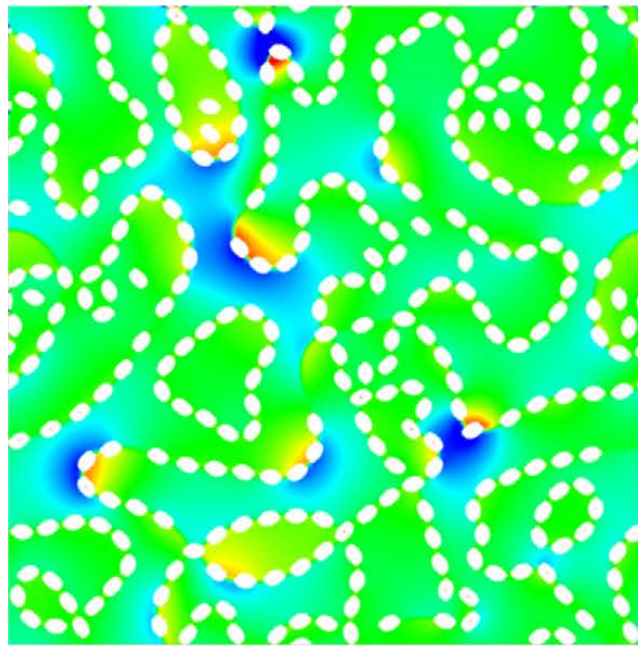
(e) $t^*=200,000$



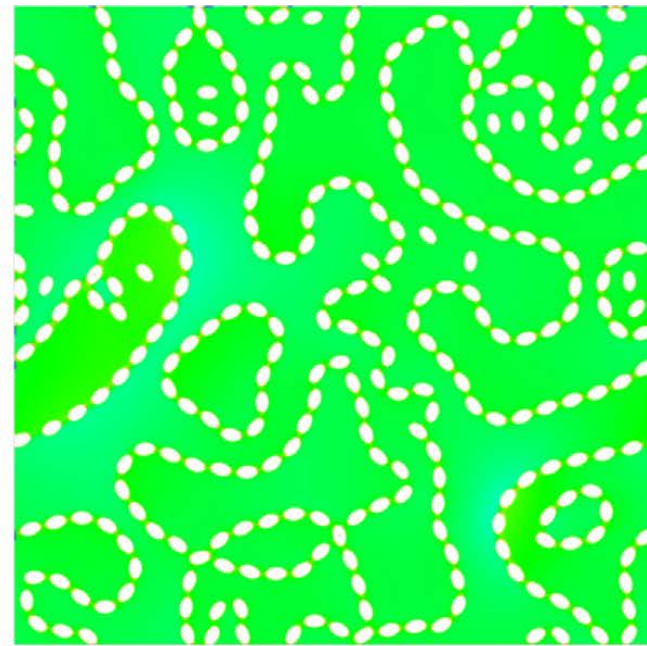
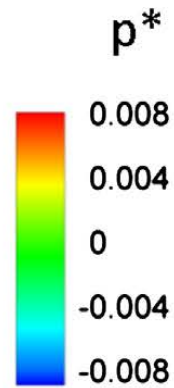
(f) $t^*=400,000$

Simulation

- Bijel: bicontinuous interfacially jammed emulsion gels



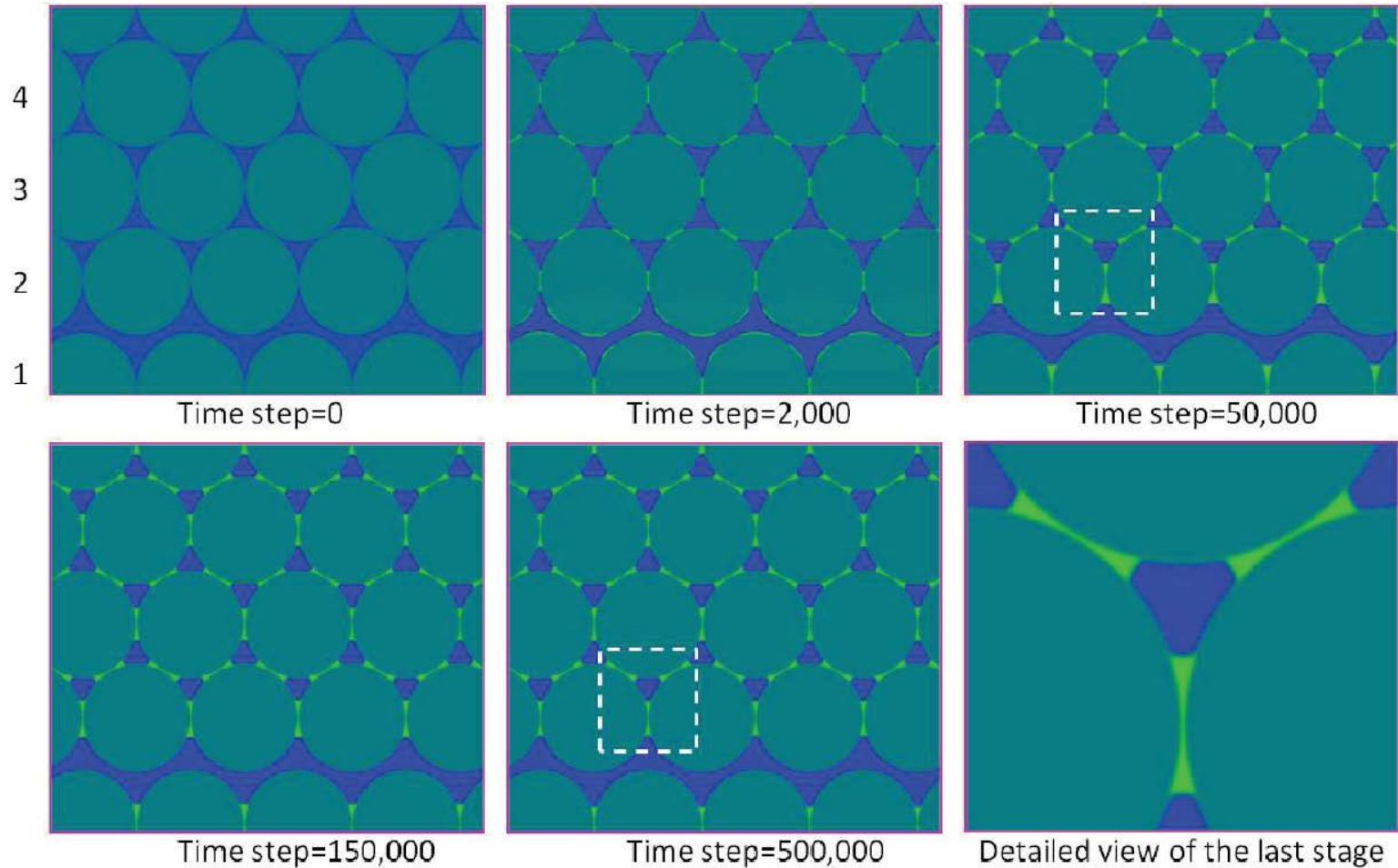
(a) $t^* = 60,000$



(b) $t^* = 200,000$

Simulation

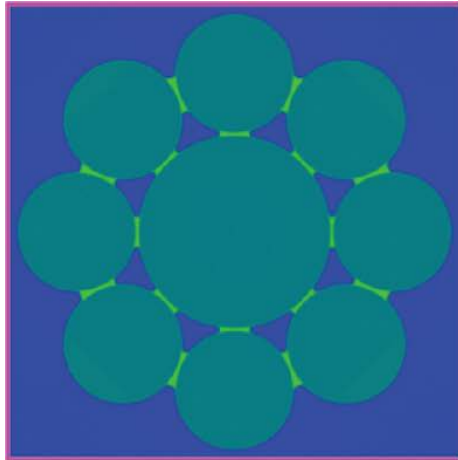
- Capillary bridges for in-situ firming of colloidal crystals



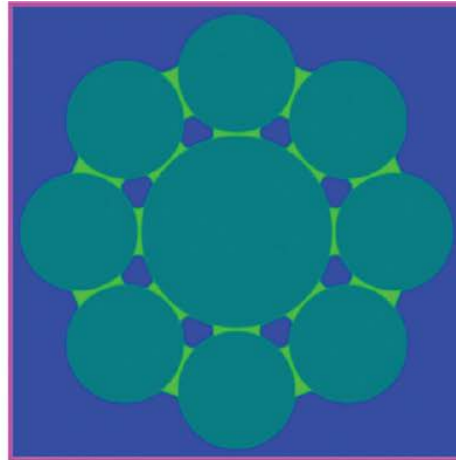
100 nm, 10,000 Pa

Simulation

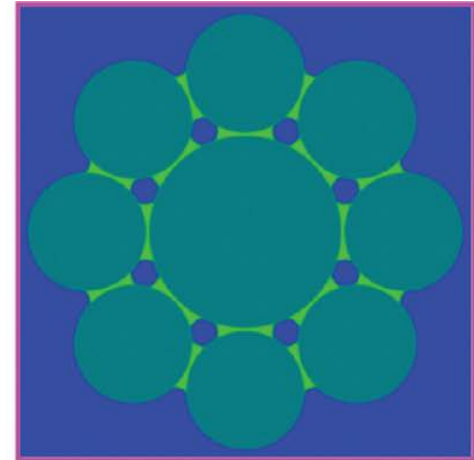
- Capillary bridges for in-situ firming of colloidal crystals



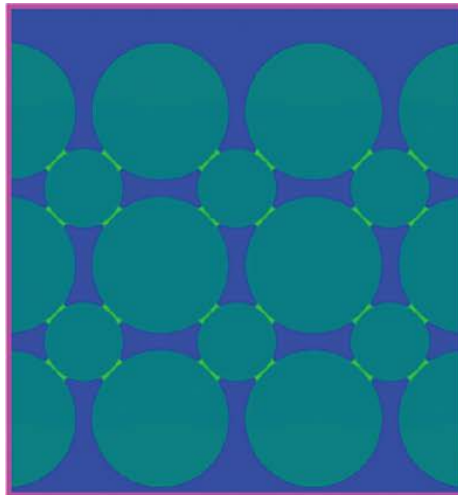
Time step=10,000



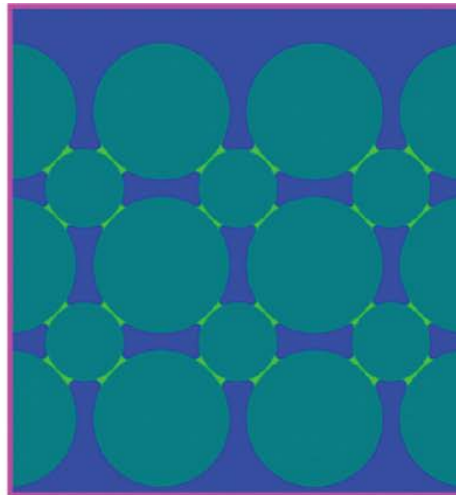
Time step=50,000



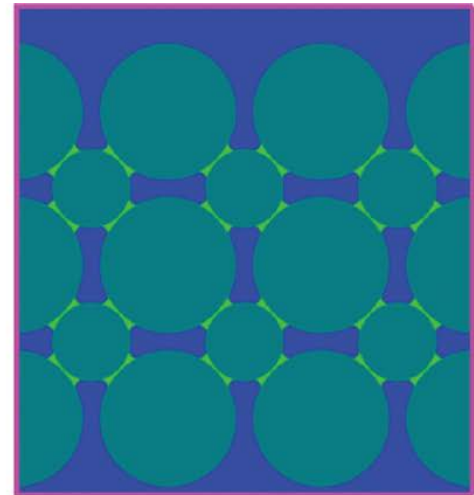
Time step=800,000



Time step=10,000



Time step=50,000



Time step=800,000

Acknowledgement

□ NSF DMR-0968792; TeraGrid supercomputers.

- Y.U. Wang, “Modeling and Simulation of Self-Assembly of Arbitrary-Shaped Ferro-Colloidal Particles in External Field: A Diffuse Interface Field Approach,” *Acta Mater.*, **55**, 3835-3844, 2007.
- P.C. Millett, Y.U. Wang, “Diffuse Interface Field Approach to Modeling and Simulation of Self-Assembly of Charged Colloidal Particles of Various Shapes and Sizes,” *Acta Mater.*, **57**, 3101-3109, 2009.
- P.C. Millett, Y.U. Wang, “Diffuse-Interface Field Approach to Modeling Arbitrarily-Shaped Particles at Fluid-Fluid Interfaces,” *J. Colloid Interface Sci.*, **353**, 46-51, 2011.
- T.L. Cheng, Y.U. Wang, “Spontaneous Formation of Stable Capillary Bridges for Firming Compact Colloidal Microstructures in Phase Separating Liquids: A Computational Study,” *Langmuir*, **28**, 2696-2703, 2012.
- T.L. Cheng, Y.U. Wang, “Shape-Anisotropic Particles at Curved Fluid Interfaces and Role of Laplace Pressure: A Computational Study,” *J. Colloid Interface Sci.*, **402**, 267-278, 2013.
- Y.U. Wang, “Phase Field Model of Dielectric and Magnetic Composites,” *Appl. Phys. Lett.*, **96**, 232901-1-3, 2010.
- Y.U. Wang, “Computer Modeling and Simulation of Solid-State Sintering: A Phase Field Approach,” *Acta Mater.*, **54**, 953-961, 2006.

Diffuse Interface Field Approach (DIFA) to Modeling and Simulation of Particle-based Materials Processes

Yu U. Wang

Materials Science and Engineering Department
Michigan Technological University